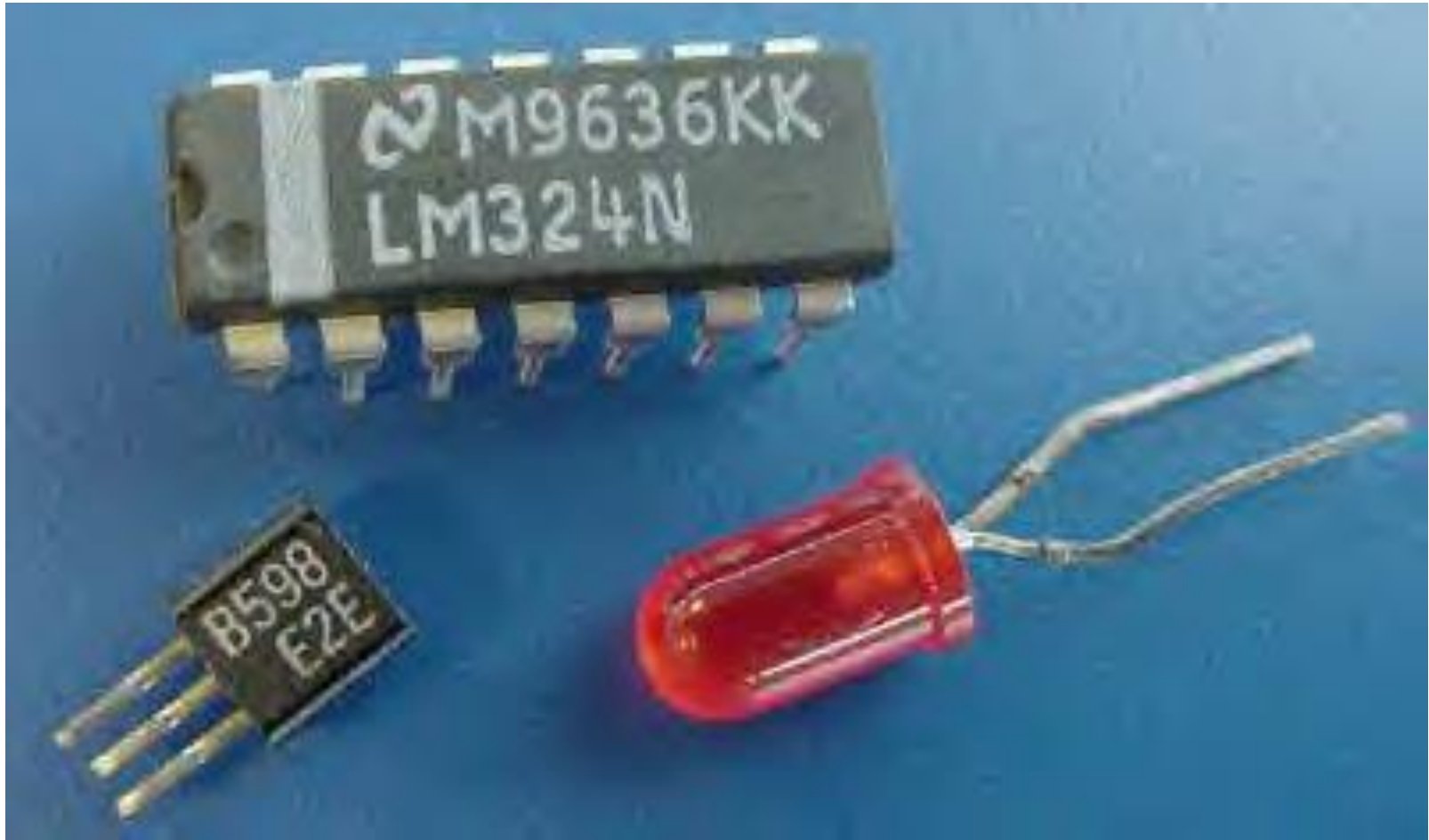


Mathematics and Science in Schools in Sub-Saharan Africa

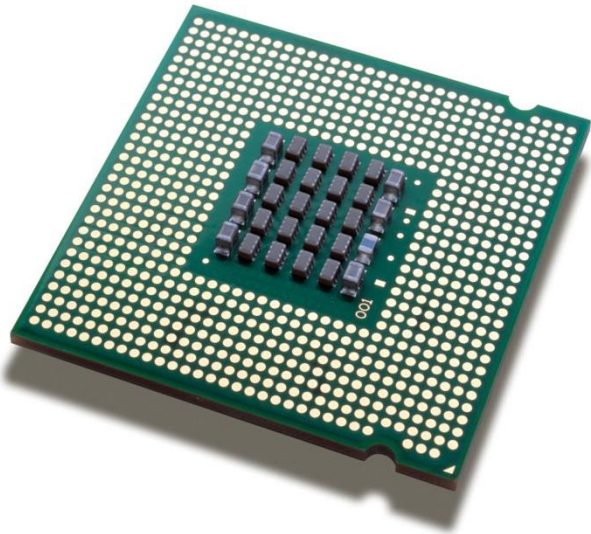
SEMICONDUCTORS



What is a Semiconductor?



What is a Semiconductor?



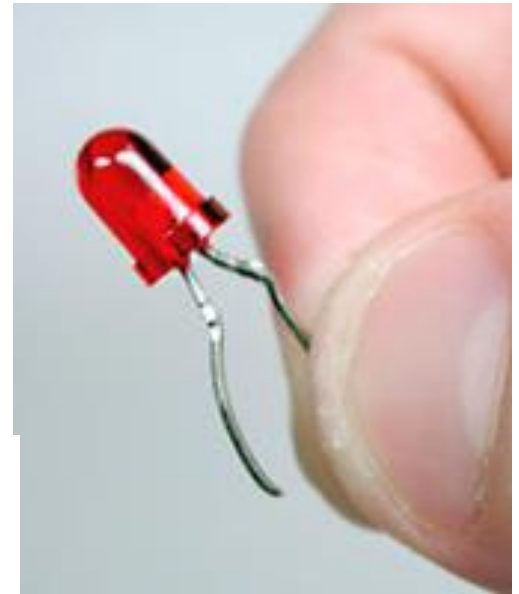
Microprocessors



Transistors



Capacitors



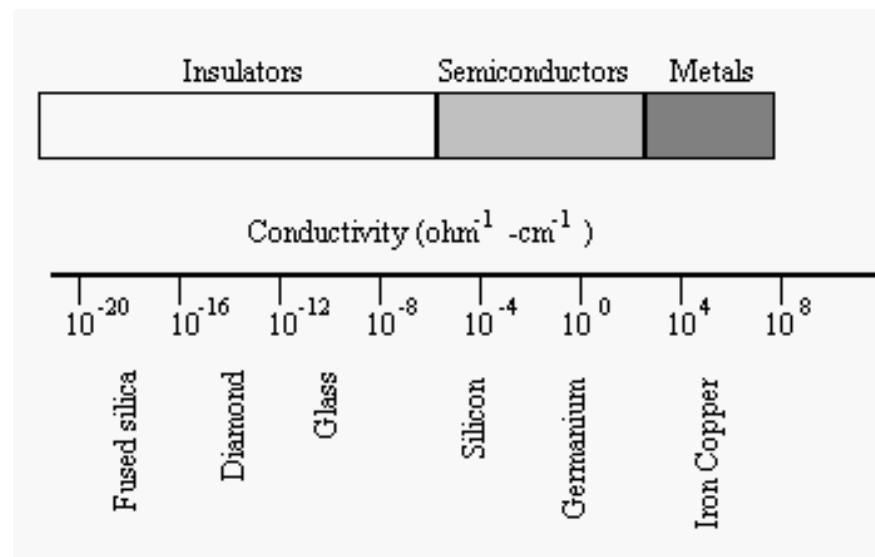
LED

¹⁴Si Elements in Semiconductors

Elements in Semiconductors																		
1 H																	14 Si	2 He
3 Li	4 Be											5 B	6 C	7 N	8 O	9 F	10 Ne	
11 Na	12 Mg											13 Al	14 Si	15 P	16 S	17 Cl	18 Ar	
19 K	20 Ca	21 Sc	22 Ti	23 V	24 Cr	25 Mn	26 Fe	27 Co	28 Ni	29 Cu	30 Zn	31 Ga	32 Ge	33 As	34 Se	35 Br	36 Kr	
37 Rb	38 Sr	39 Y	40 Zr	41 Nb	42 Mo	43 Tc	44 Ru	45 Rh	46 Pd	47 Ag	48 Cd	49 In	50 Sn	51 Sb	52 Te	53 I	54 Xe	
55 Cs	56 Ba	57 La	72 Hf	73 Ta	74 W	75 Re	76 Os	77 Ir	78 Pt	79 Au	80 Hg	81 Tl	82 Pb	83 Bi	84 Po	85 At	86 Rn	
87 Fr	88 Ra	89 Ac																

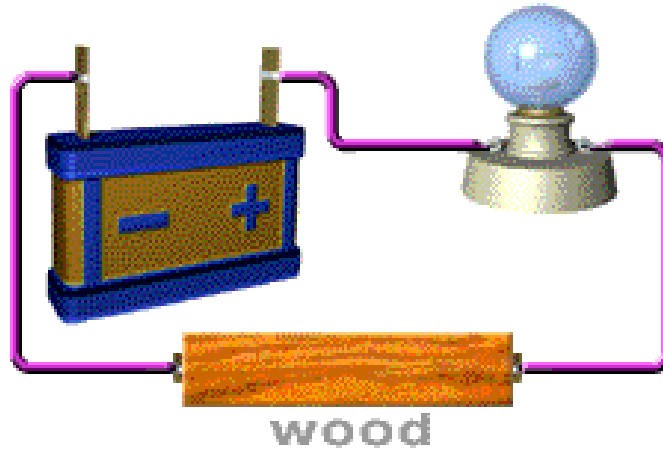
⁵⁷ La	⁵⁸ Ce	⁵⁹ Pr	⁶⁰ Nd	⁶¹ Pm	⁶² Sm	⁶³ Eu	⁶⁴ Gd	⁶⁵ Tb	⁶⁶ Dy	⁶⁷ Ho	⁶⁸ Er	⁶⁹ Tm	⁷⁰ Yb	⁷¹ Lu
⁸⁹ Ac	⁹⁰ Th	⁹¹ Pa	⁹² U	⁹³ Np	⁹⁴ Pl	⁹⁵ Am	⁹⁶ Cm	⁹⁷ Bk	⁹⁸ Cf	⁹⁹ Es	¹⁰⁰ Fm	¹⁰¹ Md	¹⁰² No	¹⁰³ Lr

Range of Conductiveness



The semiconductors fall somewhere midway between conductors and insulators.

Range of Conduciveness



Semiconductors have special electronic properties which allow them to be insulating or conducting depending on their composition.

1824



John Jacob Berzelius

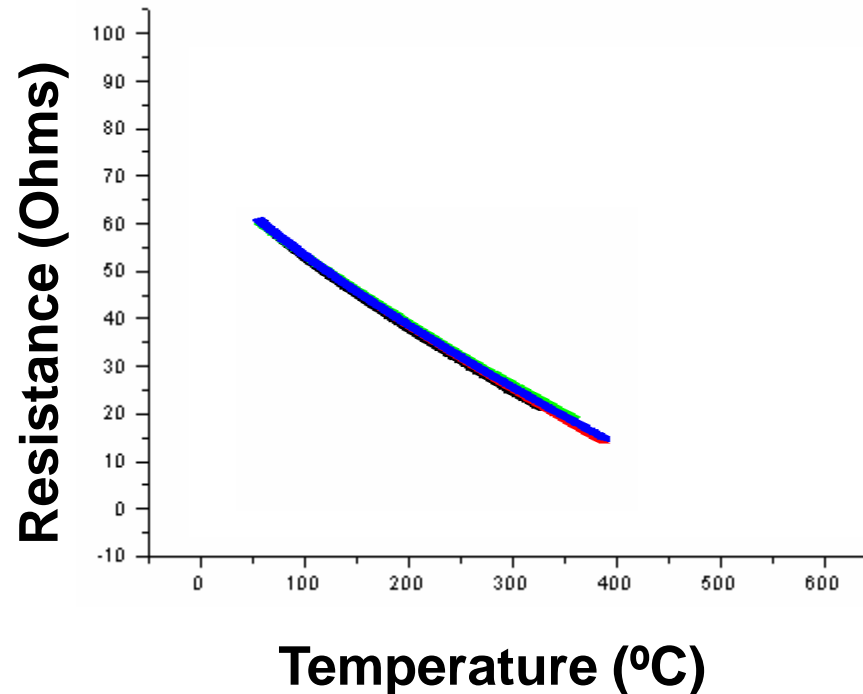
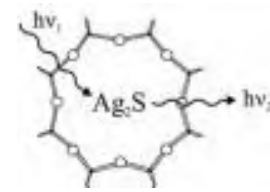


***First to isolate and identify silicon.
Remains little more than a scientific curiosity until
the 1900s.***



Michael Faraday

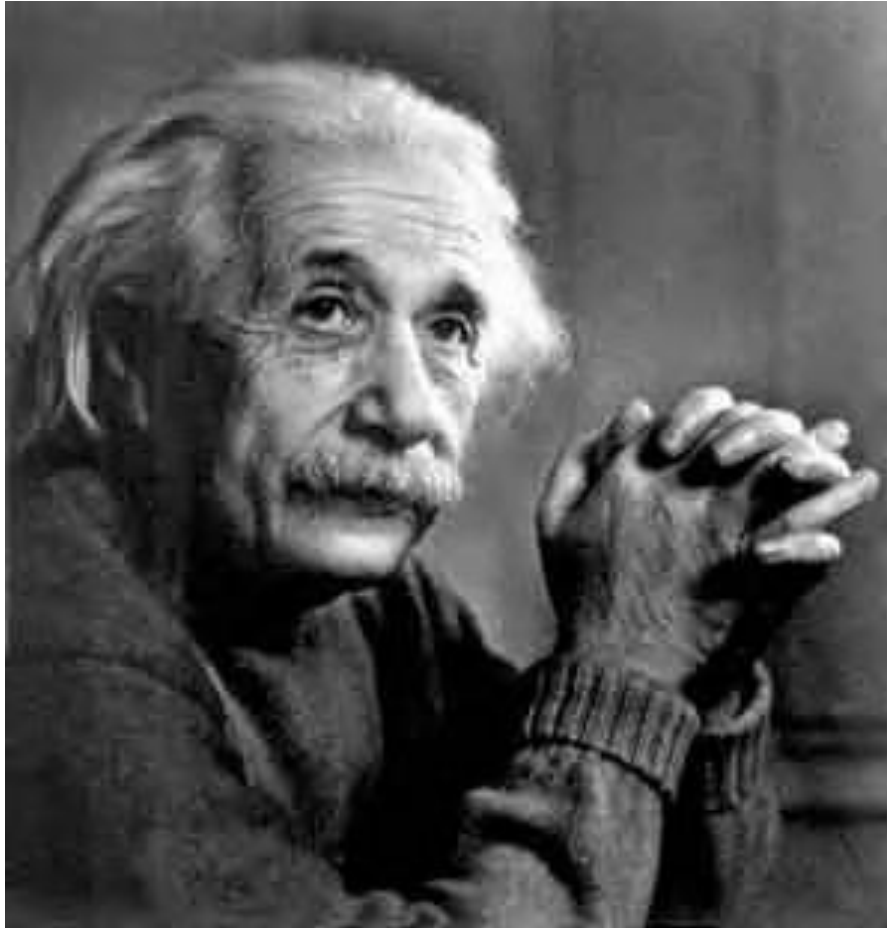
1833



Discovers that electrical resistivity decreases as temperature increases in silver sulfide.

This is the first investigation of a semiconductor.

Lab: Metals vs. Semiconductors



Lab: Metals vs. Semiconductors

Data Chart

<i>Temperature</i>	Copper	Germanium
0°C	31Ω	5.2Ω
25°C	33Ω	4.2Ω
50°C	37Ω	1.2Ω
75°C	41Ω	0.63Ω
100°C	44Ω	.029Ω

1873



William Smith

SELENIUM:

THE ELECTRICAL QUALITIES, AND THE EFFECT OF LIGHT
THEREON.

*Being a Paper read before the Society of Telegraph Engineers,
25th November, 1872.*

By WILLOUGHBY SMITH

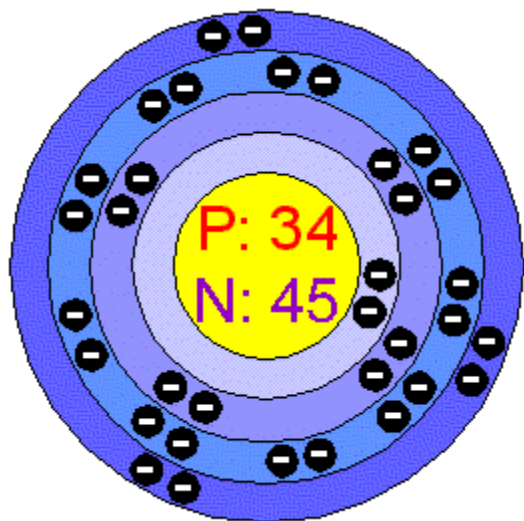
FROM the many inquiries which have reached me since I first called attention to the effect of light upon the electrical qualities of Selenium, I am induced to enter more fully into details than I otherwise should have done.

In 1817 Berzelius discovered a new and rare elementary substance, which he named Selenium. It is obtained in small quantities from iron and copper pyrites, the smoke from the furnaces of silver Works, the deposit in the leaden chambers at sulphuric acid Works, and it has also been discovered in the metallic copper of commerce. It appears in two modifications, one soluble and the other insoluble in bisulphide of carbon. That soluble in bisulphide of carbon has been called "Red Selenium," "Amorphous Selenium," and "Glassy Selenium." That insoluble in bisulphide of carbon has been called "Black Selenium," "Granular Selenium," "Metallic Selenium," and "Crystalline Selenium."

Solid amorphous Selenium is a bad conductor of heat and a non-conductor of electricity. At the ordinary temperature it remains unchanged for years. It is brittle, easily scratched and powdered, its surface reddish-brown and of a metallic lustre, and its fracture of a brown-glass colour, dark lead-grey, and shining.

Solid "crystallized" Selenium is a conductor of

***Discovers the photoconductivity of selenium and
invents a selenium photometer.***



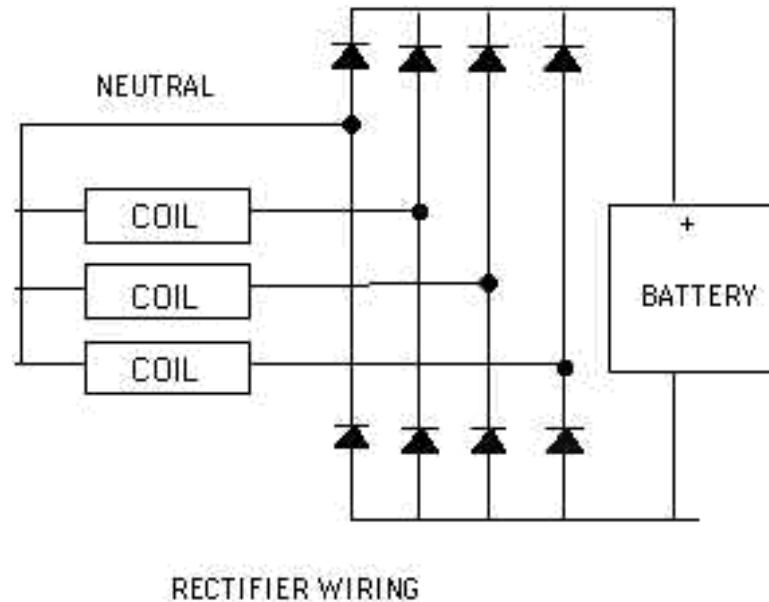
1874



Ferdinand Braun

The first semiconductor device was born.

Radio receivers required a device called a rectifier to detect signals.



He used the rectifying properties of the galena crystal, a semiconductor material composed of lead sulfide, to create the cat's whisker diode for this purpose.

1927



Sommerfeld



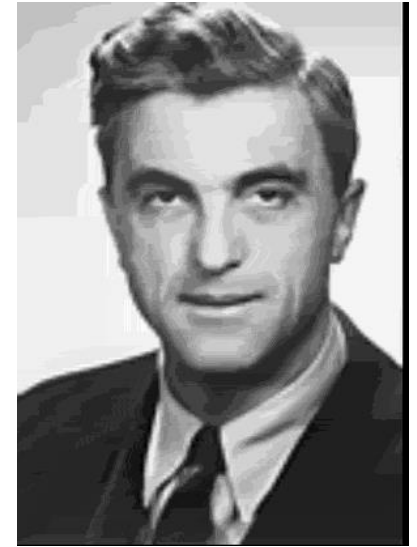
$1s$



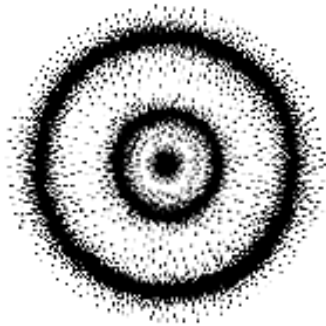
$2s$



$2p_z$



Bloch



$3s$



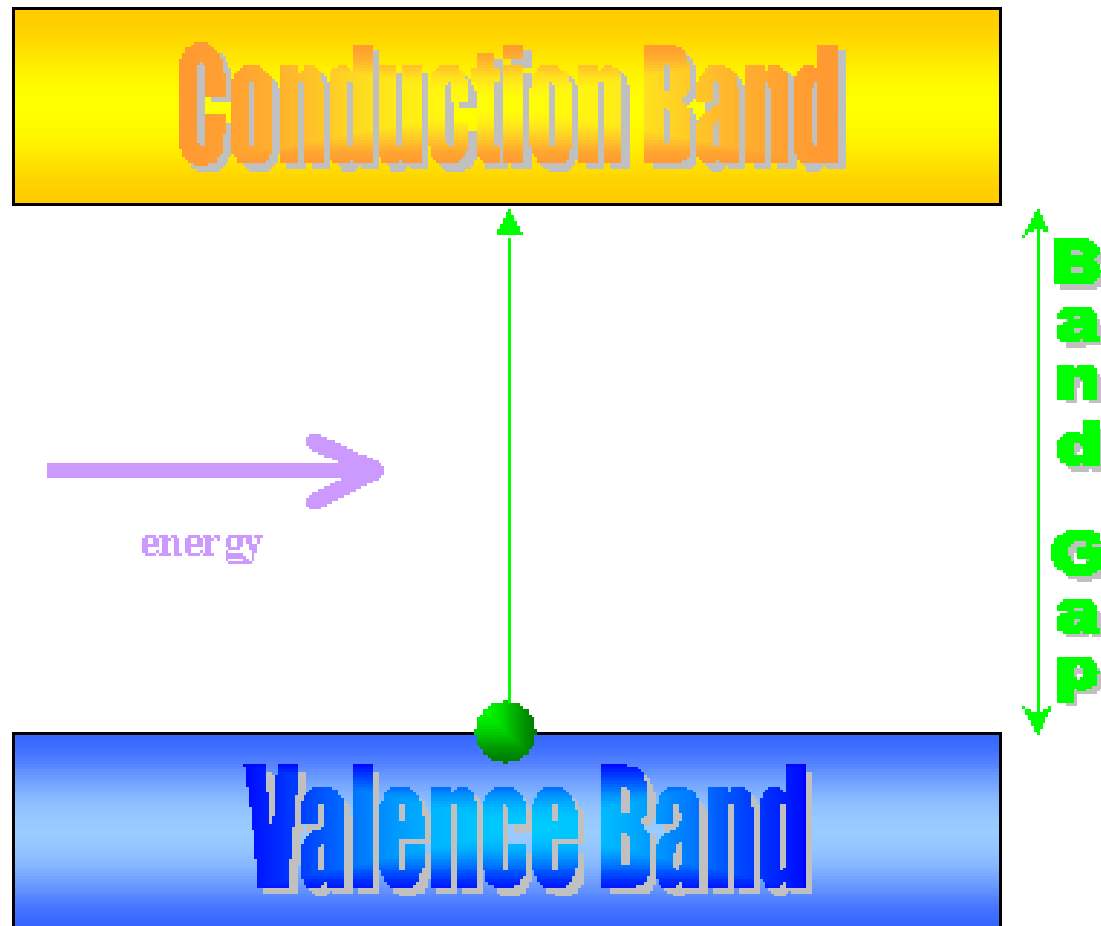
$3p_z$



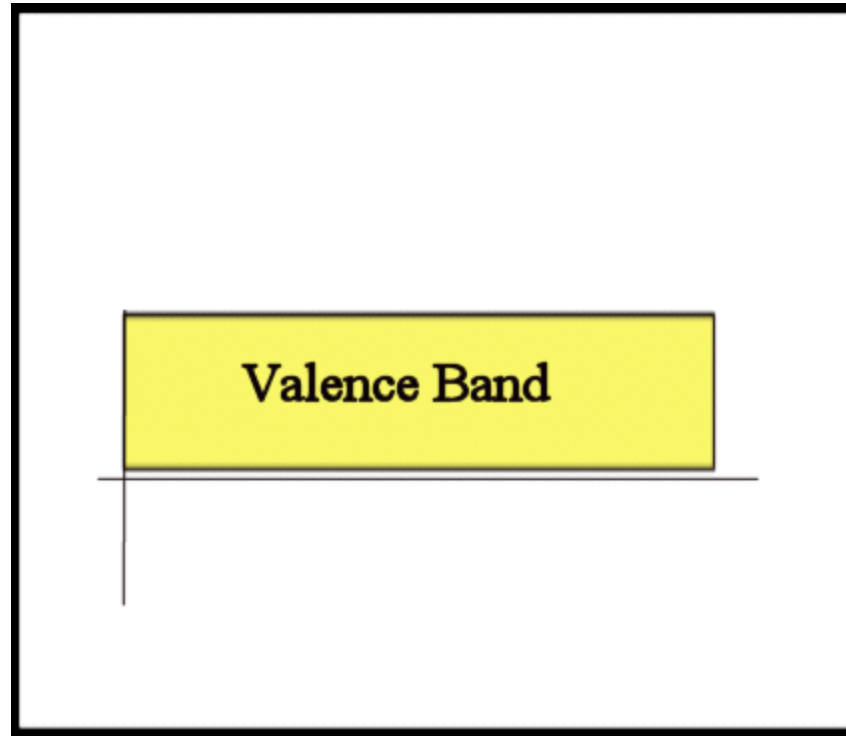
$3d_z^2$

Applied quantum mechanics to solids, helping explain the conduction of electricity in semiconductors.

Scientific Principle of Conduction



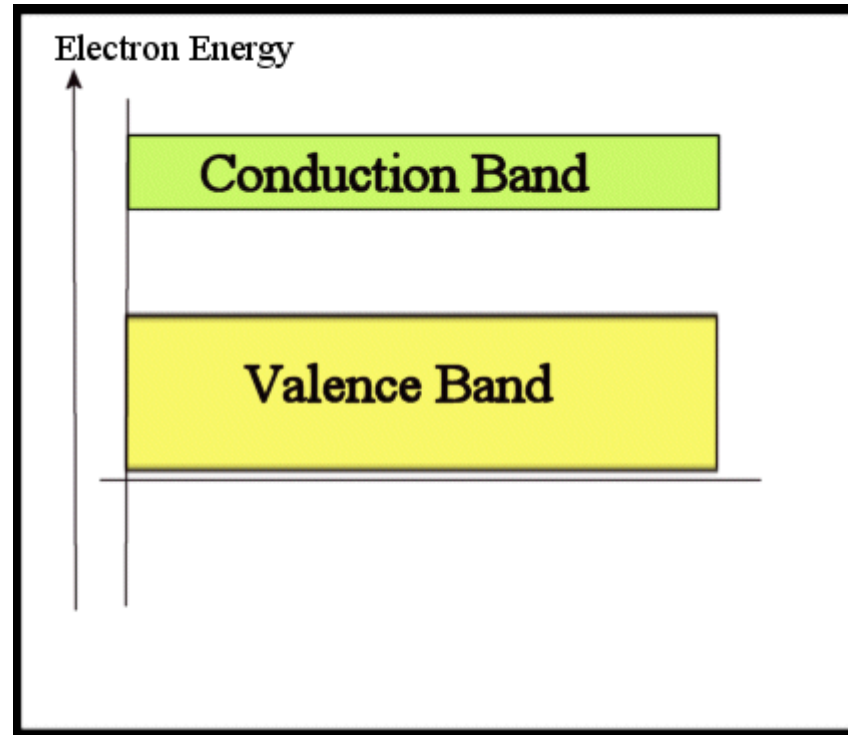
Valence Band



The highest occupied energy band is called the valence band.

Most electrons remain bound to the atoms in this band.

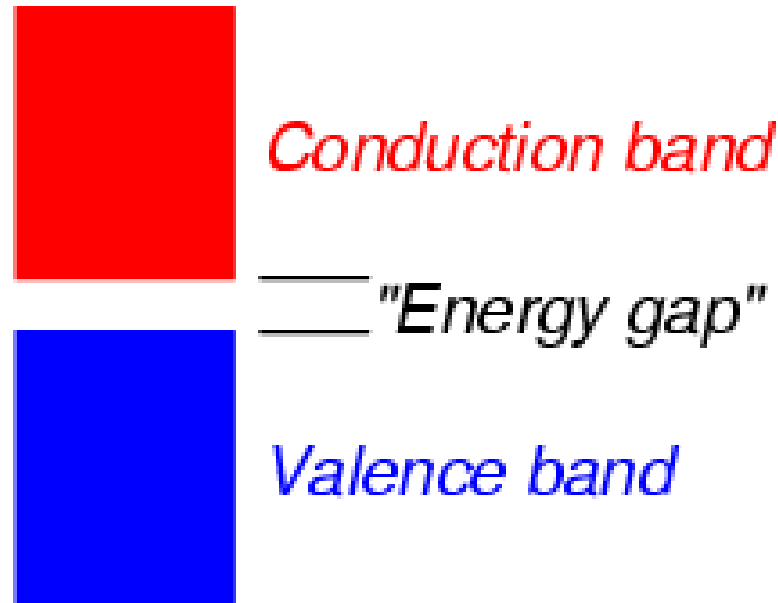
Conduction Band



The conduction band is the band of orbitals that are high in energy and are generally empty.

It is the band that accepts the electrons from the valence band.

Energy Gap



The “leap” required for electrons from the Valence Band to enter the Conduction Band.

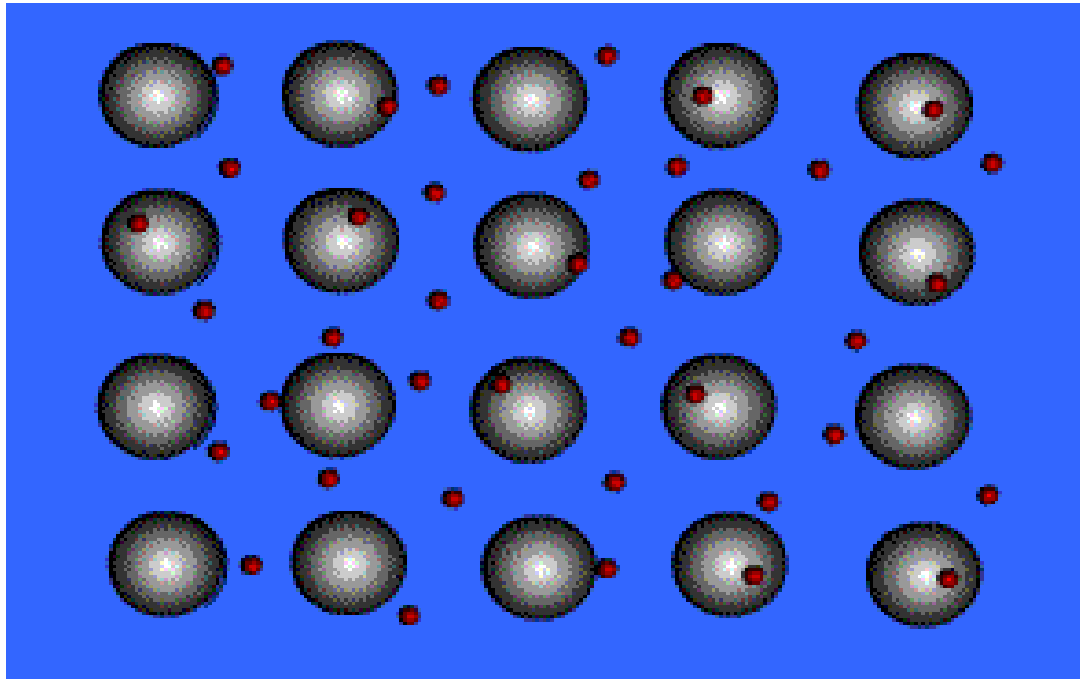
Conduction Band

Band Gap

Valence Band

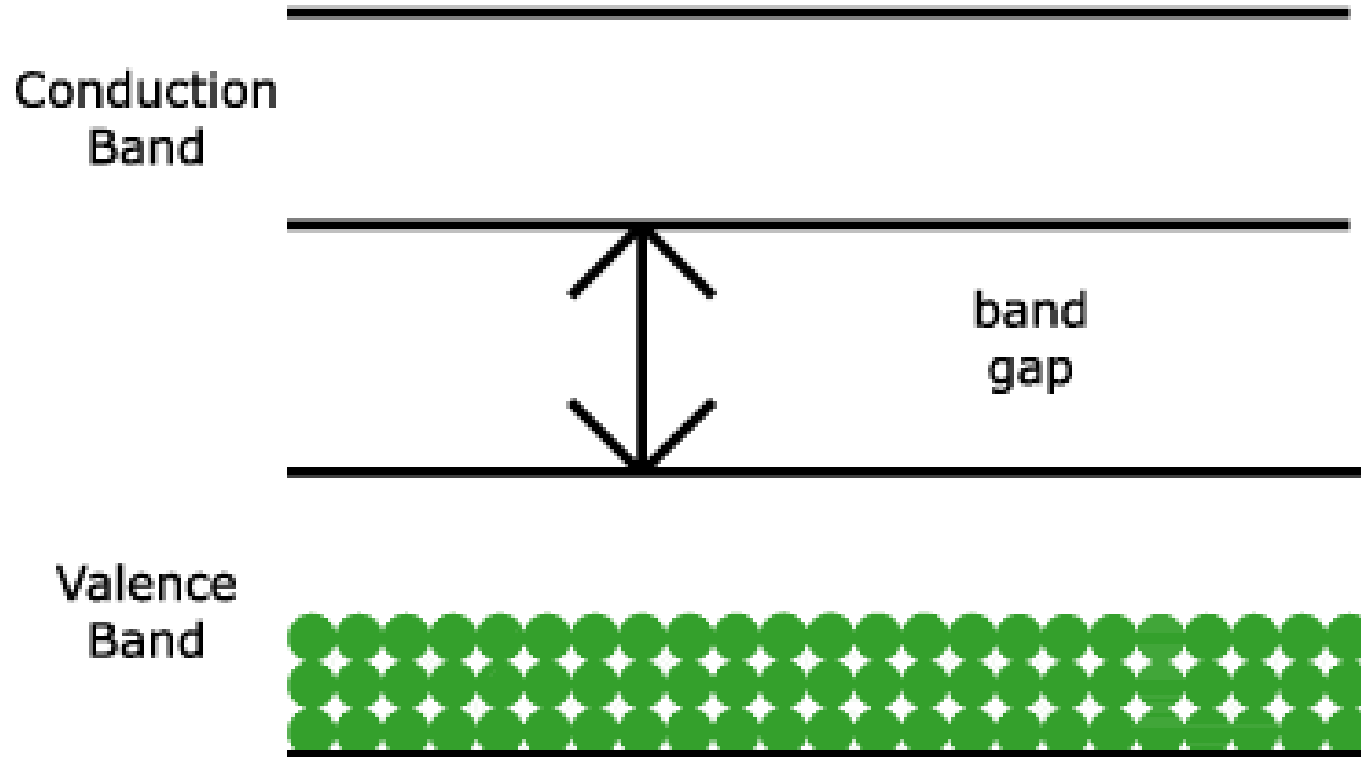
LongIslandExchange.com

Conductors



In a conductor, electrons can move freely among these orbitals within an energy band as long as the orbitals are not completely occupied.

Conductors

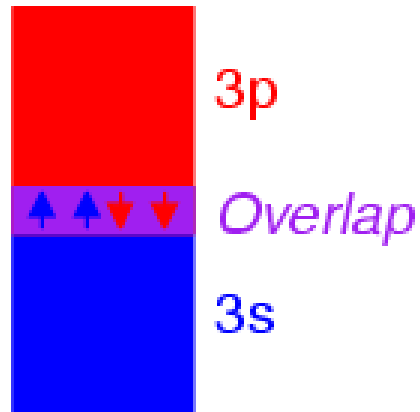


In conductors, the valence band is empty.



Conductors

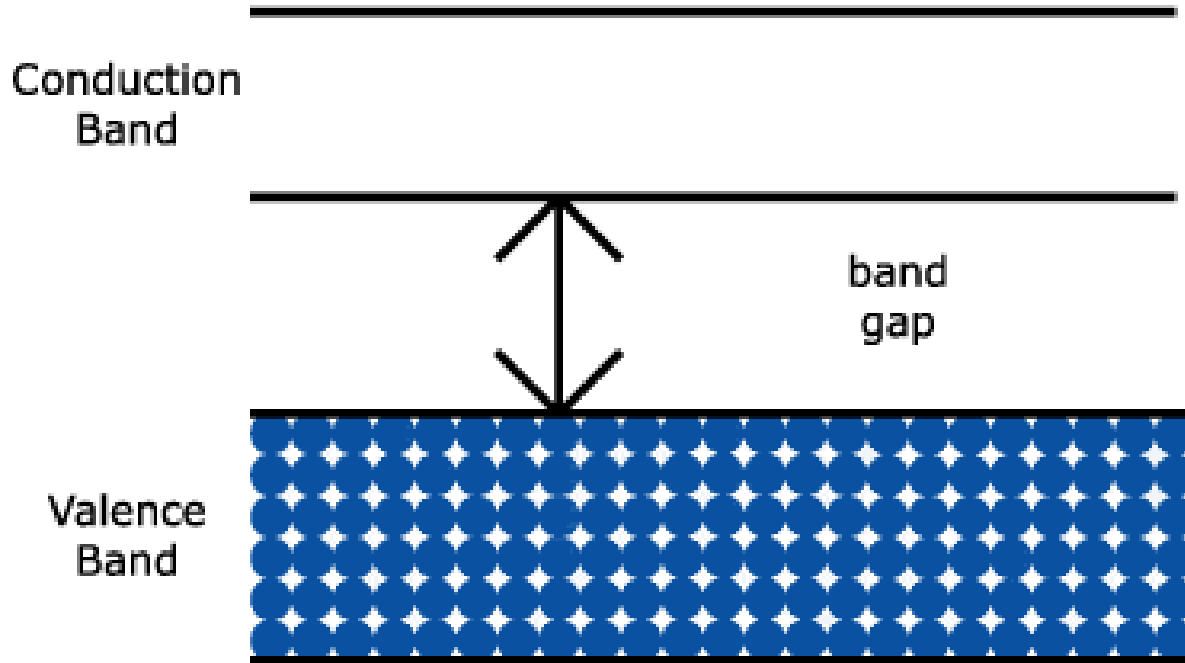
*Overlap permits
electrons to freely
drift between bands*



Multitudes of atoms
in close proximity

Also in conductors, the energy gap is nonexistent or relatively small.

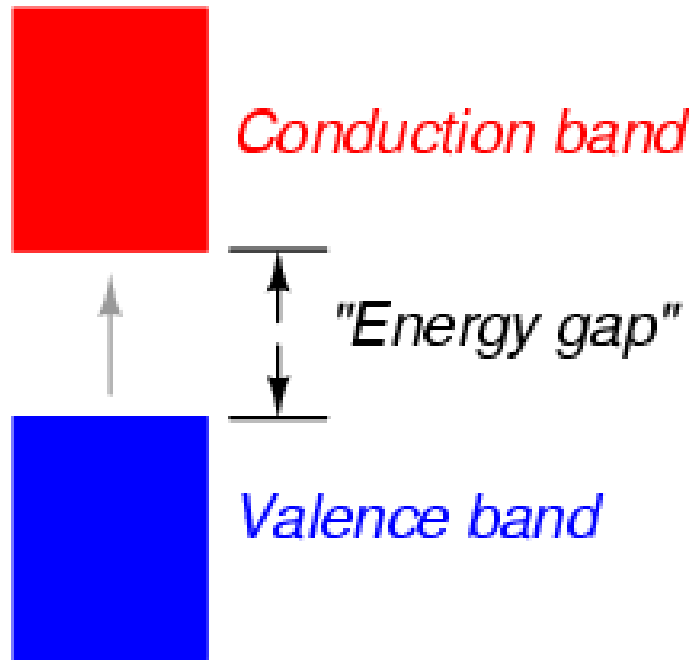
Insulators



In insulators, the valence band is full.

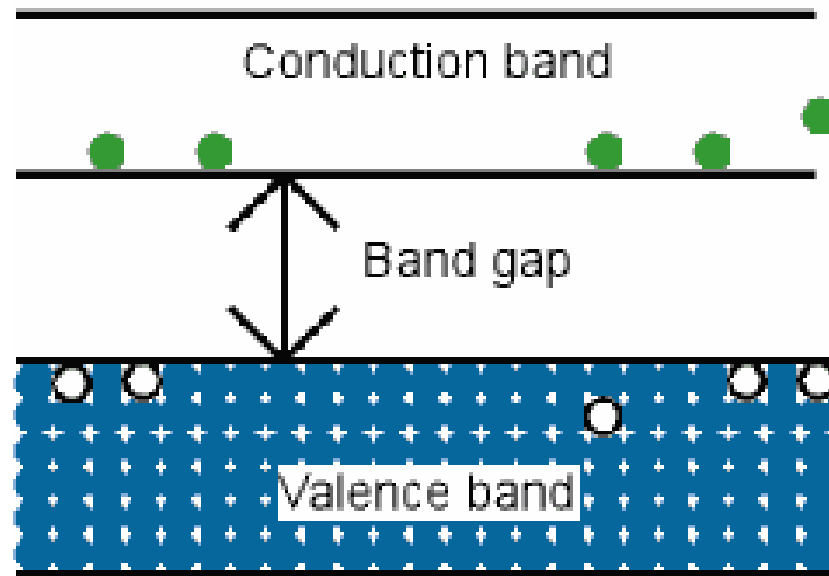


Insulators



Also in insulators, the energy gap is relatively large.

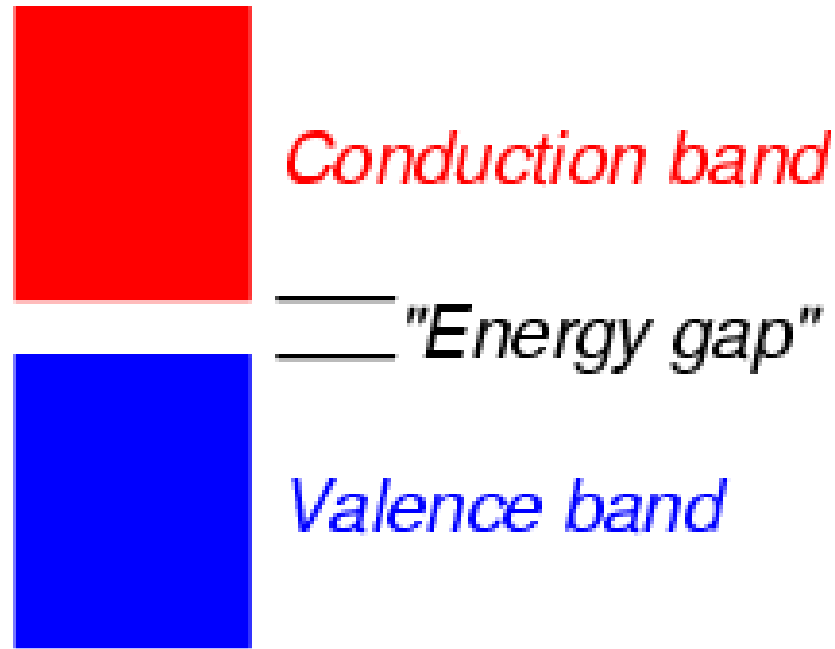
Semiconductors



In semiconductors, the valence band is full but the energy gap is intermediate.

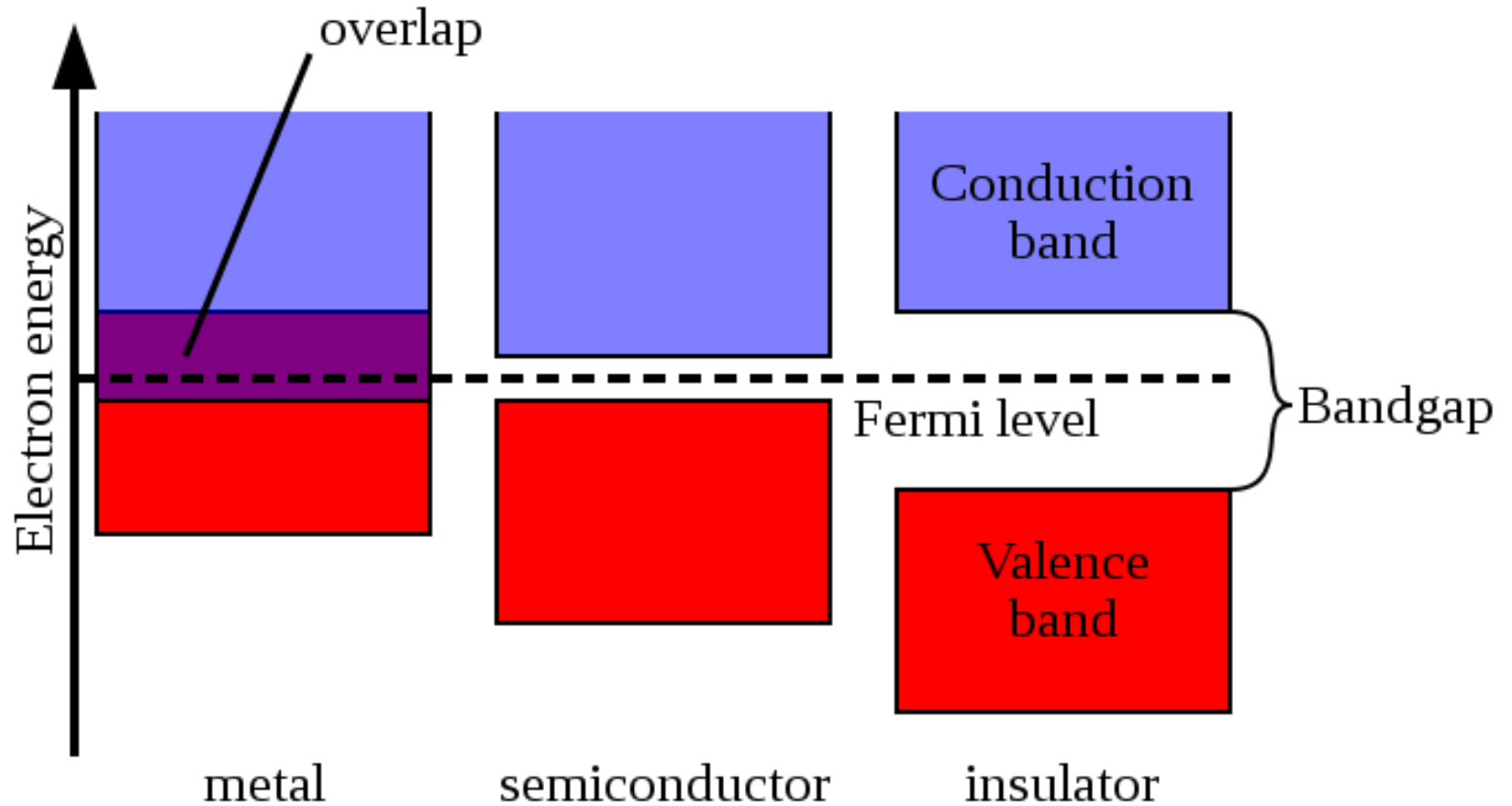


Semiconductors



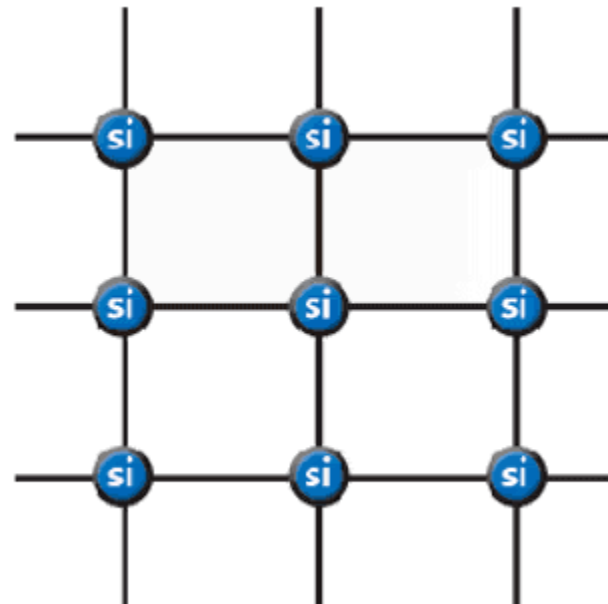
Only a small leap is required for an electron to enter the Conduction Band.

Band Diagrams



Silicon

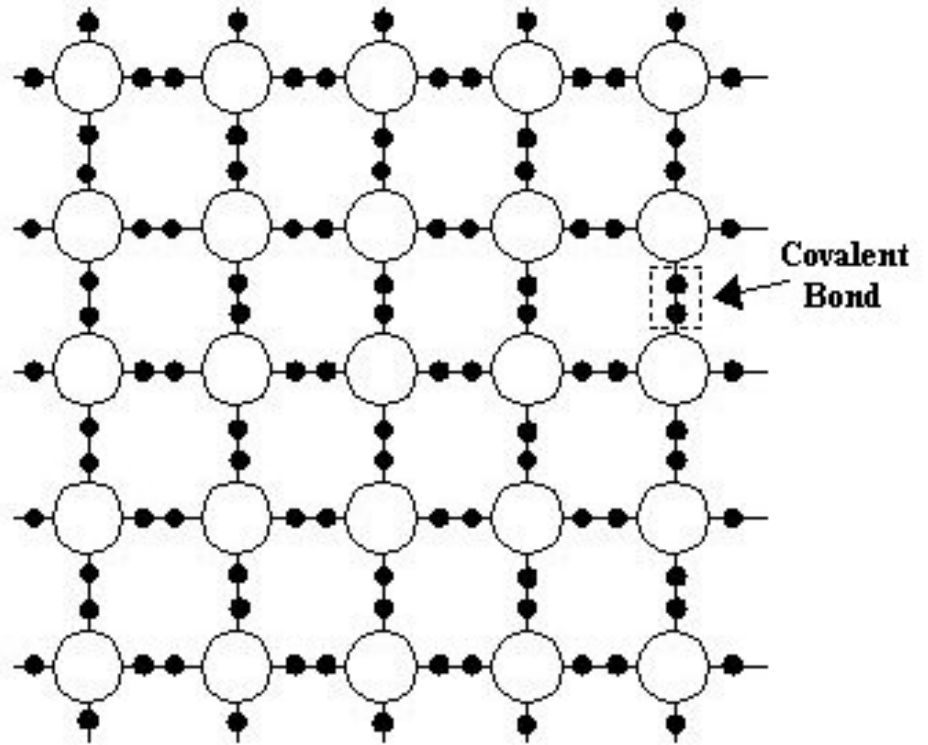
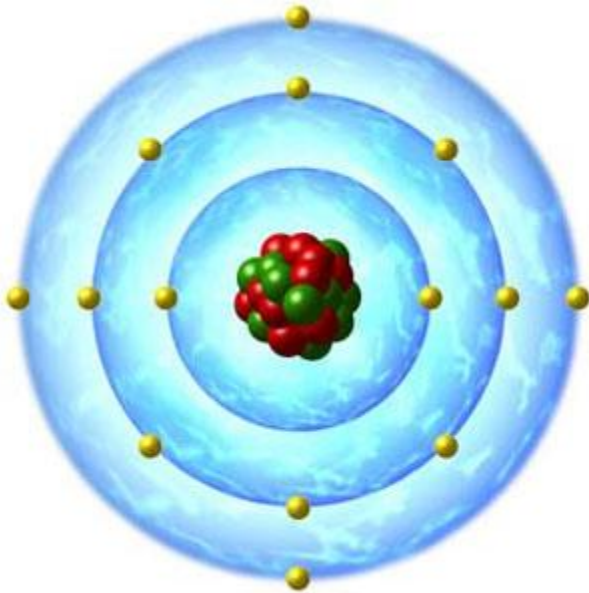
5 B Boron 2.34	6 C Carbon 2.62	7 N Nitrogen 1.251
13 Al Aluminum 2.70	14 Si Silicon 2.33	15 P Phosphorus 1.82
31 Ga Gallium 5.91	32 Ge Germanium 5.32	33 As Arsenic 5.72



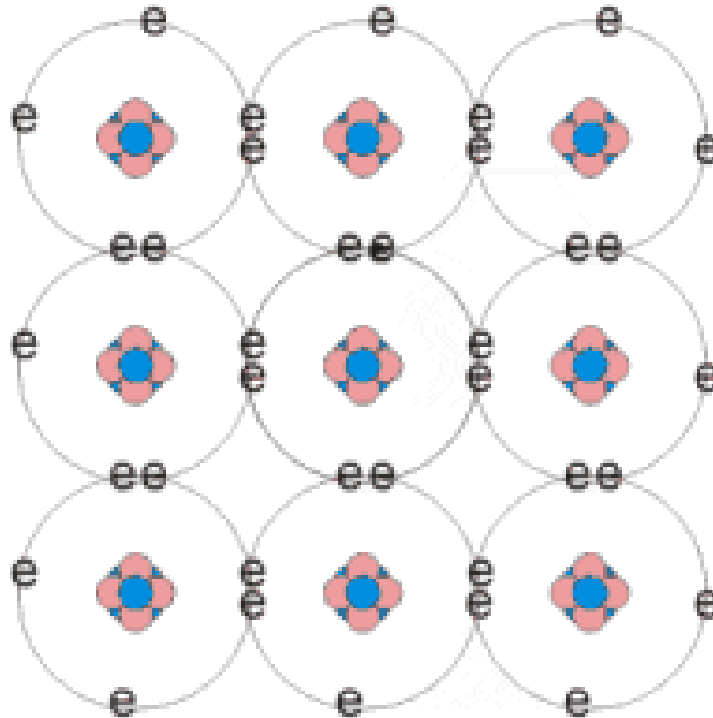


Silicon is a very common element, the main element in sand & quartz.

Silicon's Arrangement

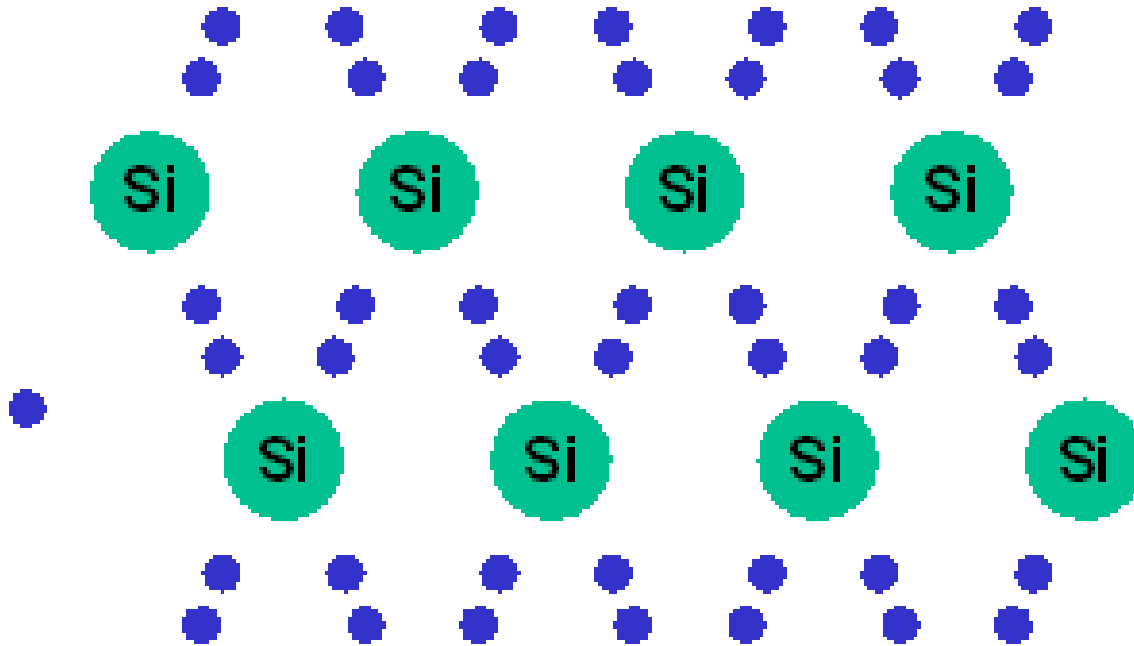


Intrinsic Silicon



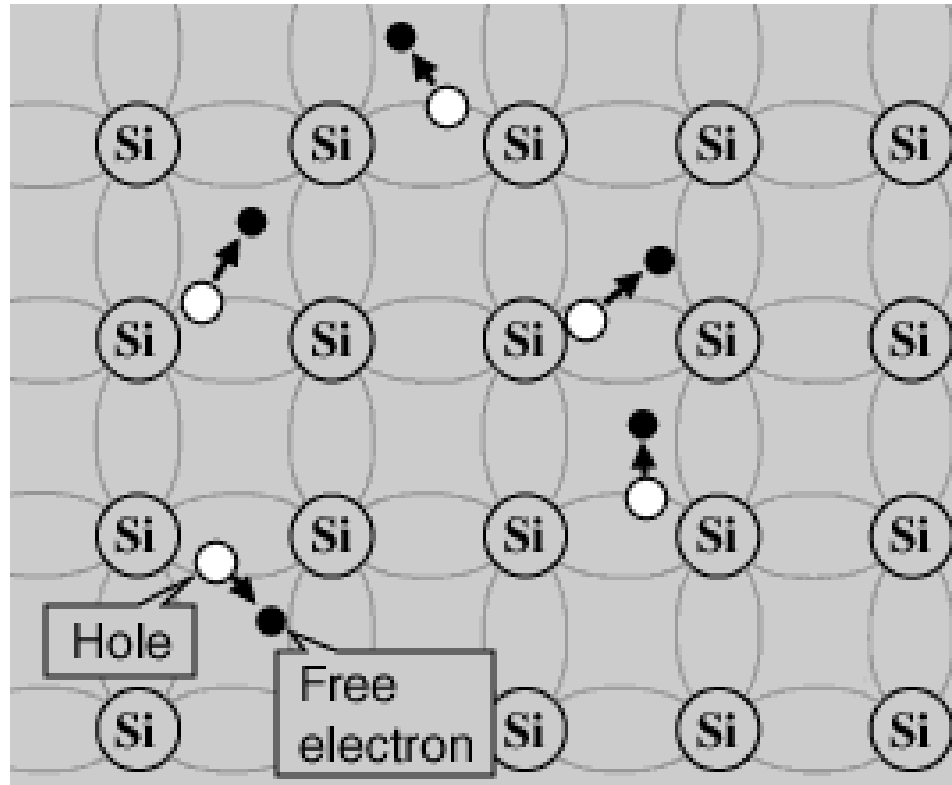
A silicon crystal is different from an insulator.

Intrinsic Silicon



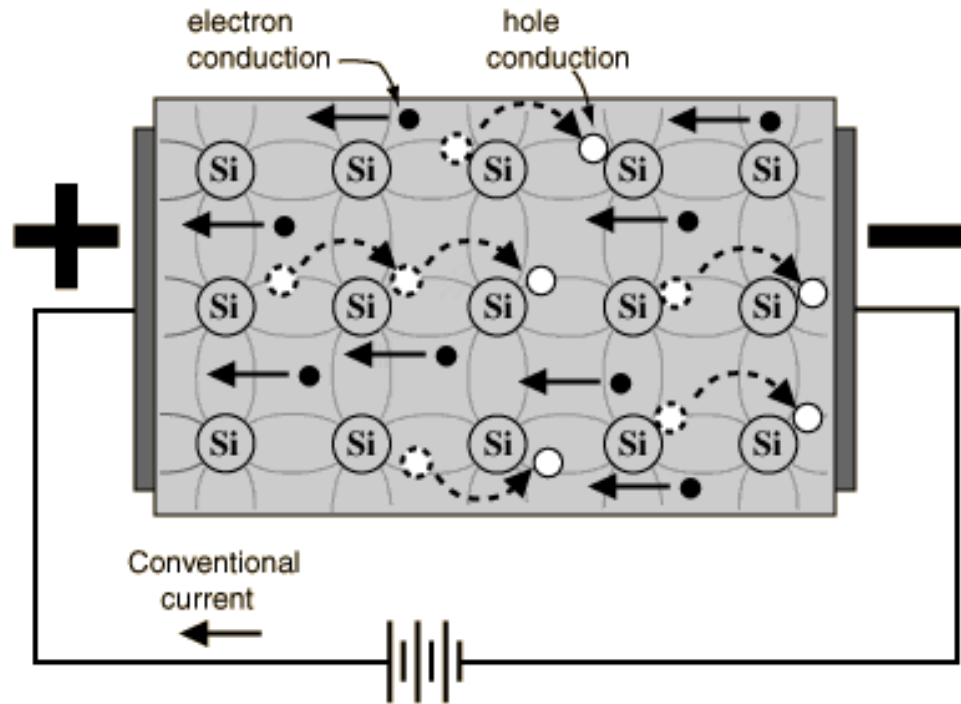
At any temperature above absolute zero temperature, there is a finite probability that an electron in the lattice will be knocked loose from its position.

Intrinsic Silicon



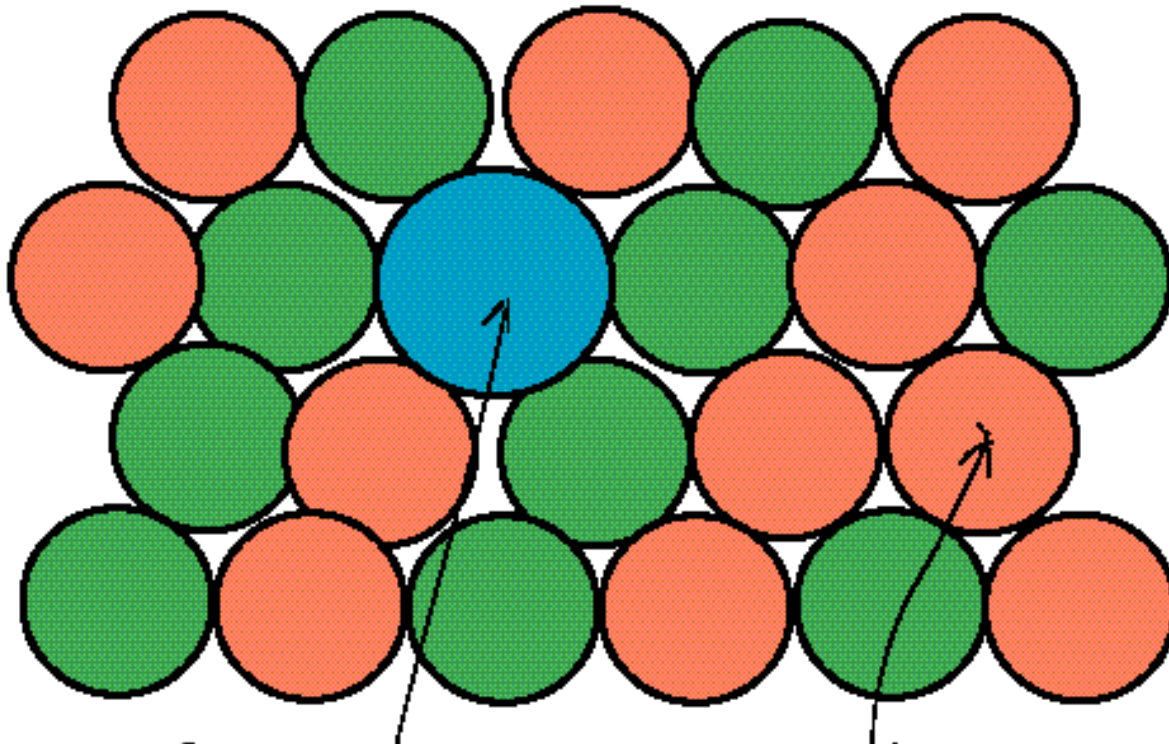
The electron in the lattice knocked loose from its position leaves behind an electron deficiency called a "hole".

Current Flow

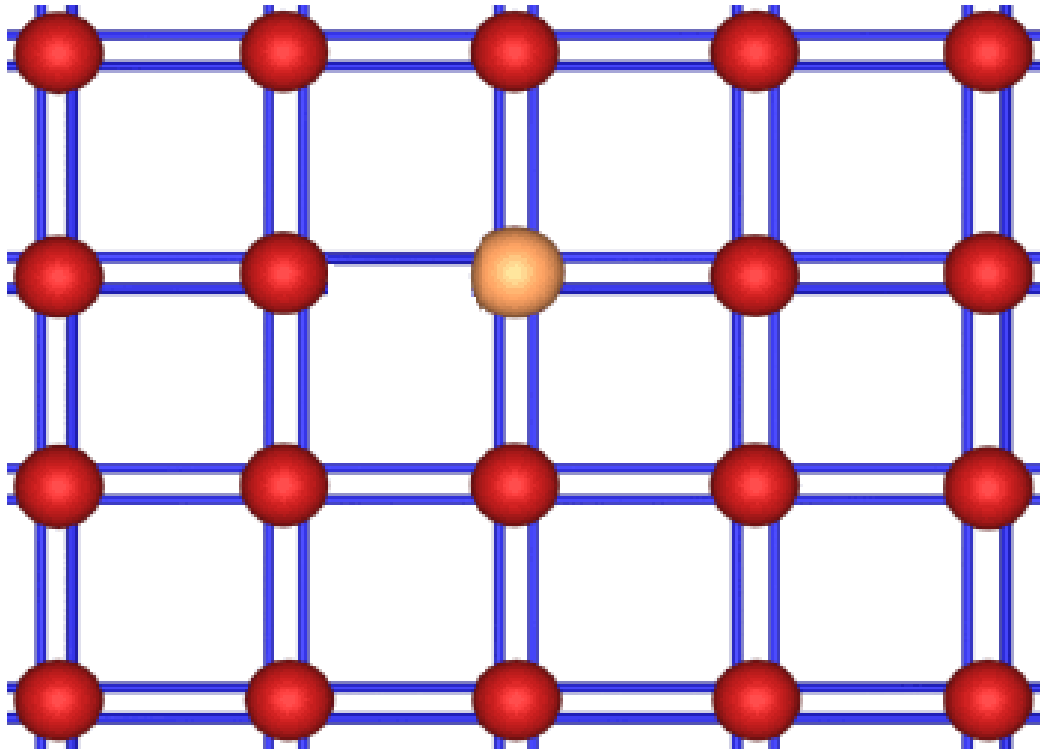


If a voltage is applied, then both the electron and the hole can contribute to a small current flow.

Impurity

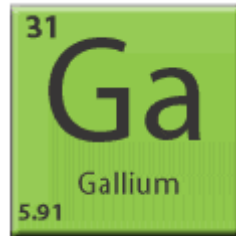
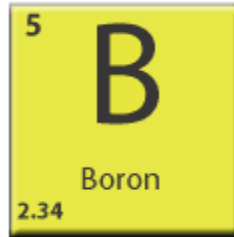


Doping



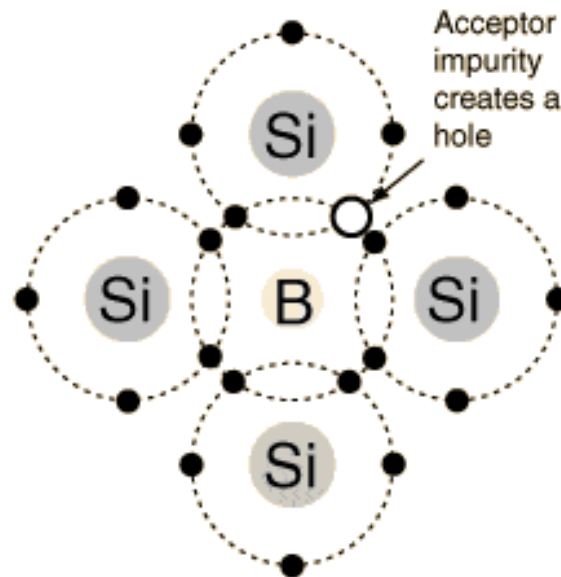
Doping (adding an impurity) can produce 2 types of semi-conductors depending upon the element added.

P-Type Doping



In P-type doping, boron or gallium is the dopant.

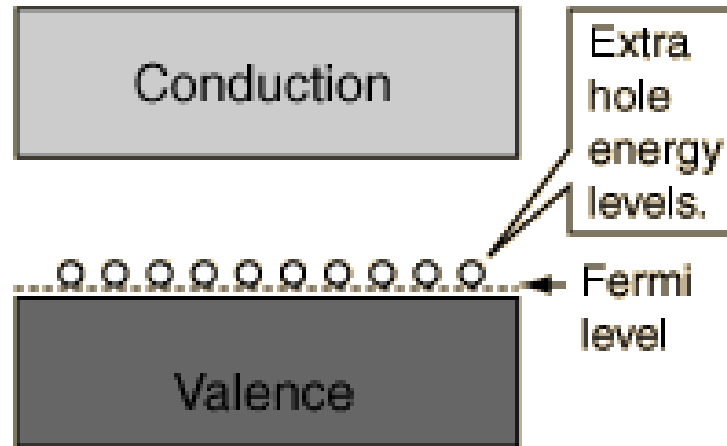
P-Type Doping



Boron and gallium each have only three outer electrons.

When mixed into the silicon lattice, they form "holes" in the lattice where a silicon electron has nothing to bond to.

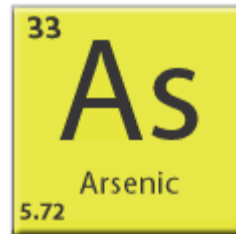
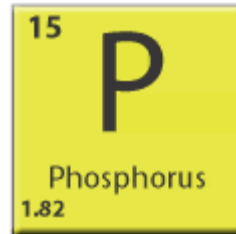
P-Type Doping



The absence of an electron creates the effect of a positive charge, hence the name P-type.

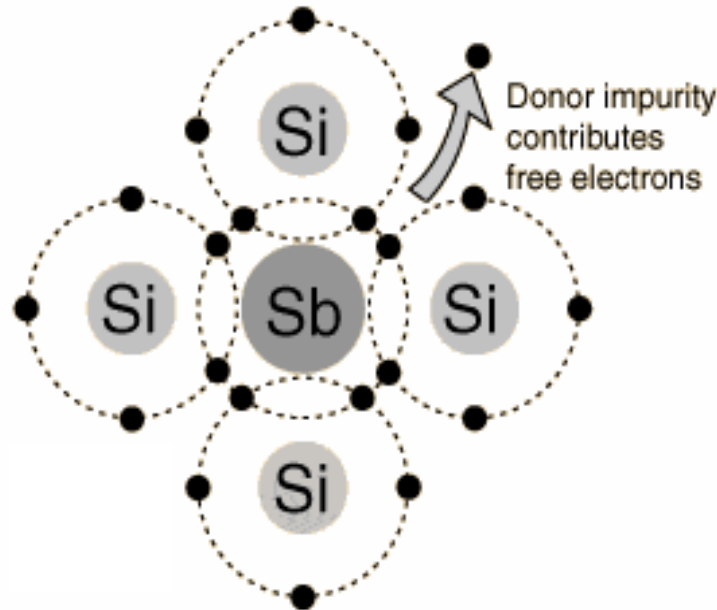
Holes can conduct current. A hole happily accepts an electron from a neighbor, moving the hole over a space. P-type silicon is a good conductor.

N-Type



In N-type doping, phosphorus or arsenic is added to the silicon in small quantities.

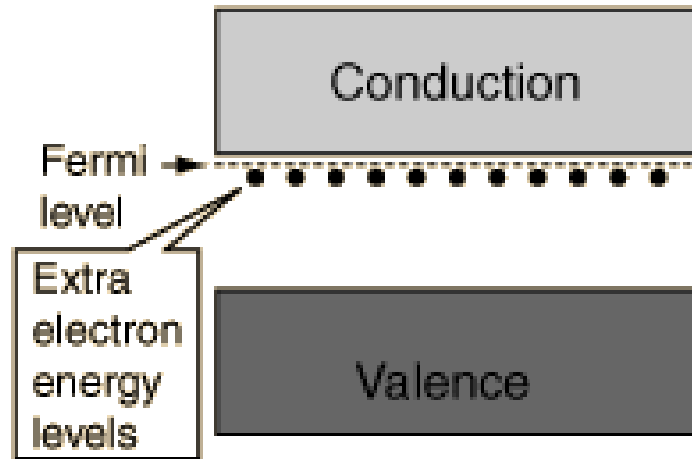
N-Type



Phosphorus and arsenic each have five outer electrons, so they're out of place when they get into the silicon lattice.

The fifth electron has nothing to bond to, so it's free to move around.

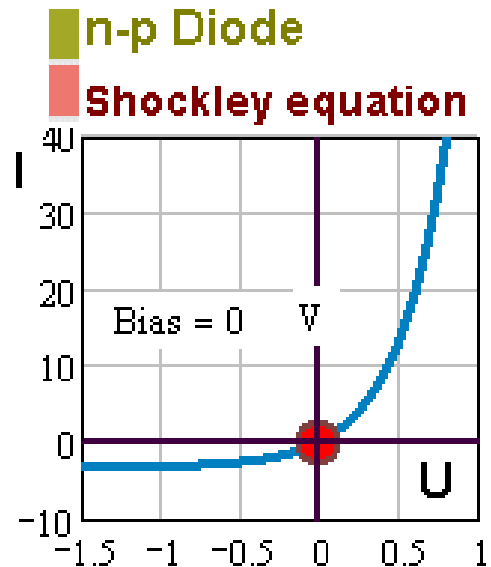
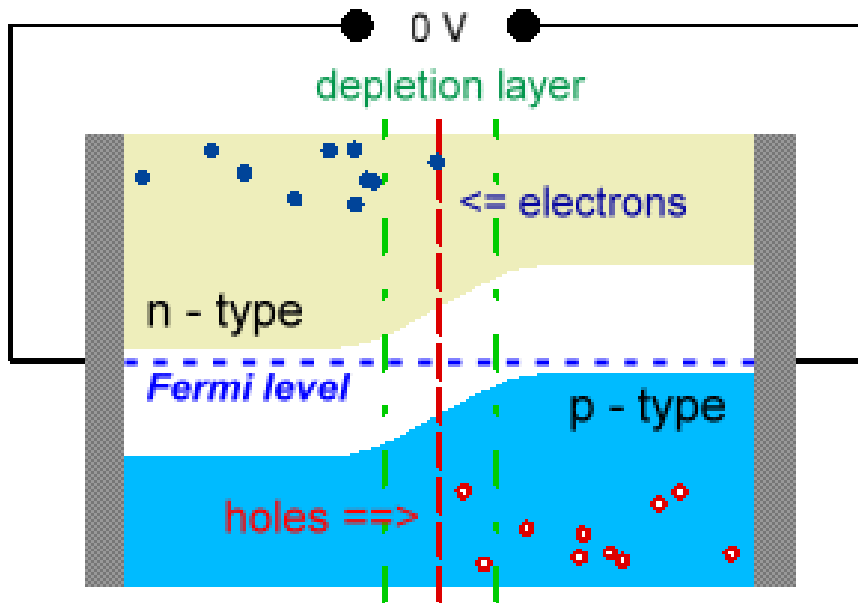
N-Type



It takes only a very small quantity of the impurity to create enough free electrons to allow an electric current to flow through the silicon. N-type silicon is a good conductor.

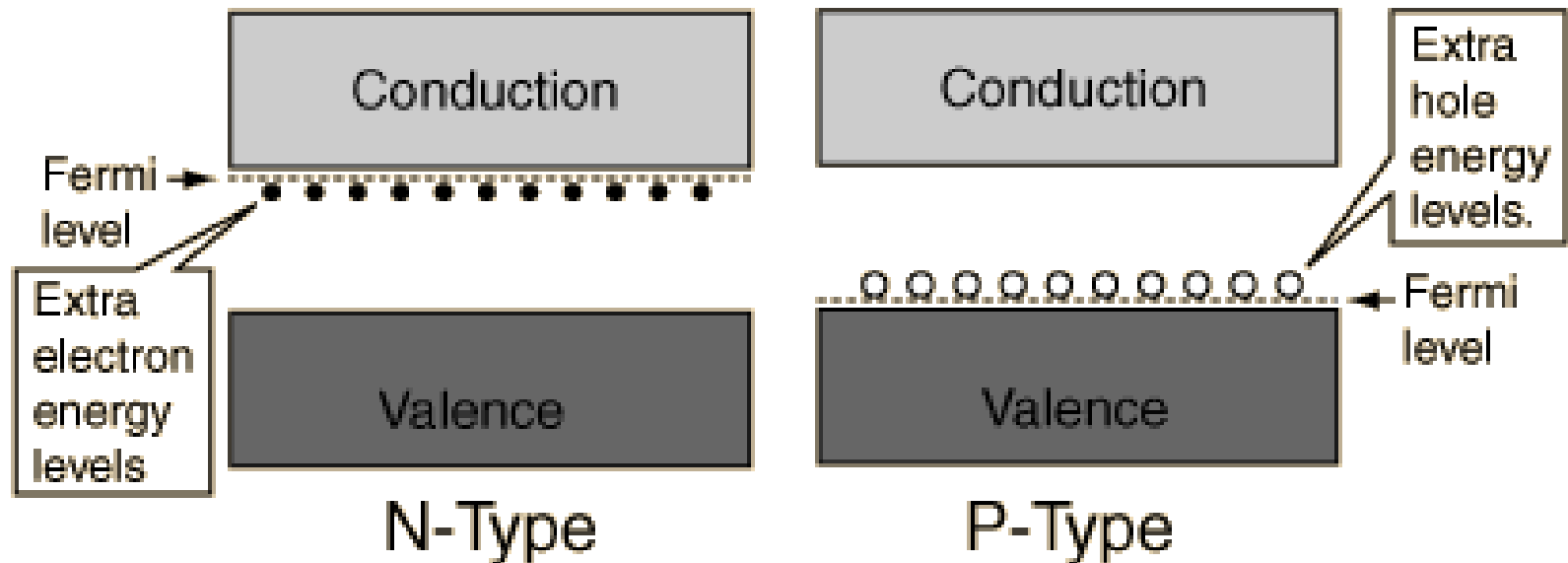
Electrons have a negative charge, hence the name N-type.

P-N Junction



We create a p-n junction by joining together two pieces of semiconductor, one doped n-type, the other p-type.

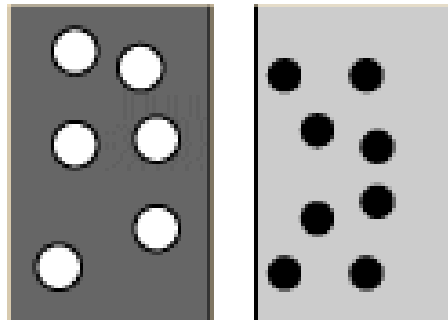
P-N Junction



In the n-type region there are extra electrons and in the p-type region, there are holes from the acceptor impurities .

P-N Junction

In the p-type region there are holes from the acceptor impurities and in the n-type region there are extra electrons.



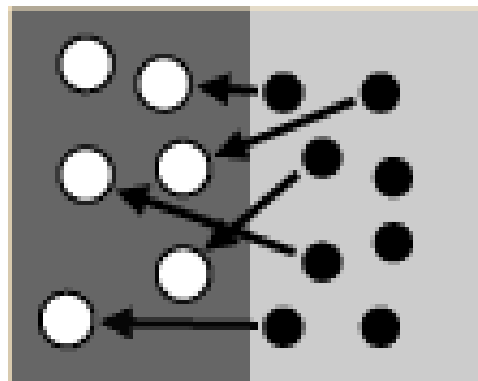
● Electron ○ Hole

⊖ Negative ion from
filling of p-type
vacancy.

⊕ Positive ion from
removal of electron
from n-type impurity.

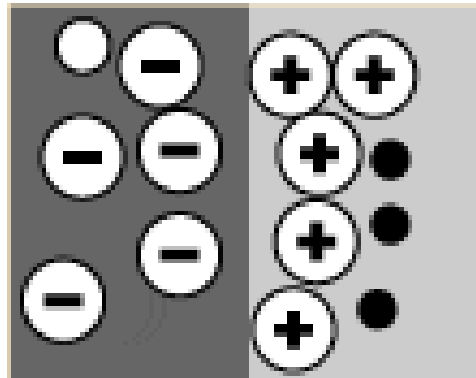
P-N Junction

When a p-n junction is formed, some of the electrons from the n-region which have reached the conduction band are free to diffuse across the junction and combine with holes.



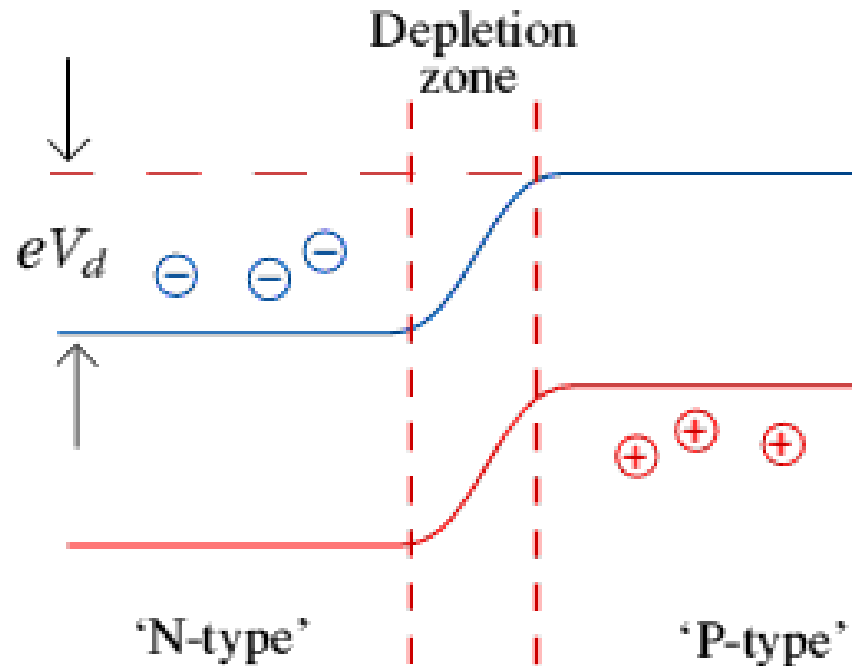
P-N Junction

Filling a hole makes a negative ion and leaves behind a positive ion on the n-side.



A space charge builds up, creating a depletion region.

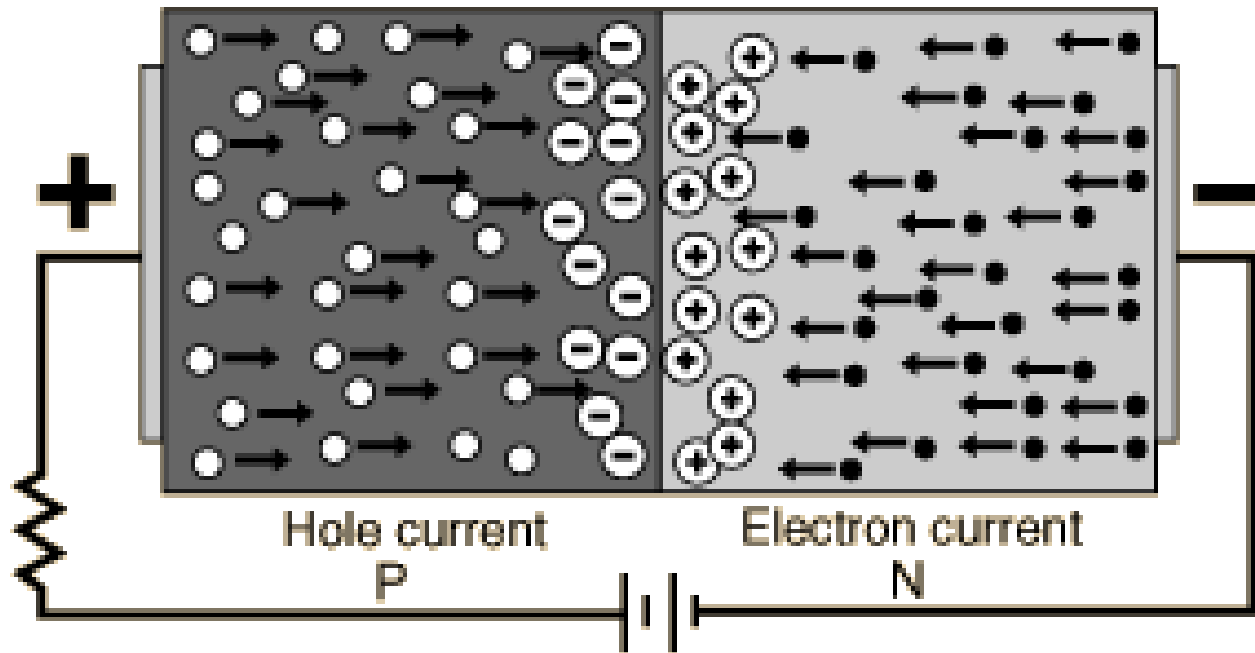
P-N Junction



This causes a depletion zone to form around the junction (the join) between the two materials.

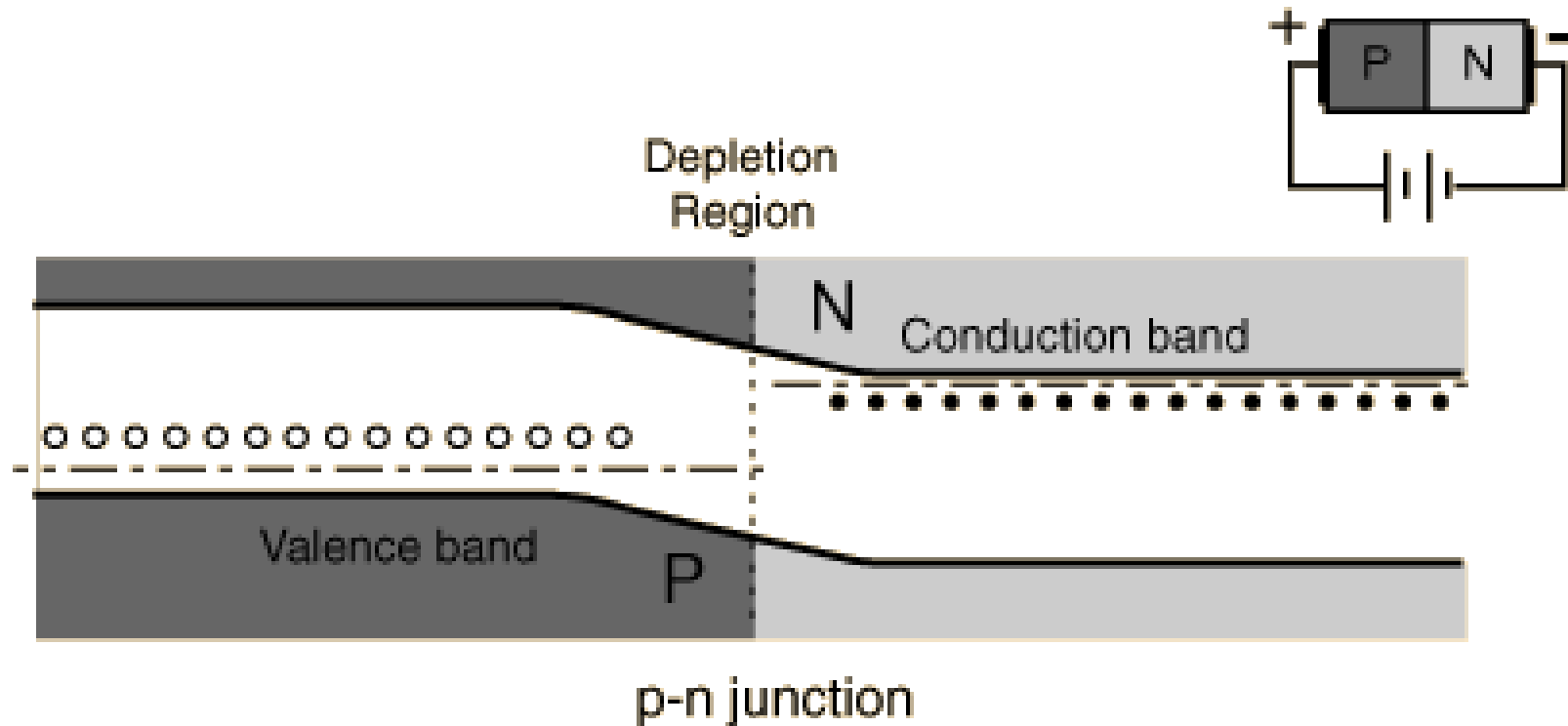
This zone controls the behavior of the diode.

Forward Biasing



Forward biasing the p-n junction drives holes to the junction from the p-type material and electrons to the junction from the n-type material.

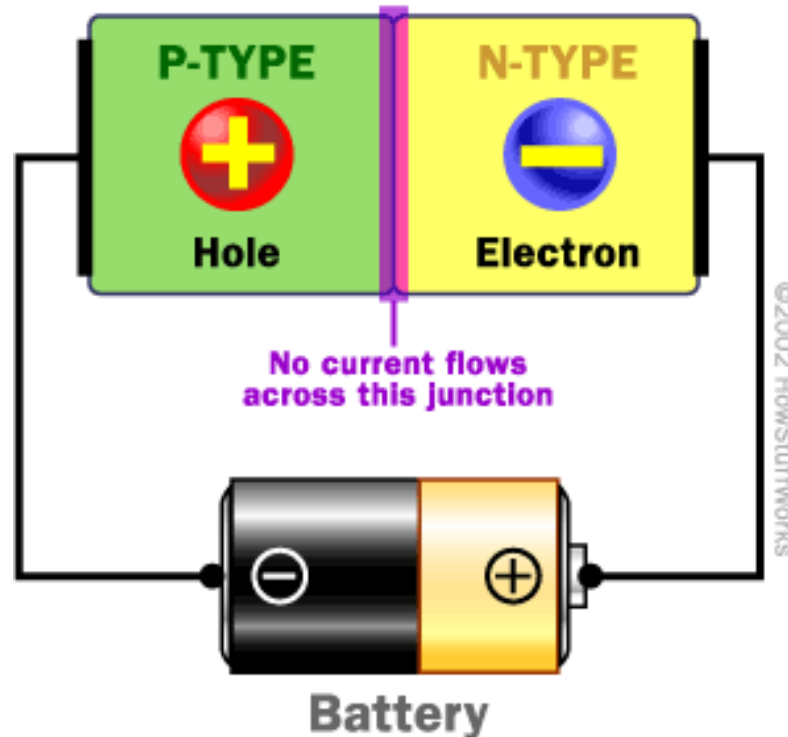
Forward Biasing



At the junction the electrons and holes combine so that a continuous current can be maintained.

Diode

DIODE



A diode is the simplest possible semiconductor device.

One Way Electric “Turnstile”



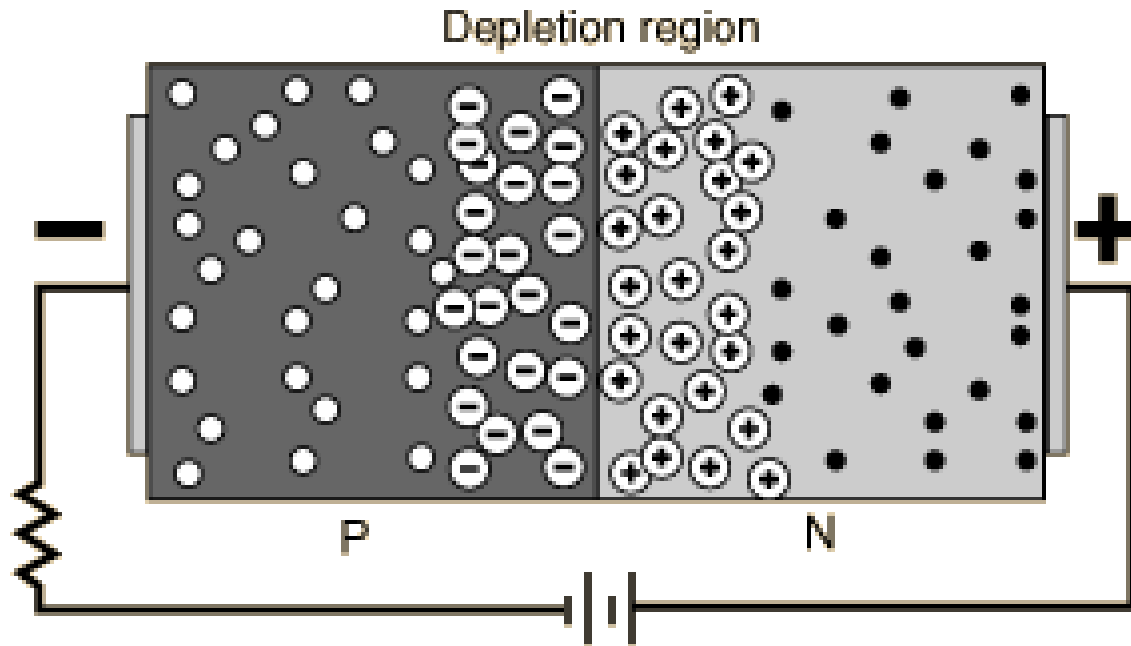
A diode allows current to flow in one direction but not the other.

Jumping



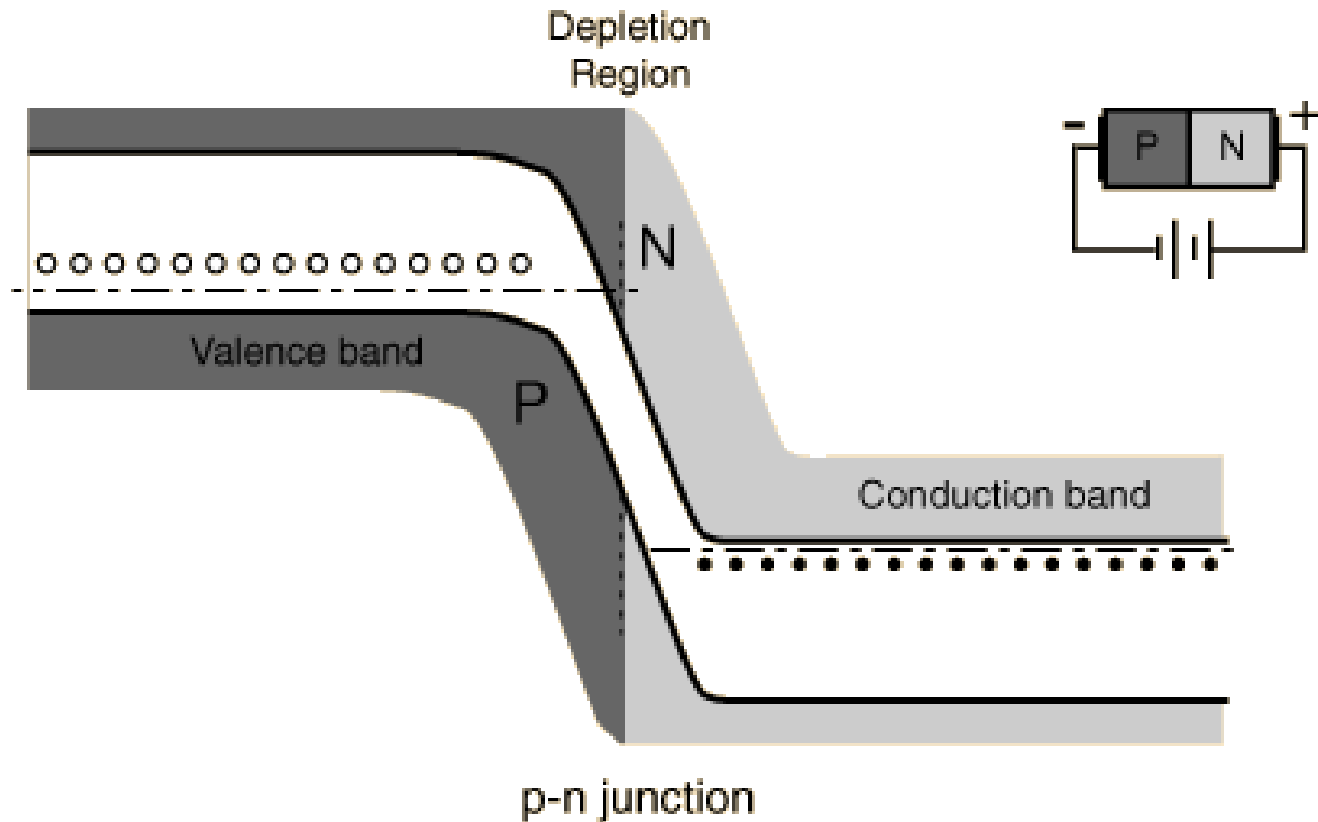
If you apply enough reverse voltage, the junction breaks down and lets current through.

Reverse Biasing



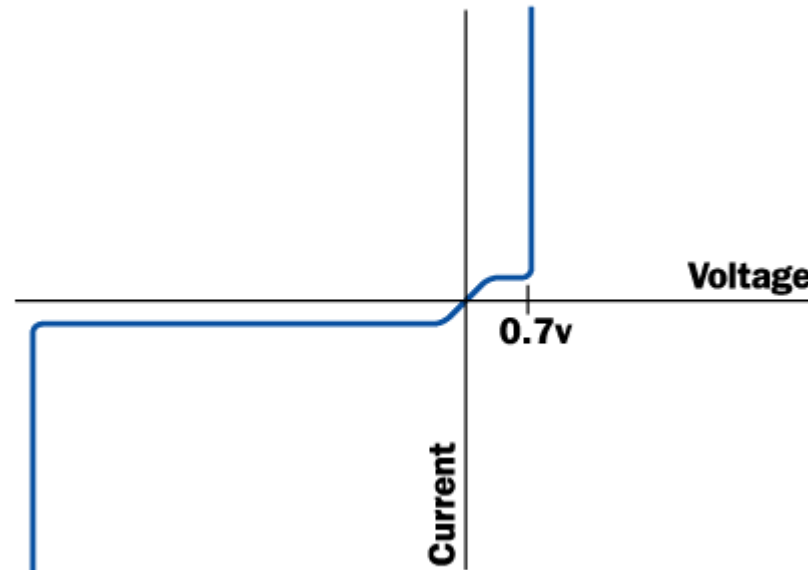
The application of a reverse voltage to the p-n junction will cause a transient current to flow as both electrons and holes are pulled away from the junction.

Reverse Biasing



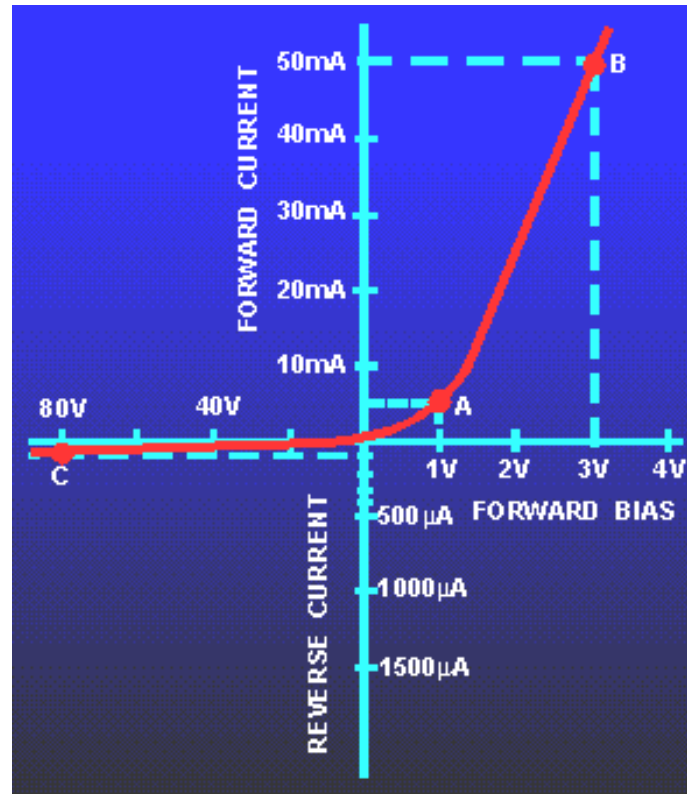
When the potential formed by the widened depletion layer equals the applied voltage, the current will cease except for the small thermal current.

When forward-biased, there is a small amount of voltage necessary to get the diode going. In silicon, this voltage is about 0.7 volts.



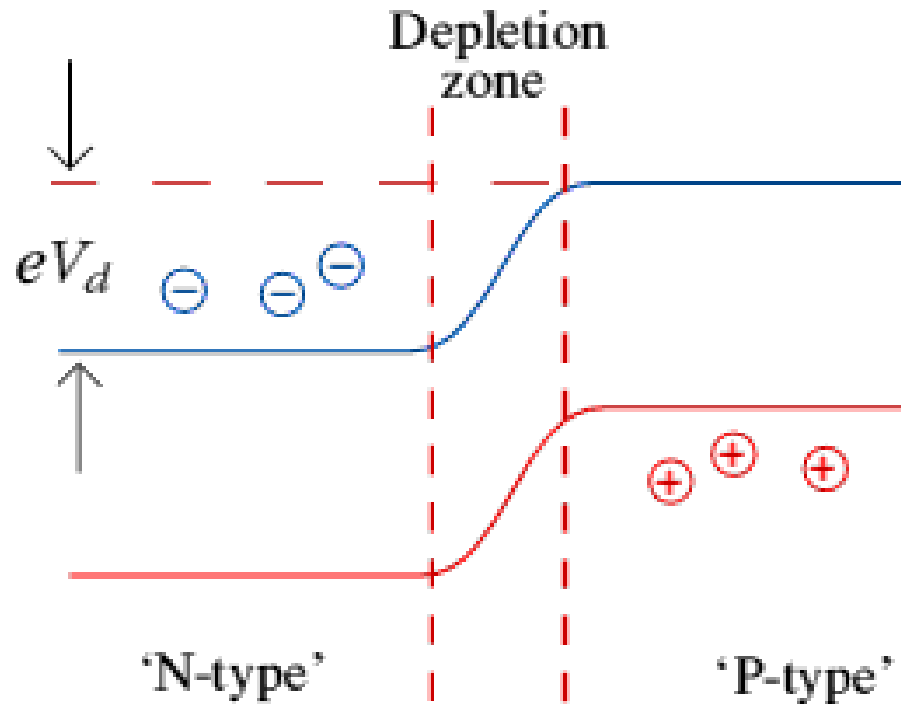
This voltage is needed to start the hole-electron combination process at the junction.

Diode Characteristic



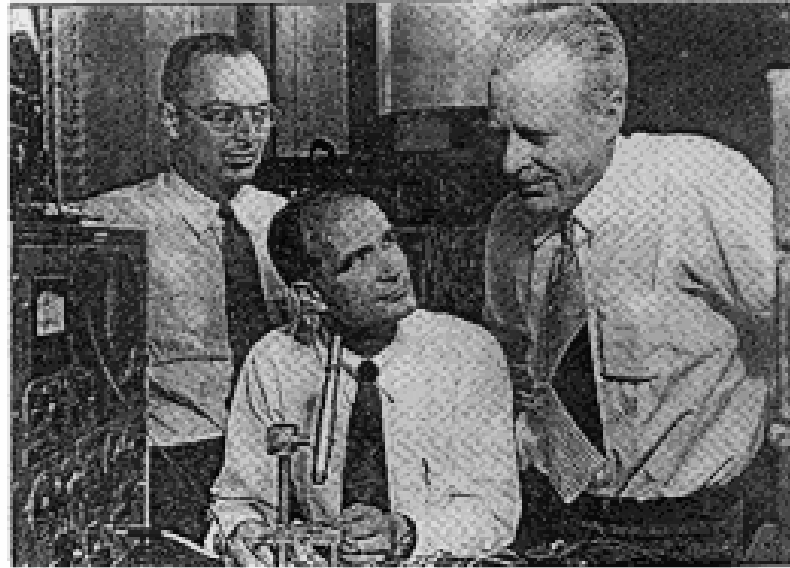
When reverse-biased, an ideal diode would block all current. A real diode lets perhaps 10 microamps through -- not a lot, but still not perfect.

Diode Characteristic



Usually, the breakdown voltage is a lot more voltage than the circuit will ever see, so it is irrelevant.

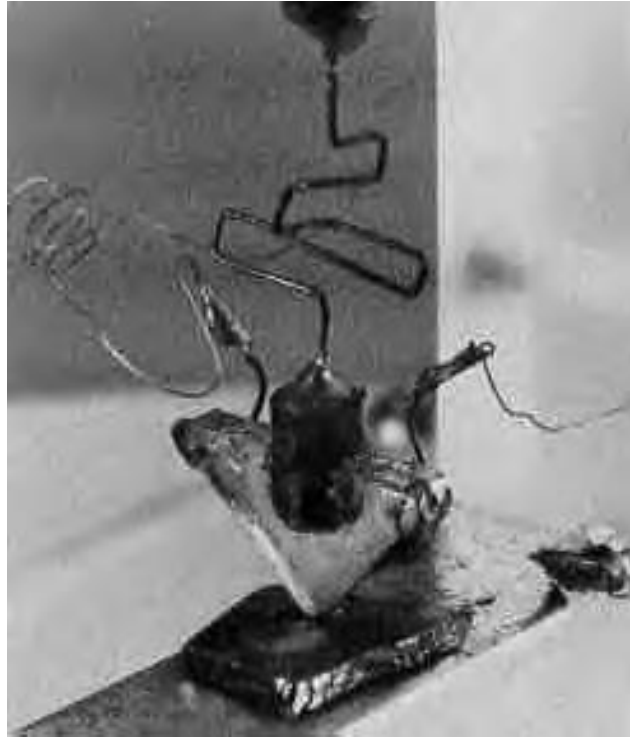
1947



John Bardeen, William Shockley and Walter Brattain

Working at Bell Telephone, they were trying to understand the nature of the electrons at the interface between a metal and a semiconductor (germanium).

First Transistor

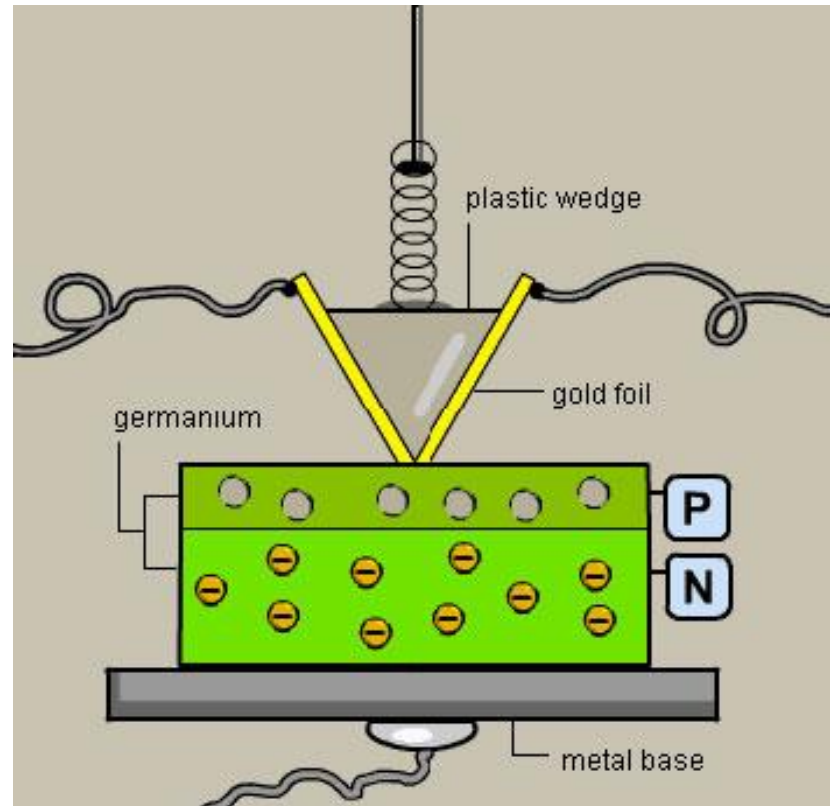


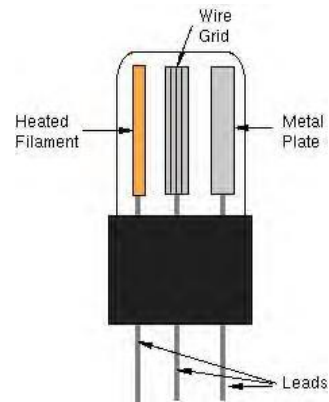
It consisted of a plastic triangle lightly suspended above a germanium crystal which itself was sitting on a metal plate attached to a voltage source.

A strip of gold was wrapped around the point of the triangle with a tiny gap cut into the gold at the precise point it came in contact with the germanium crystal.



The germanium acted as a semiconductor so that a small electric current entering on one side of the gold strip came out the other side as a proportionately amplified current.

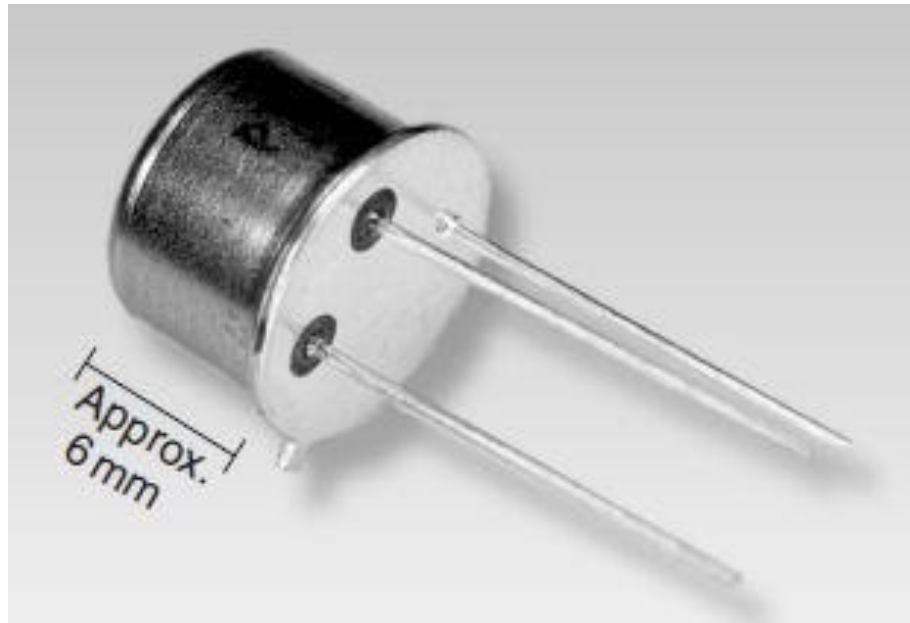




Transistors didn't need time to "warm up" like the heaters in vacuum tube circuits.

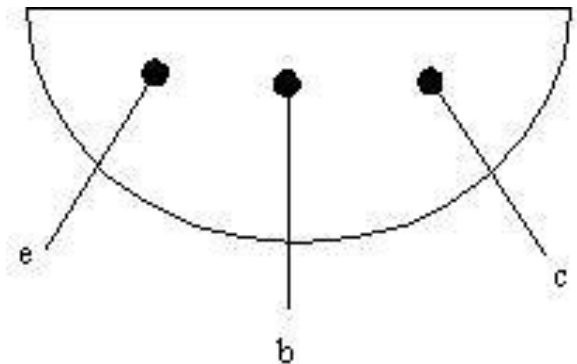
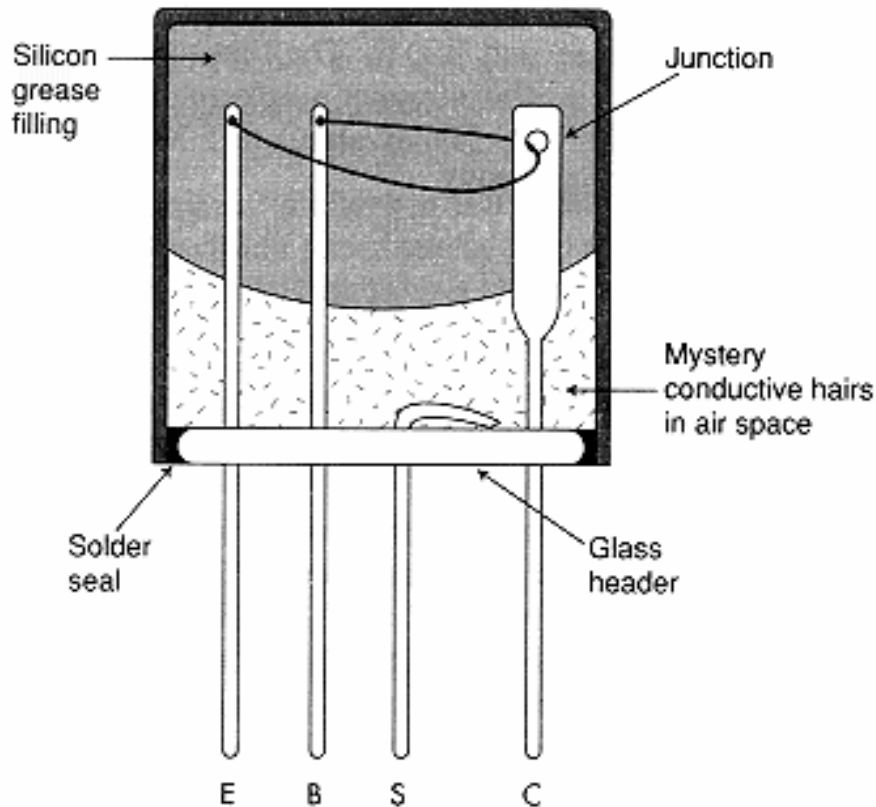


Transistor

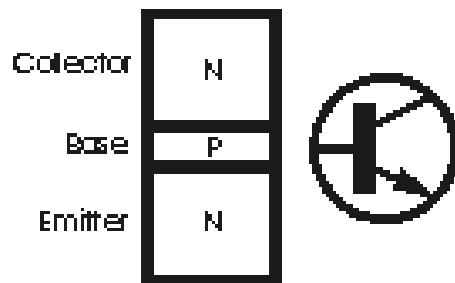


A transistor is a semiconductor device commonly used to amplify or switch electronic signals.

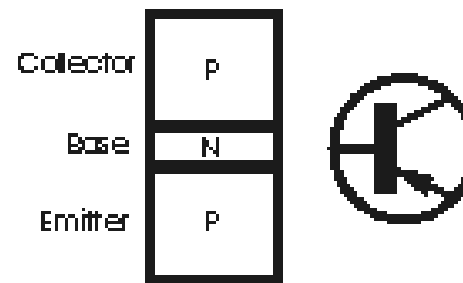
The transistor is a three terminal device and consists of three distinct layers.



Two of them are doped to give one type of semiconductor and the there is the opposite type, i.e. two may be n-type and one p-type, or two may be p-type and one may be n-type.



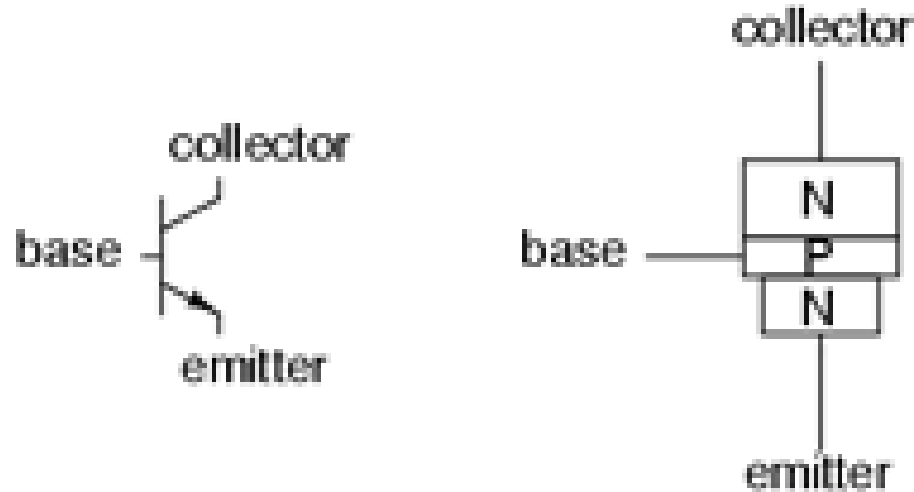
NPN Transistor



PNP Transistor

They are designated either P-N-P (PNP) types or N-P-N (NPN).

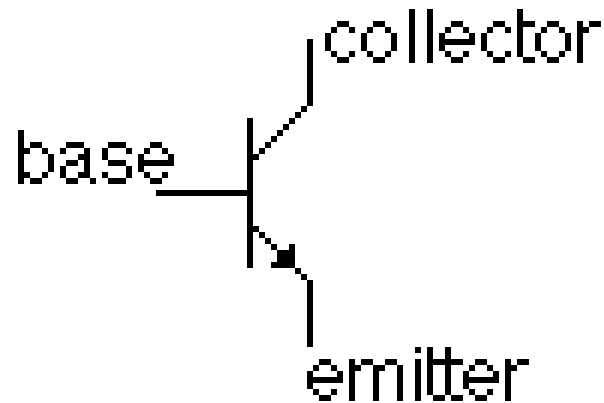
NPN transistor



schematic symbol

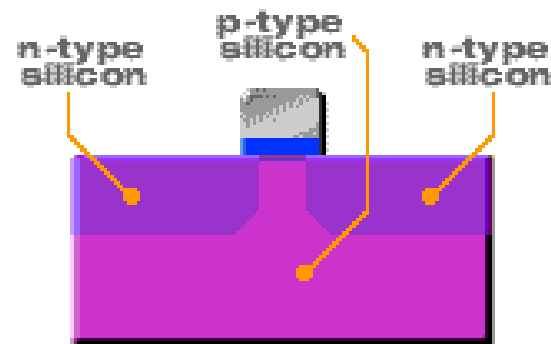
physical diagram

When discussing NPN transistors the N-Type semiconductor material on one side of the wafer is designated an emitter and it is most often connected to a negative electrical current.

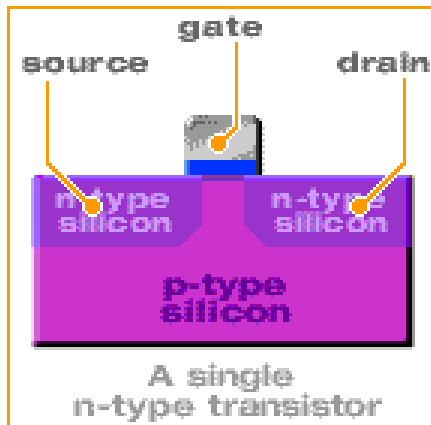


The P-Type material in the middle is the base.

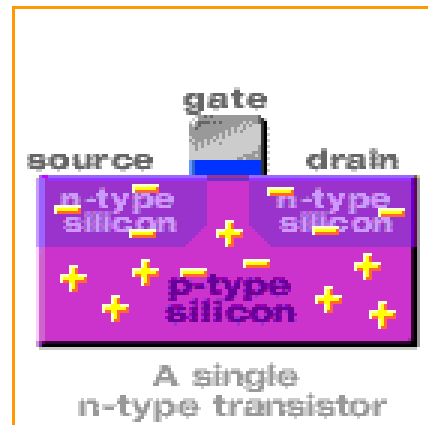
The N-Type material on the other side of the base is called the collector.



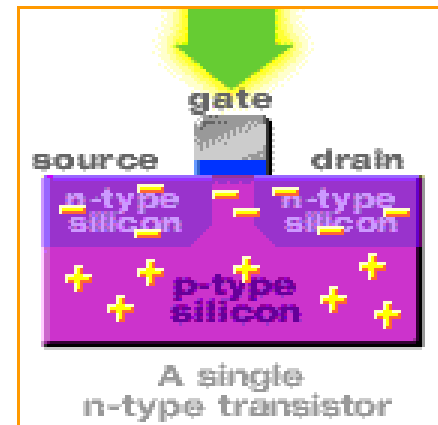
A single
n-type transistor



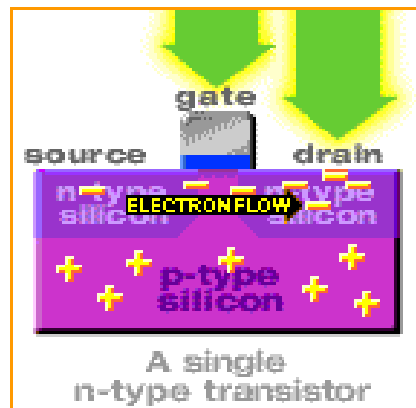
A single
n-type transistor



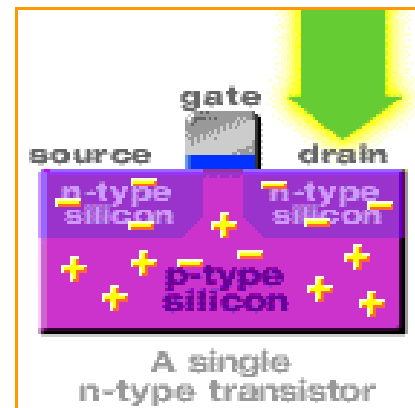
A single
n-type transistor



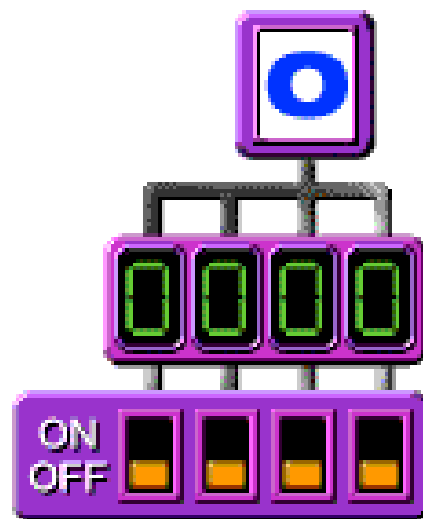
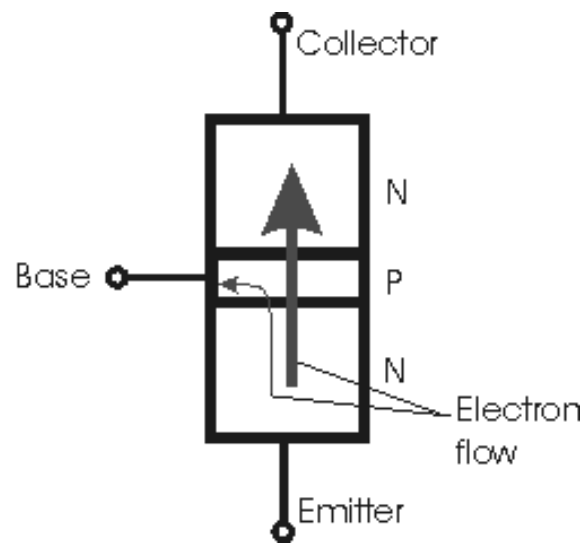
A single
n-type transistor



A single
n-type transistor



A single
n-type transistor



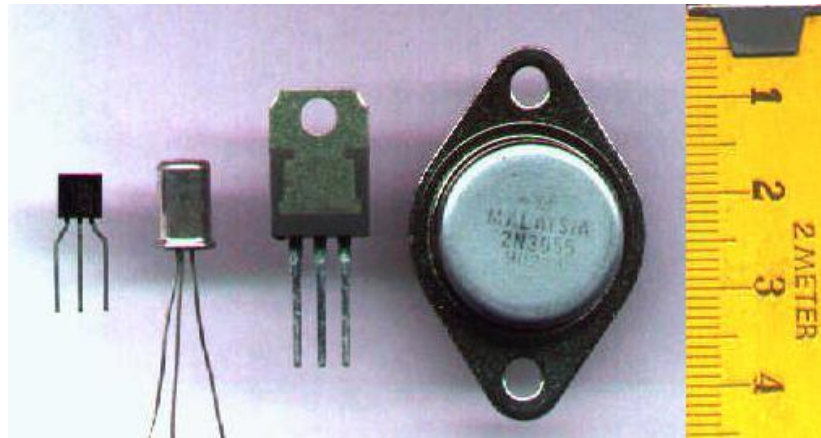
Transistor Advantages



***Highly automated manufacturing processes,
resulting in low per-unit cost.***

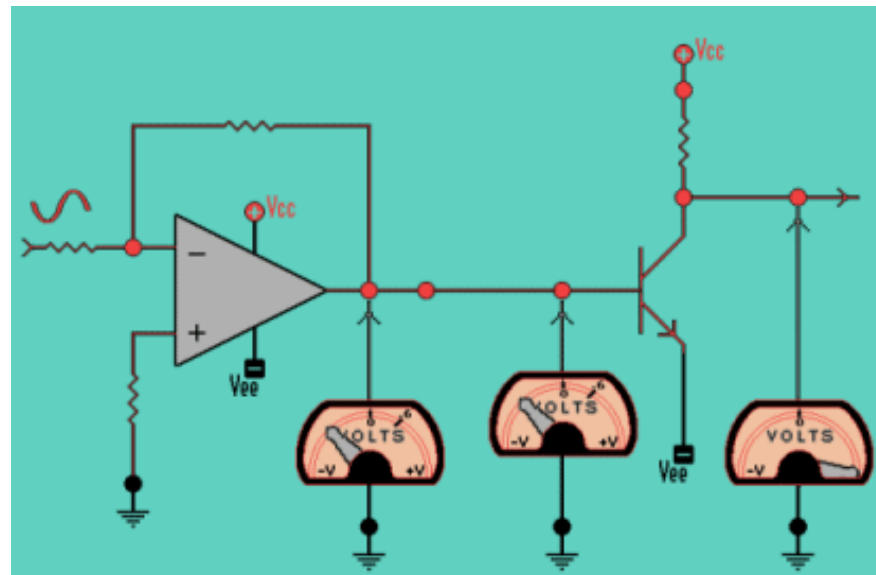
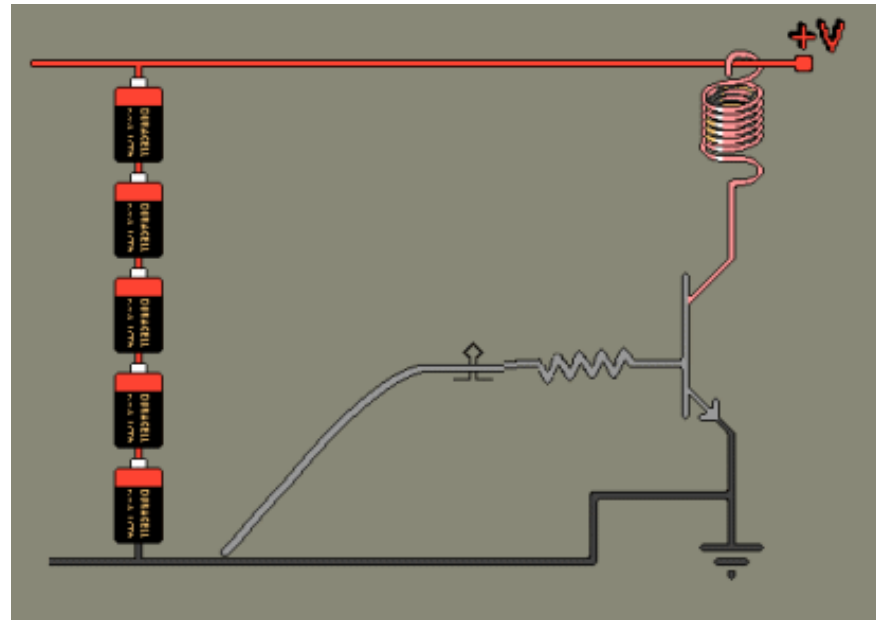
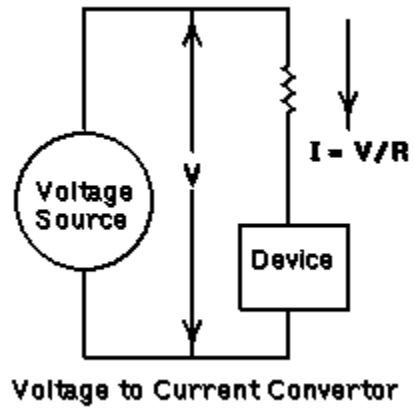
Extremely long life.

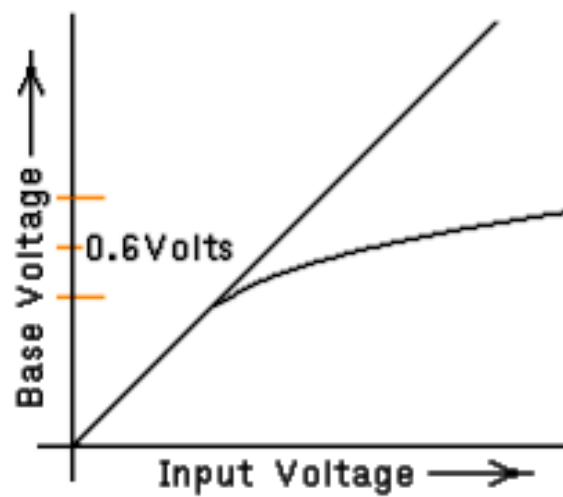
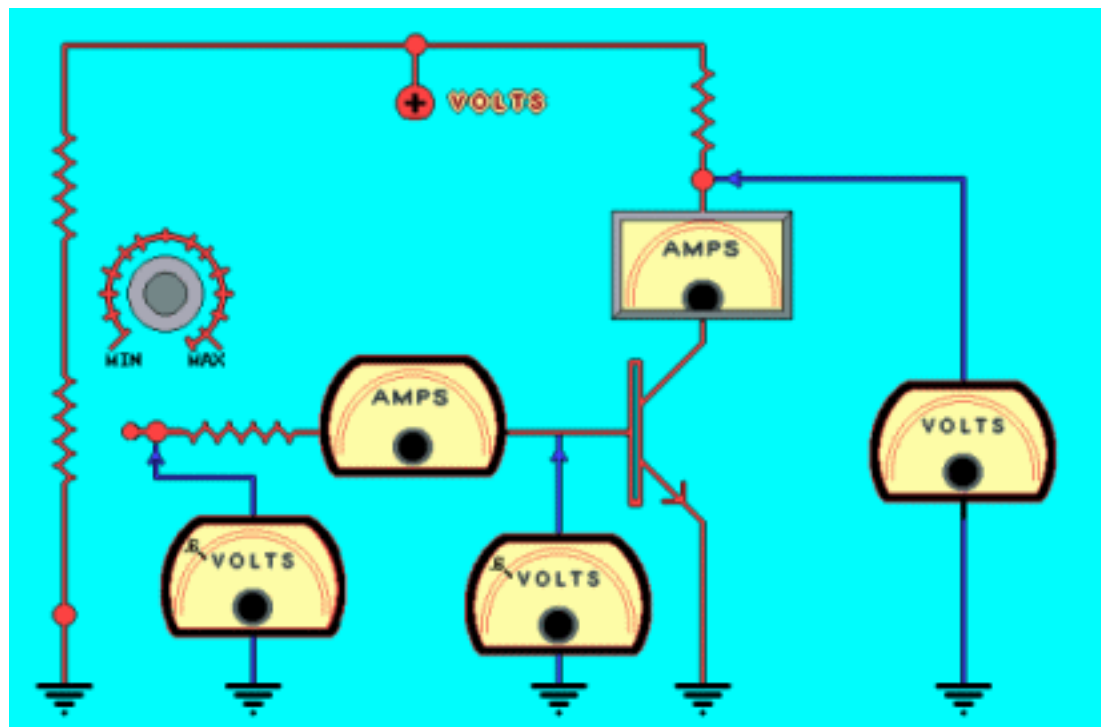
Higher reliability and greater physical ruggedness.



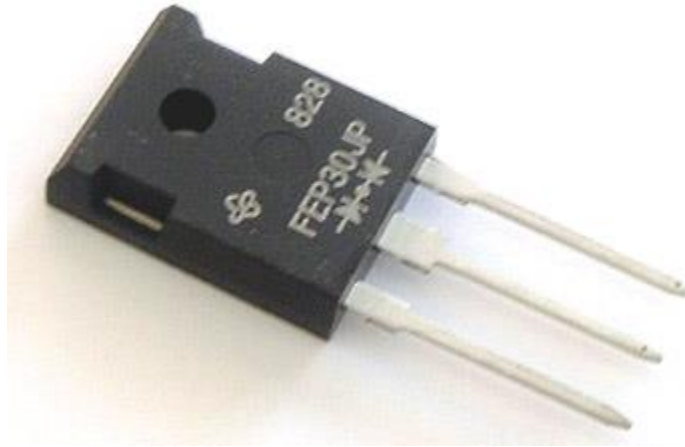
Small size and minimal weight, allowing the development of miniaturized electronic devices.

Lower possible operating voltages, making transistors suitable for small, battery-powered applications.





Rectifiers

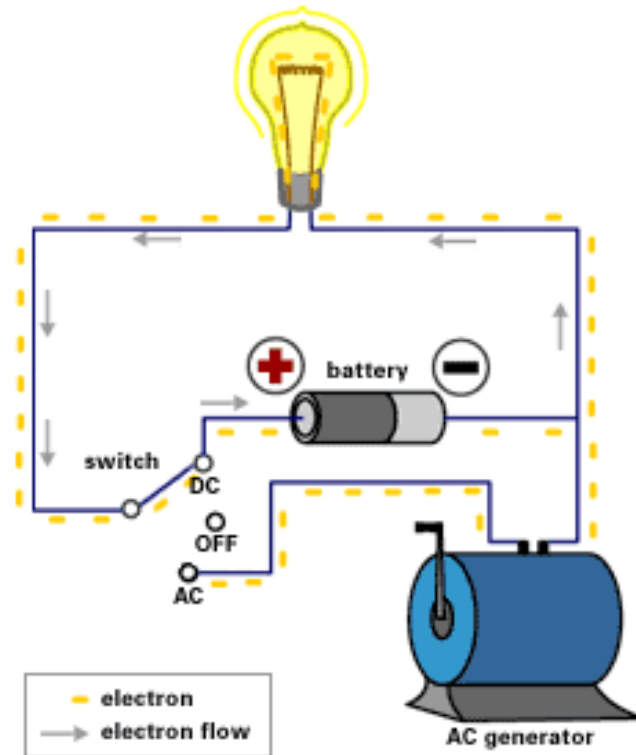
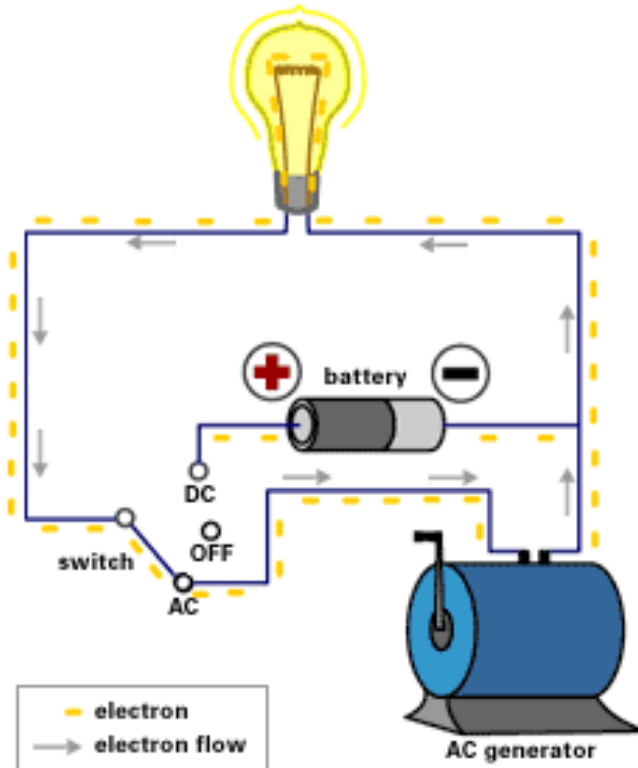


The most popular application of the diode.



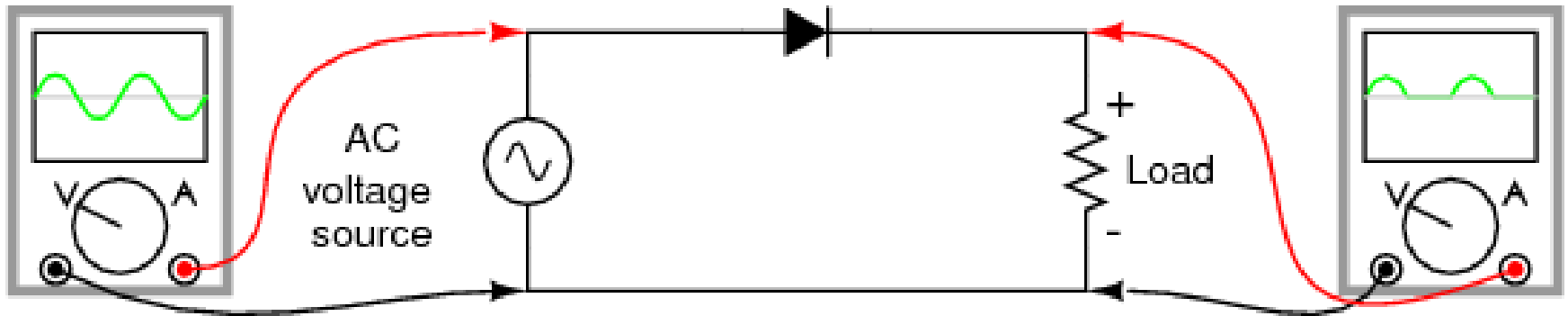
***Most electronics need a direct current to function,
but the standard form of electricity that is
transmitted to homes is alternating current.***

Rectifiers are needed to change the alternating current



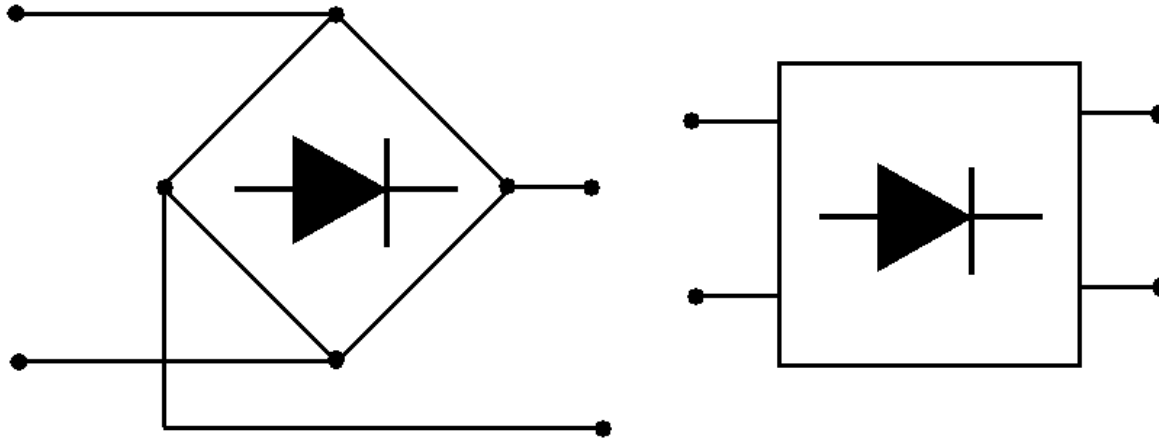
into direct current inside the electronics so that they can function correctly.

Rectification



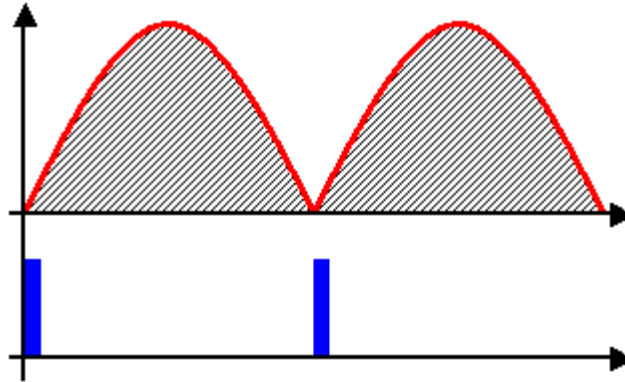
is the conversion of alternating current (AC) to direct current (DC).

Rectifiers



This involves a device that only allows one-way flow of electrons, which is exactly what a semiconductor diode does.

Half-Wave Rectifiers



The simplest kind of rectifier circuit is the half-wave rectifier.

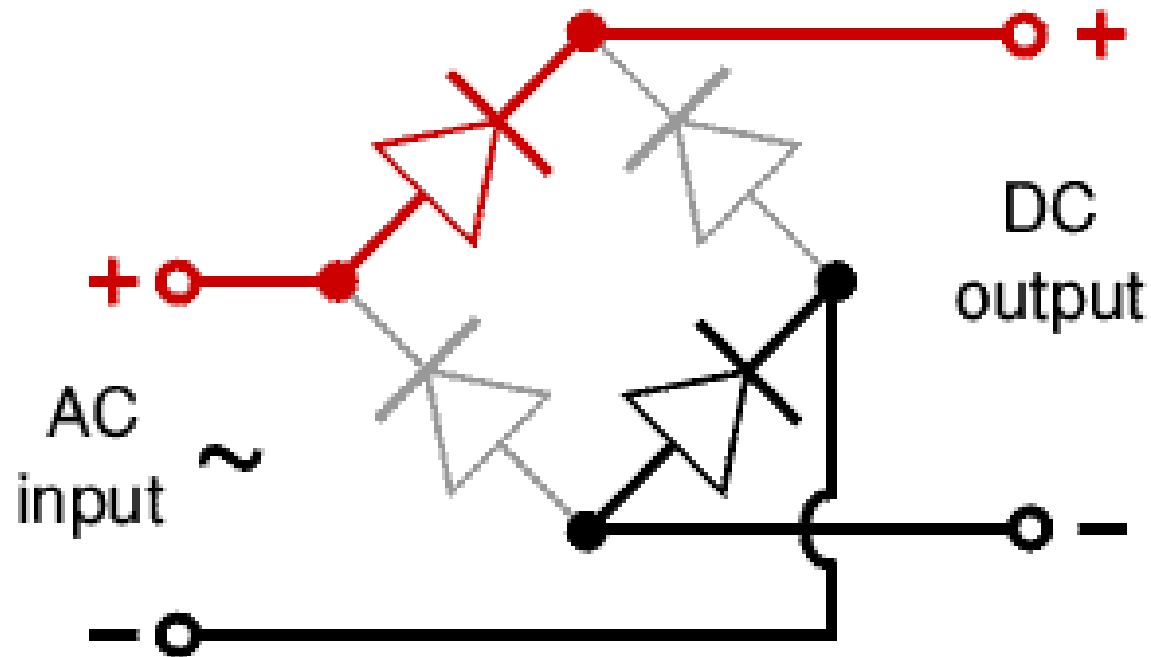
It only allows one half of an AC waveform to pass through to the load.

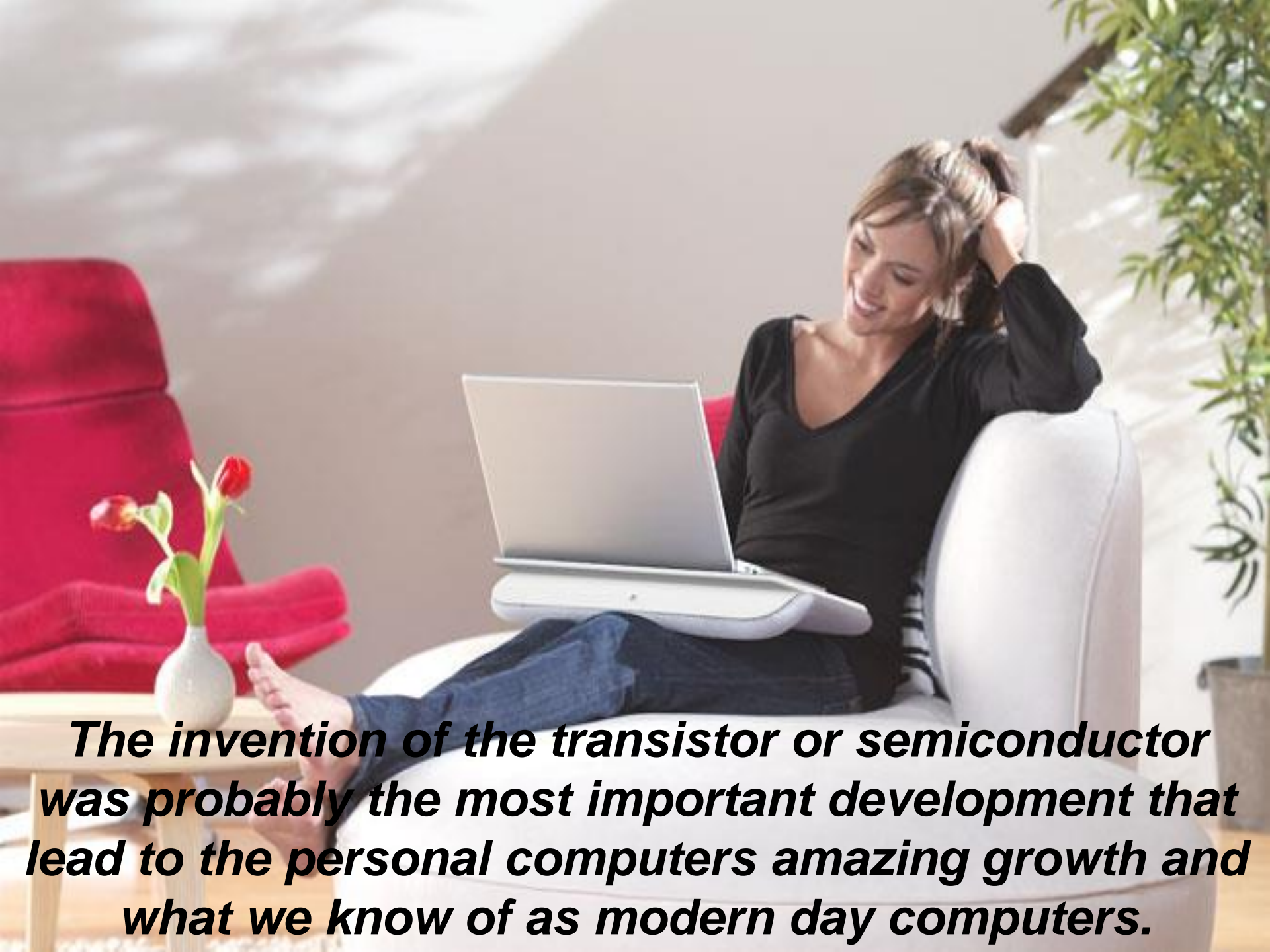
Half-wave rectification is a very simple way to reduce power to a resistive load.



Some two-position lamp dimmer switches apply full AC power to the lamp filament for “full” brightness and then half-wave rectify it for a lesser light output.

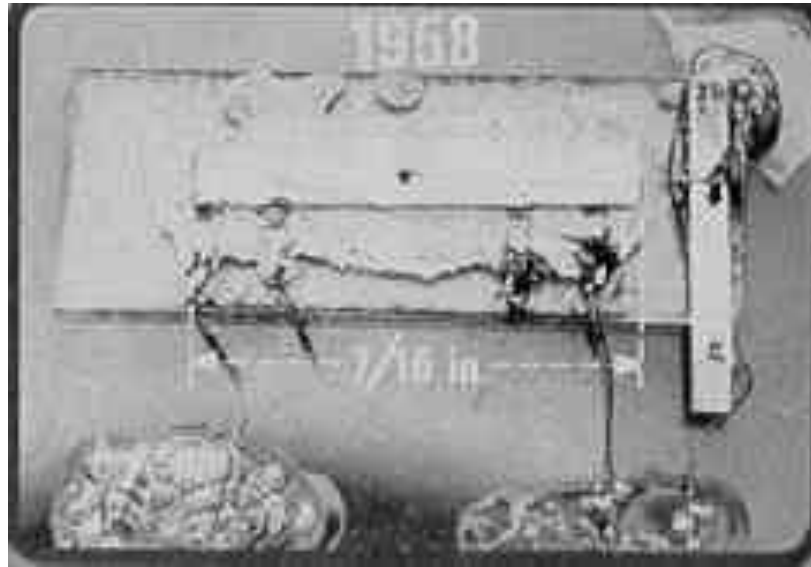
Bridge Rectifiers





The invention of the transistor or semiconductor was probably the most important development that lead to the personal computers amazing growth and what we know of as modern day computers.

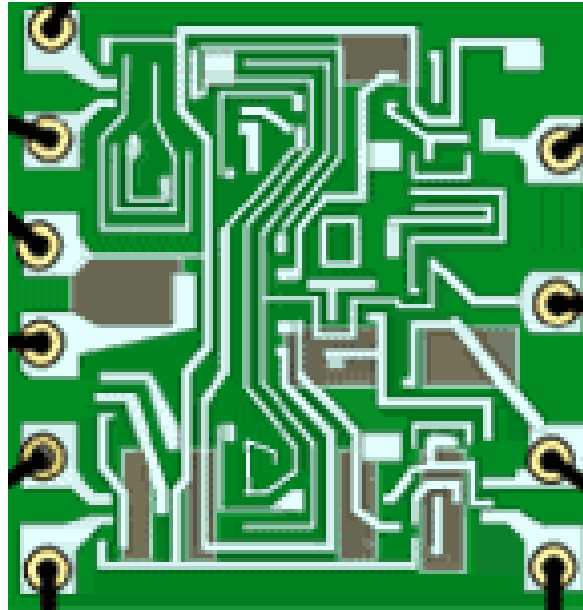
1959



The First I.C.

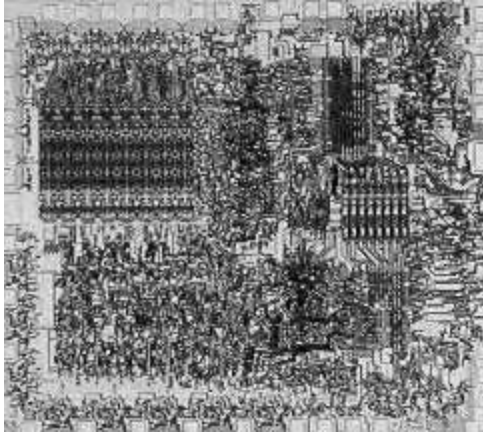
Jack Kilby at Texas Instruments and Robert Noyce at Fairchild Camera, came up with a solution to the problem of large numbers of components, and the integrated circuit was developed.

Instead of making transistors one-by-one, several transistors could be made at the same time, on the same piece of semiconductor(a silicon wafer).

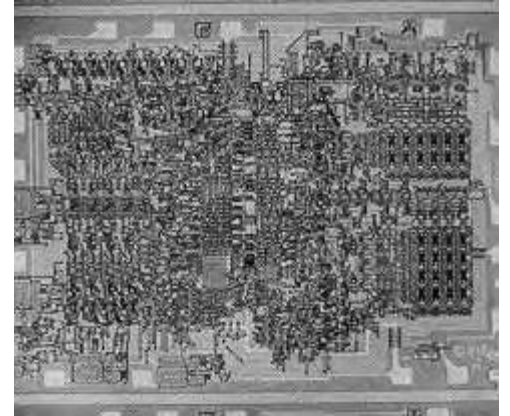


Not only transistors, but other electric components such as resistors, capacitors and diodes could be made by the same process with the same materials.

1970



4004	8080
4-bit unit	8-bit processor



First microprocessor invented at Intel.

First commercial MPU in 1975.

1981



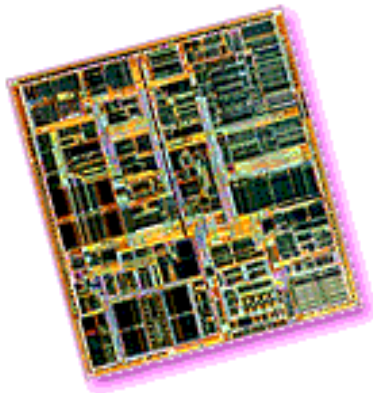
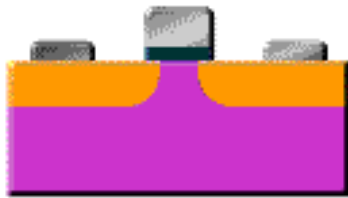
The IBM PC model 5150 was announced at a press conference in New York on August 12, 1981 and became available for purchase in early Fall 1981.



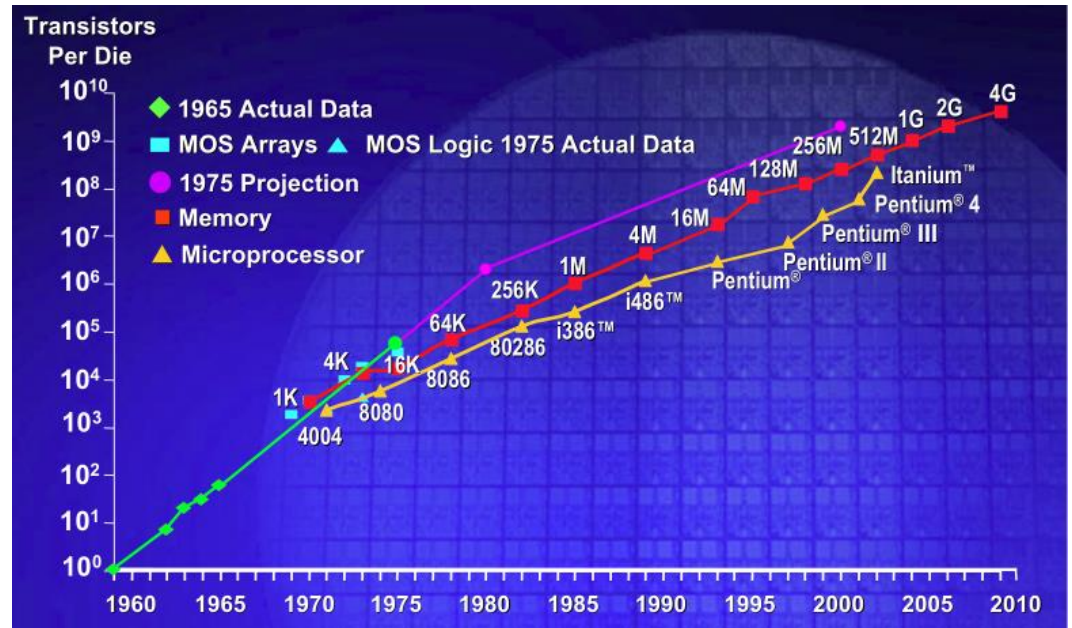
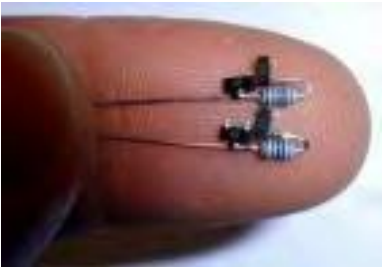
The base model retailed for \$2880!

This included 64 kilobytes of RAM and a single-sided 160K 5.25" floppy drive.

The IBM PC was powered by a 4.77 MHz Intel 8088 processor.



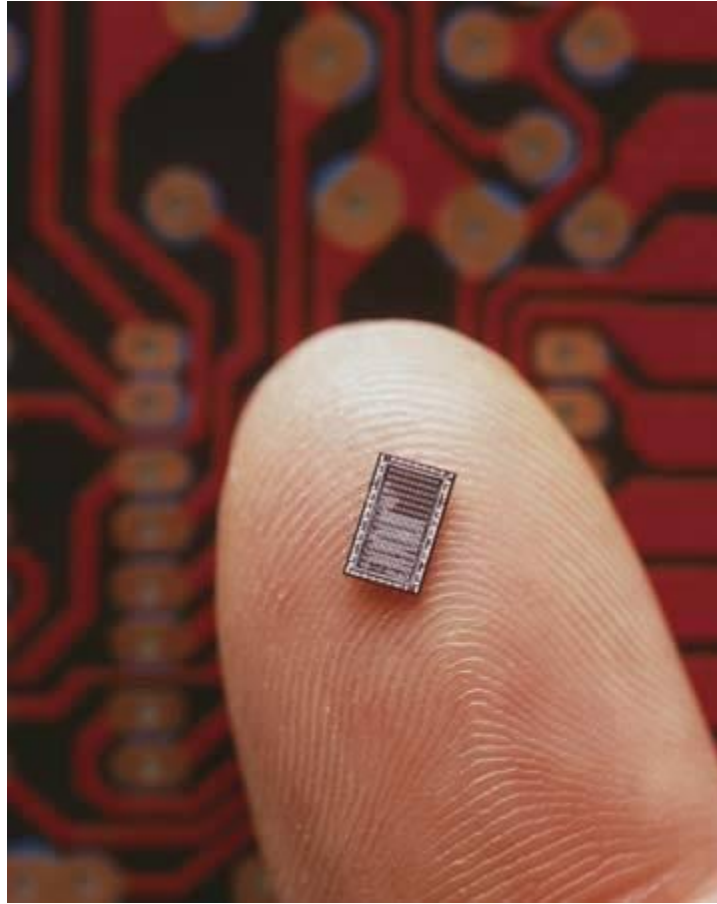
Trends in Semiconductors



Smaller Transistors

Higher Switching Speeds

Declining Costs



The semiconductor industry has been successful in its consistent efforts to reduce feature size on a chip.

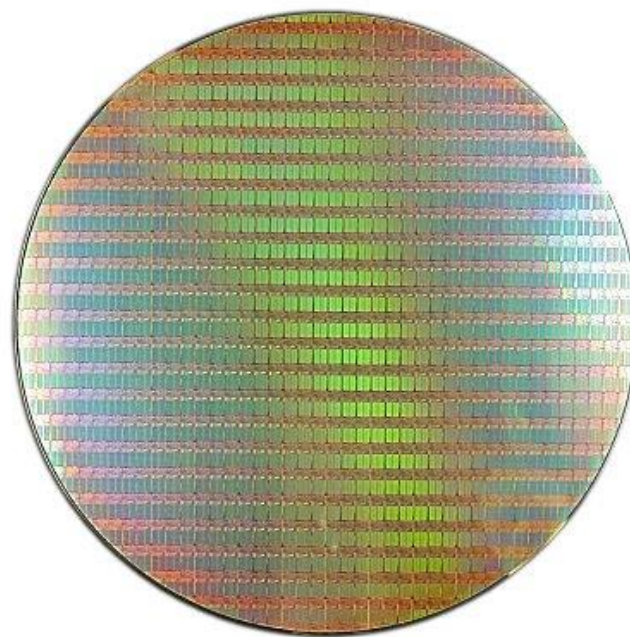


55,000,000 transistors

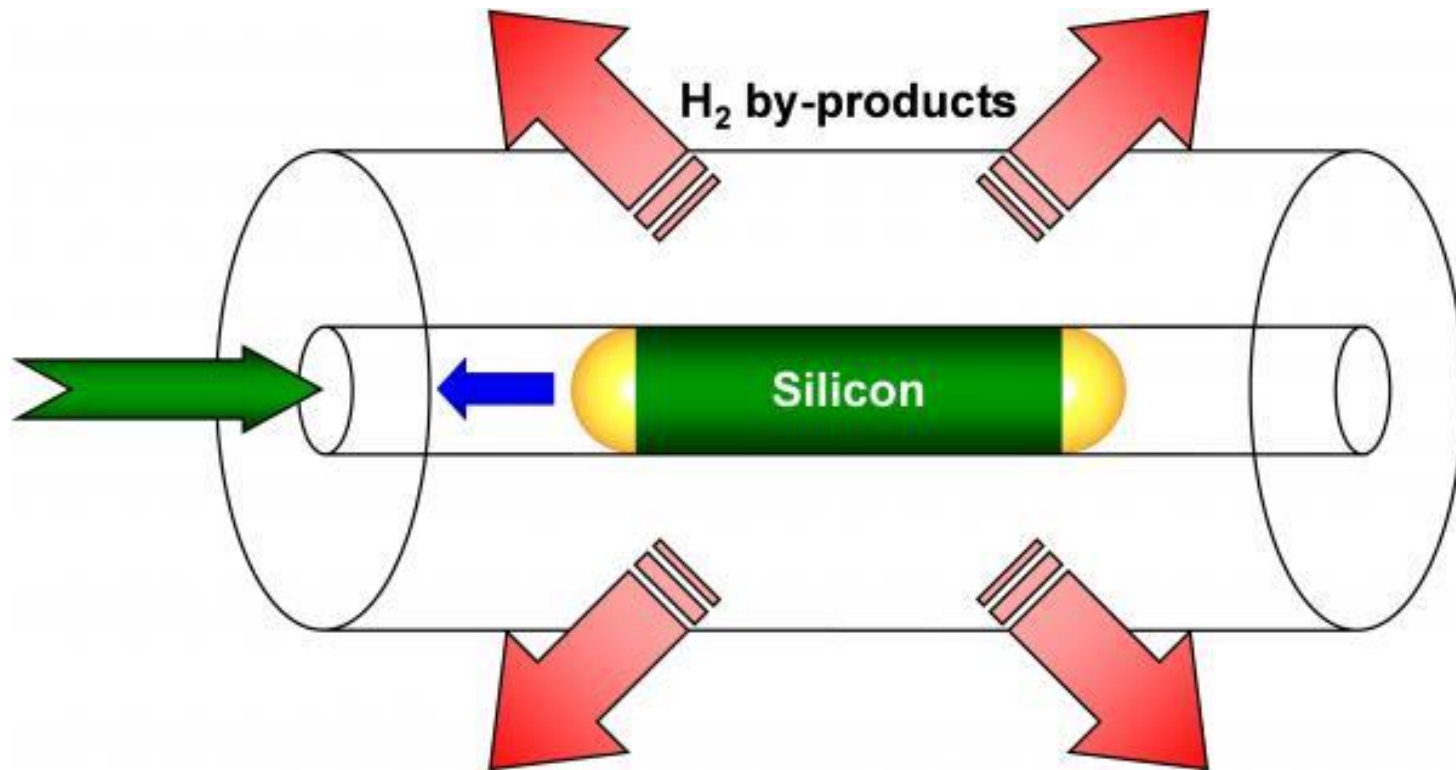


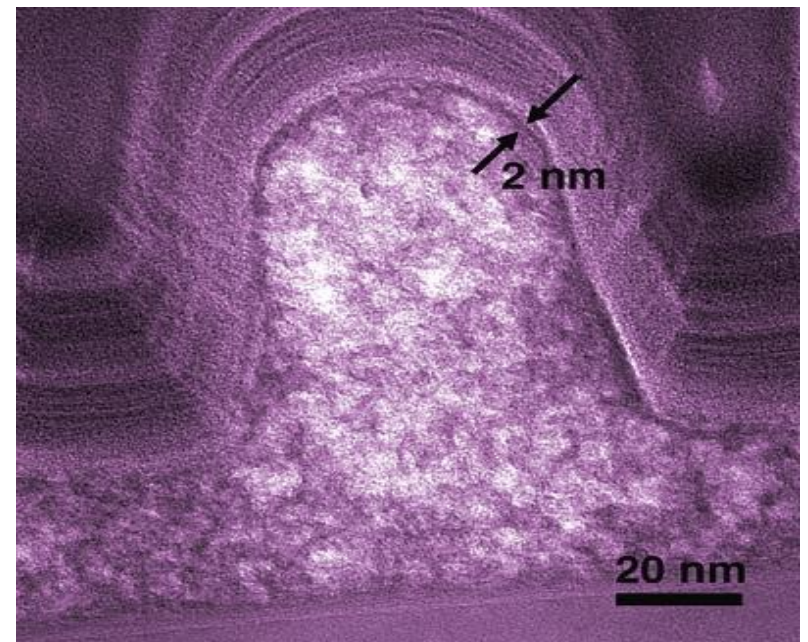
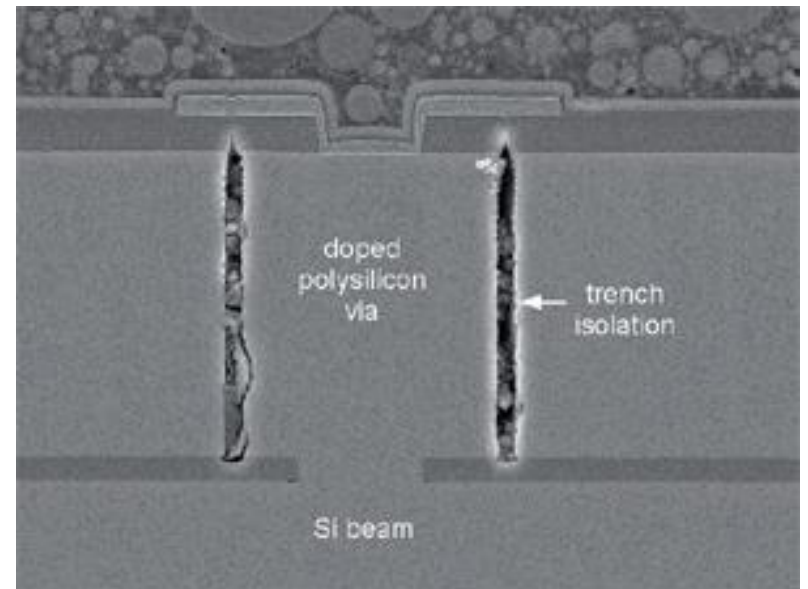
105,900,000 transistors

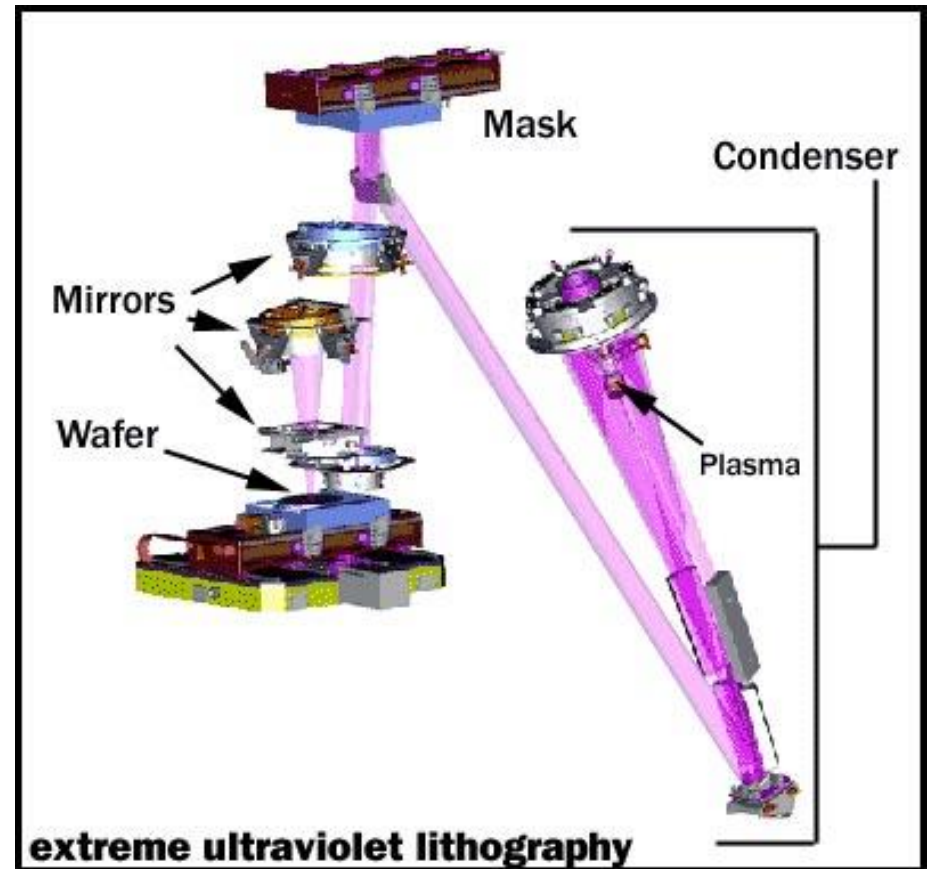
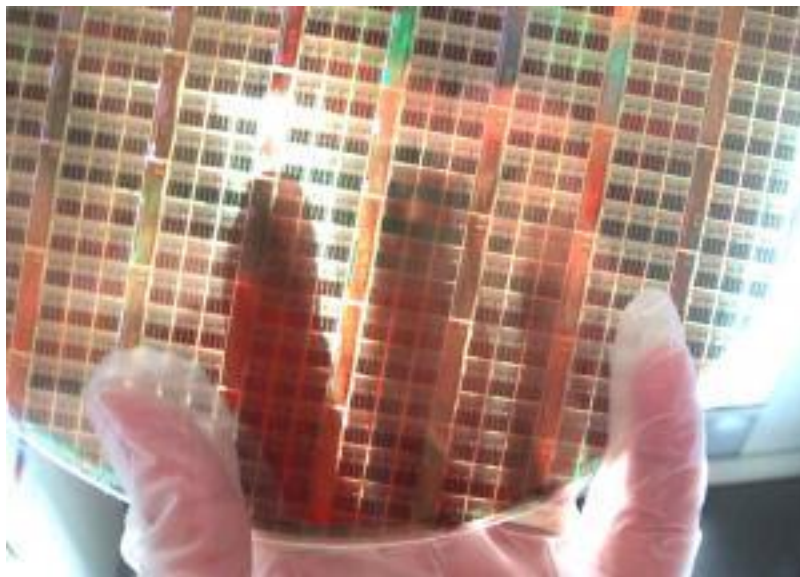
Smaller features mean denser packing of transistors, which leads to more powerful computers, more memory, and hopefully lower costs.



Single Crystal Semiconductor

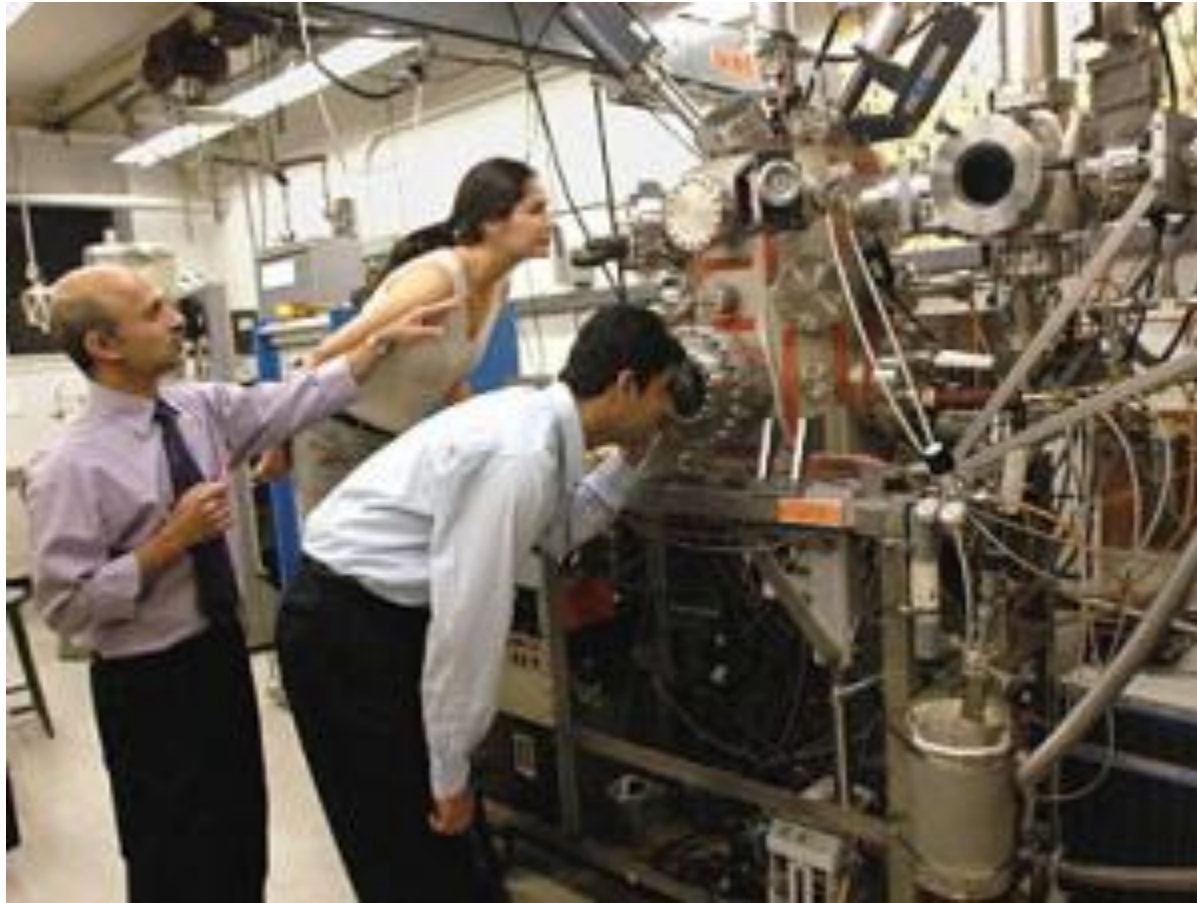


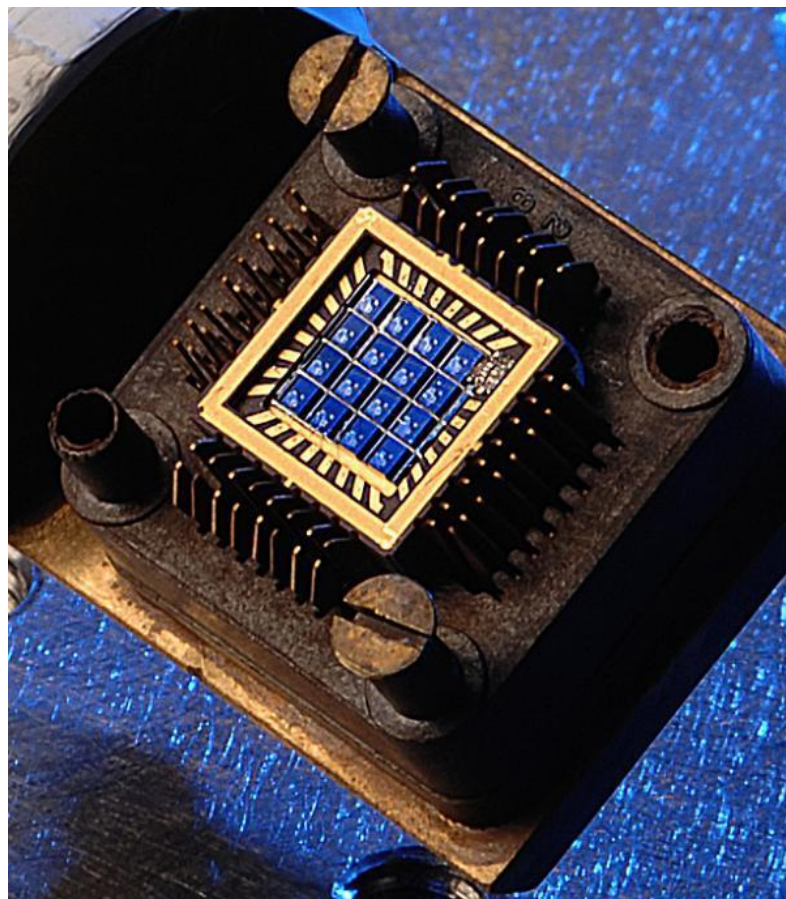


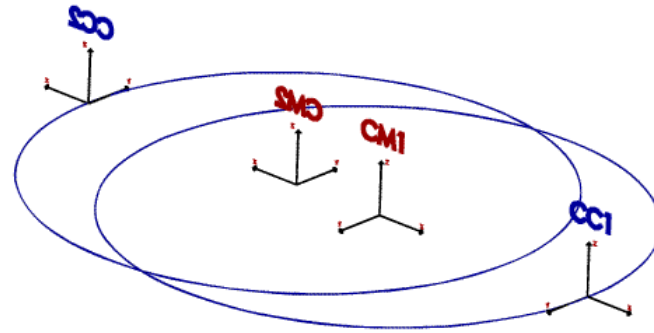
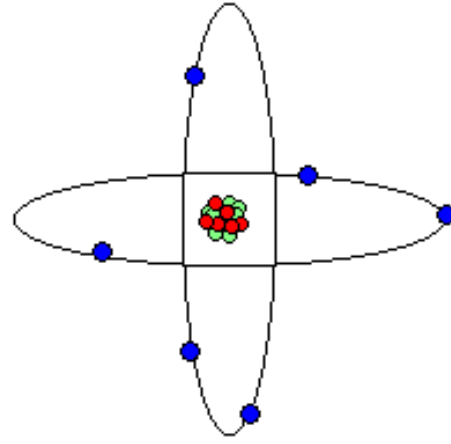


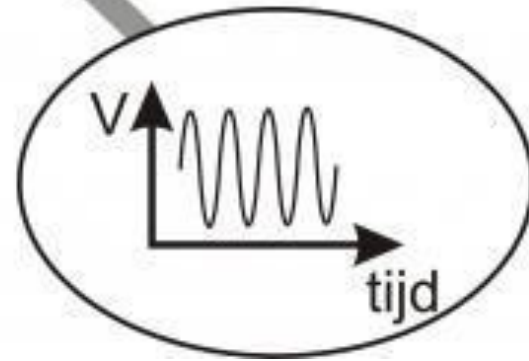
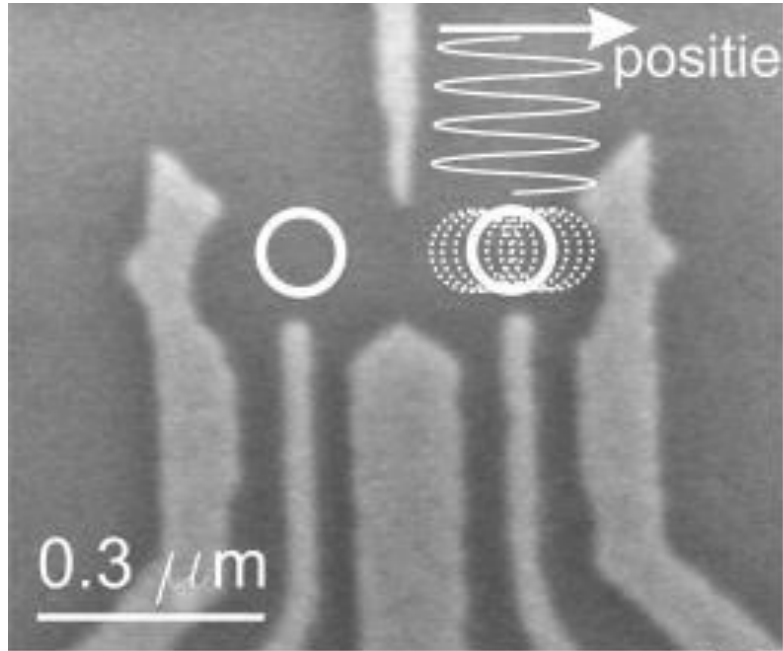


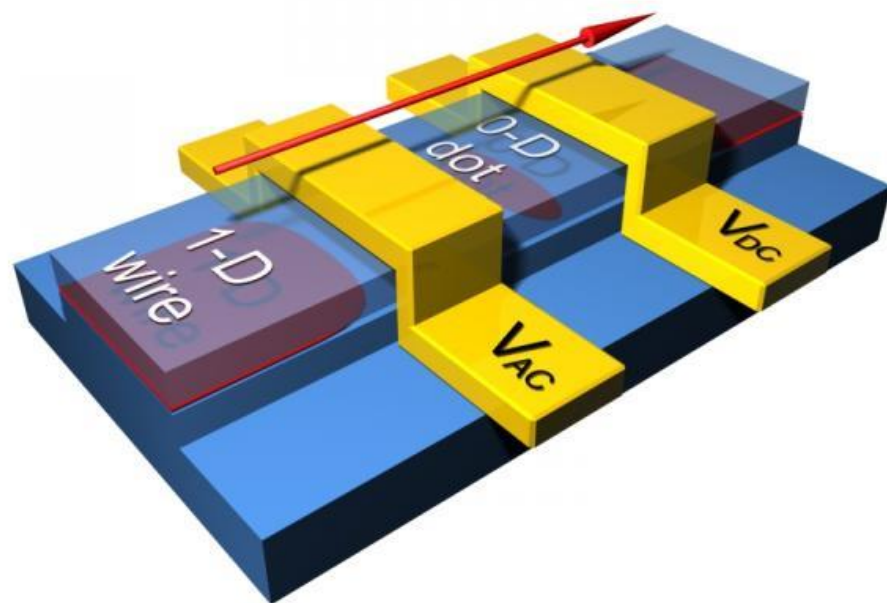
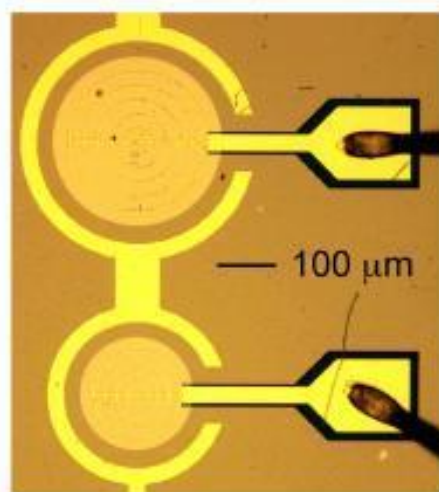
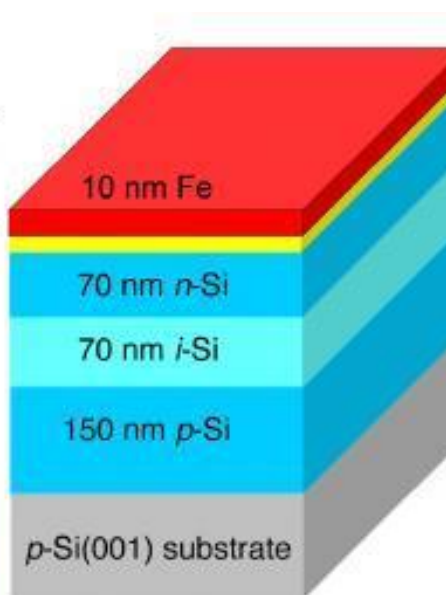
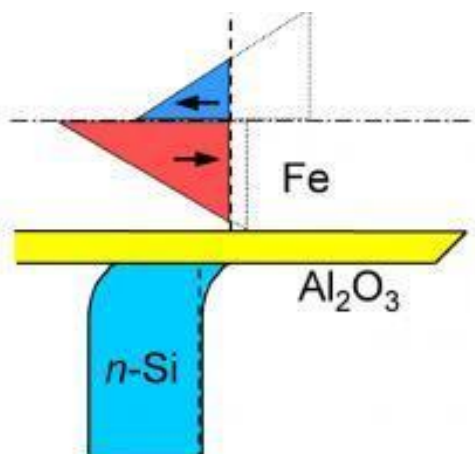
Semiconductor Spintronics



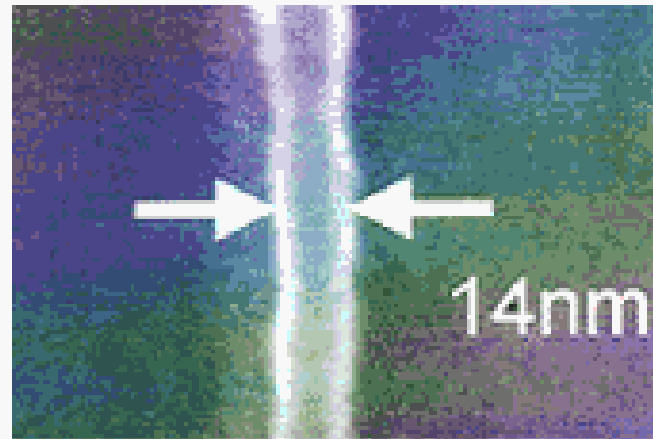
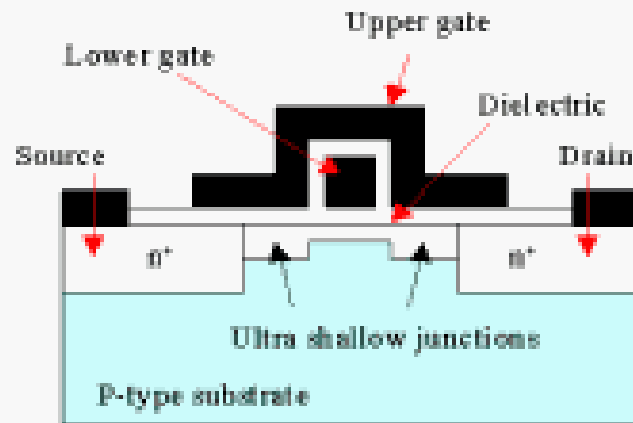


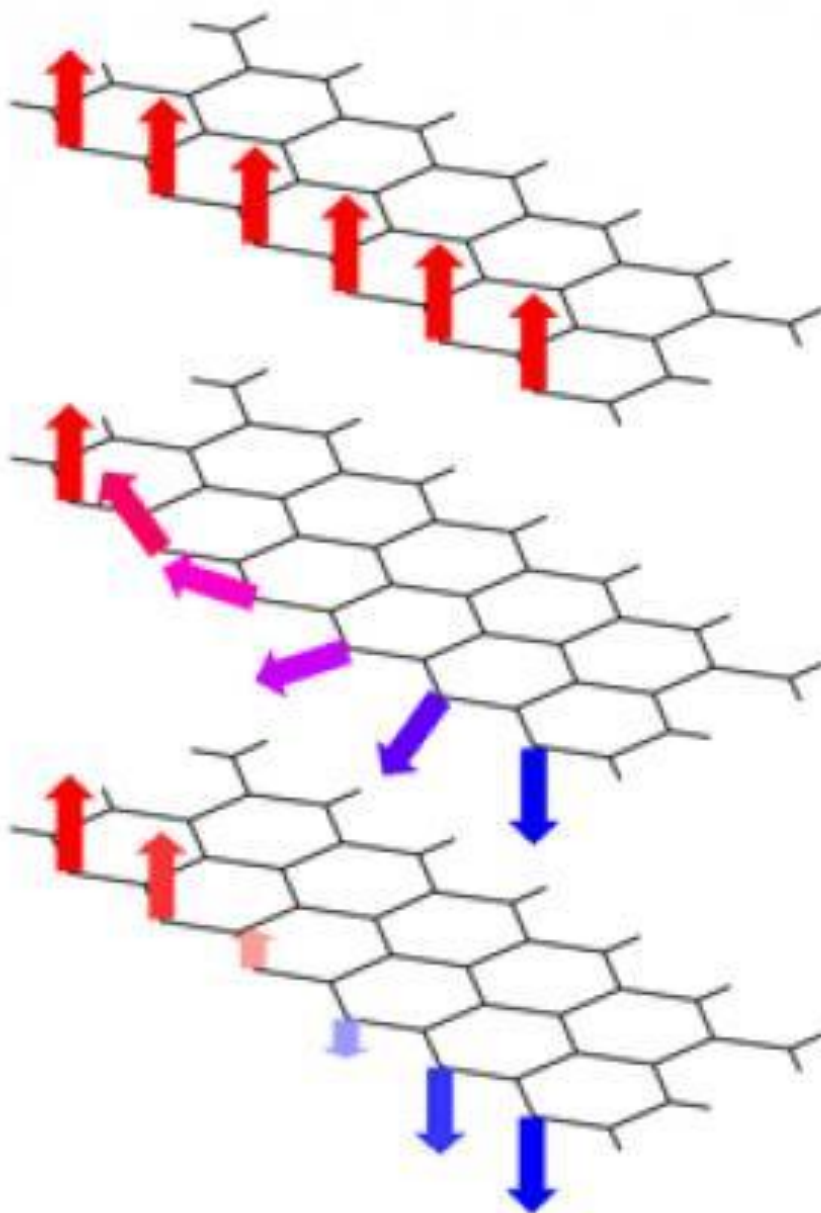
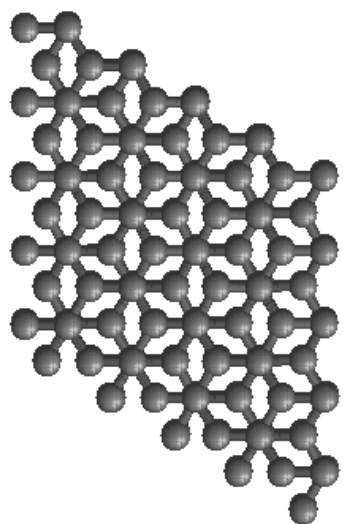
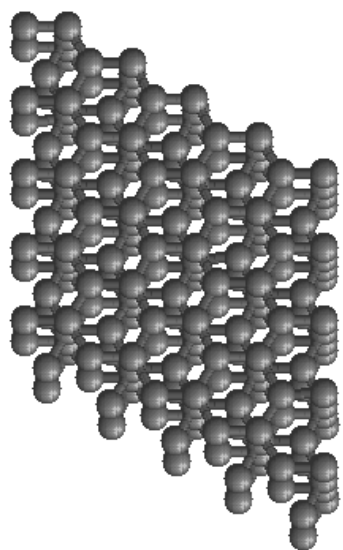




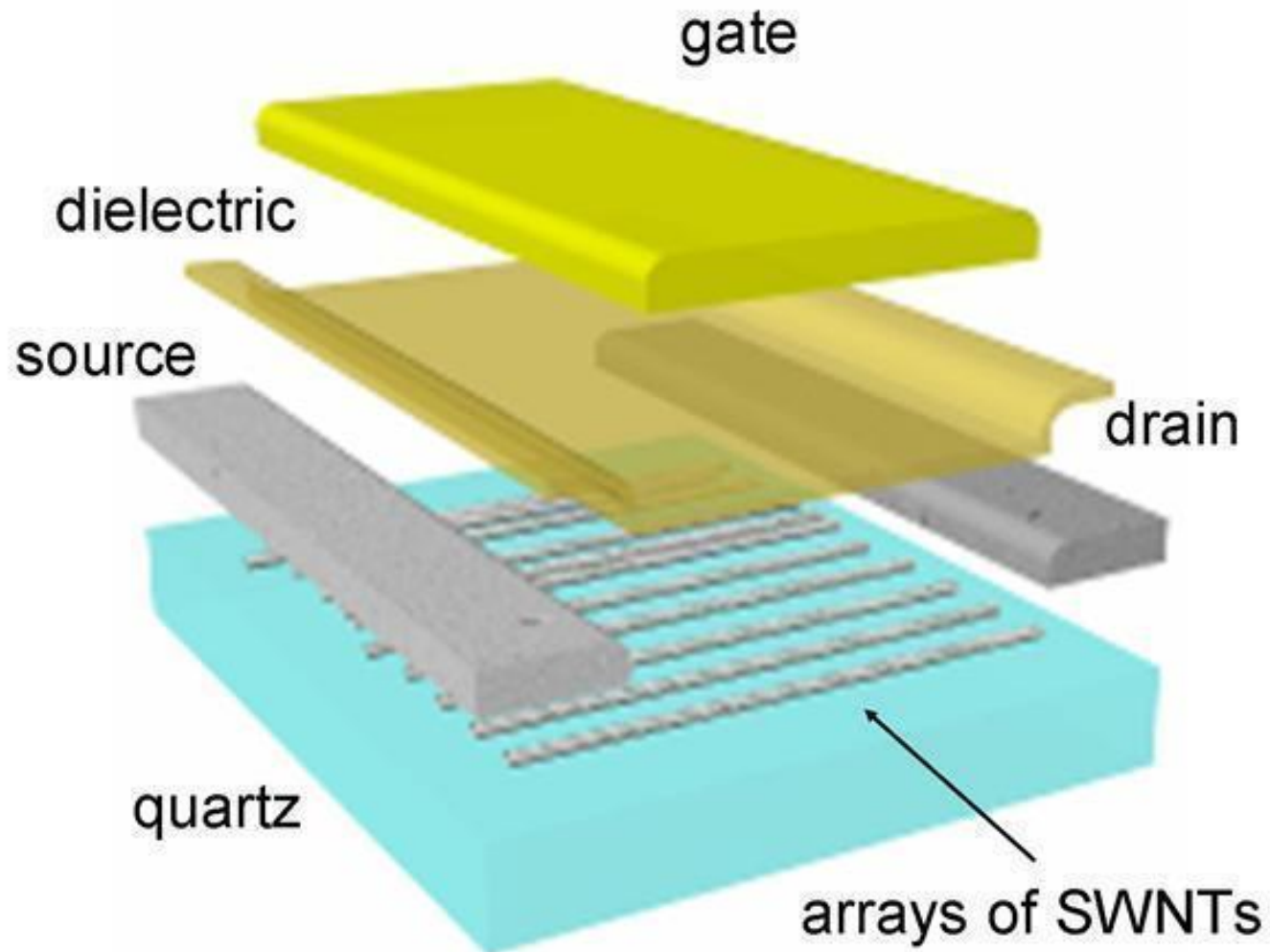


Smallest Transistor ?

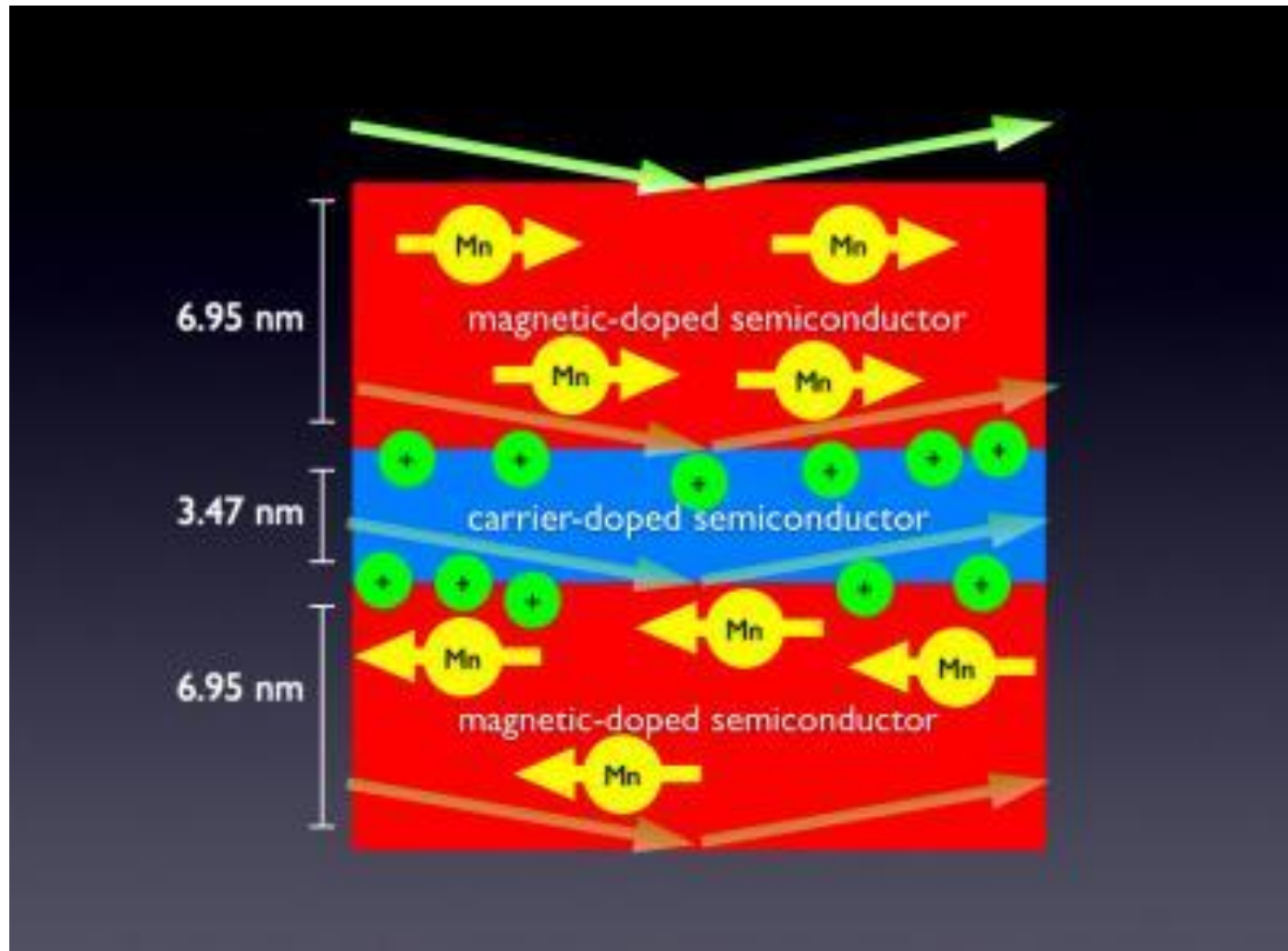




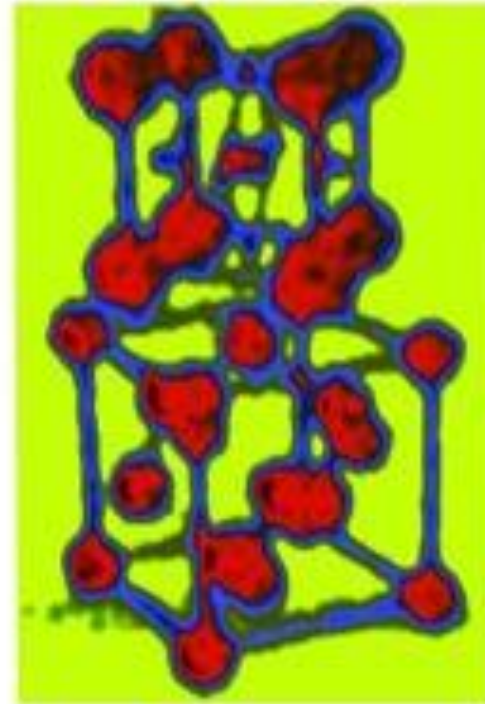
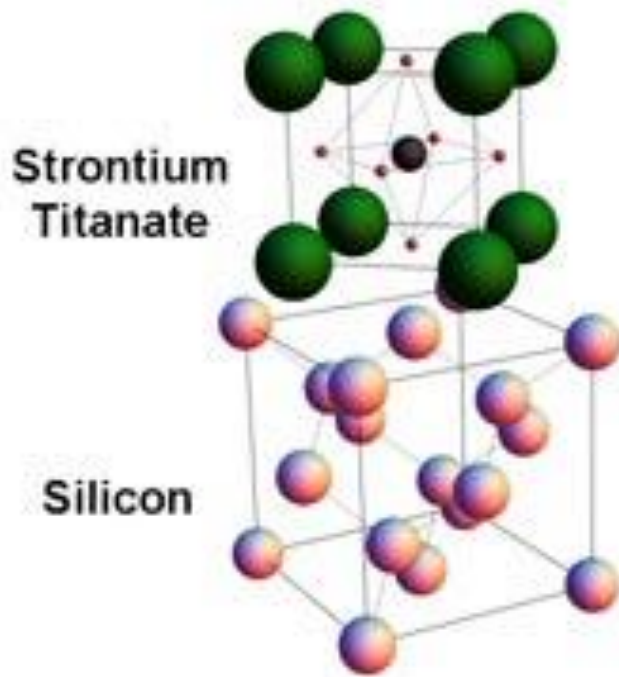
Smallest Radio?



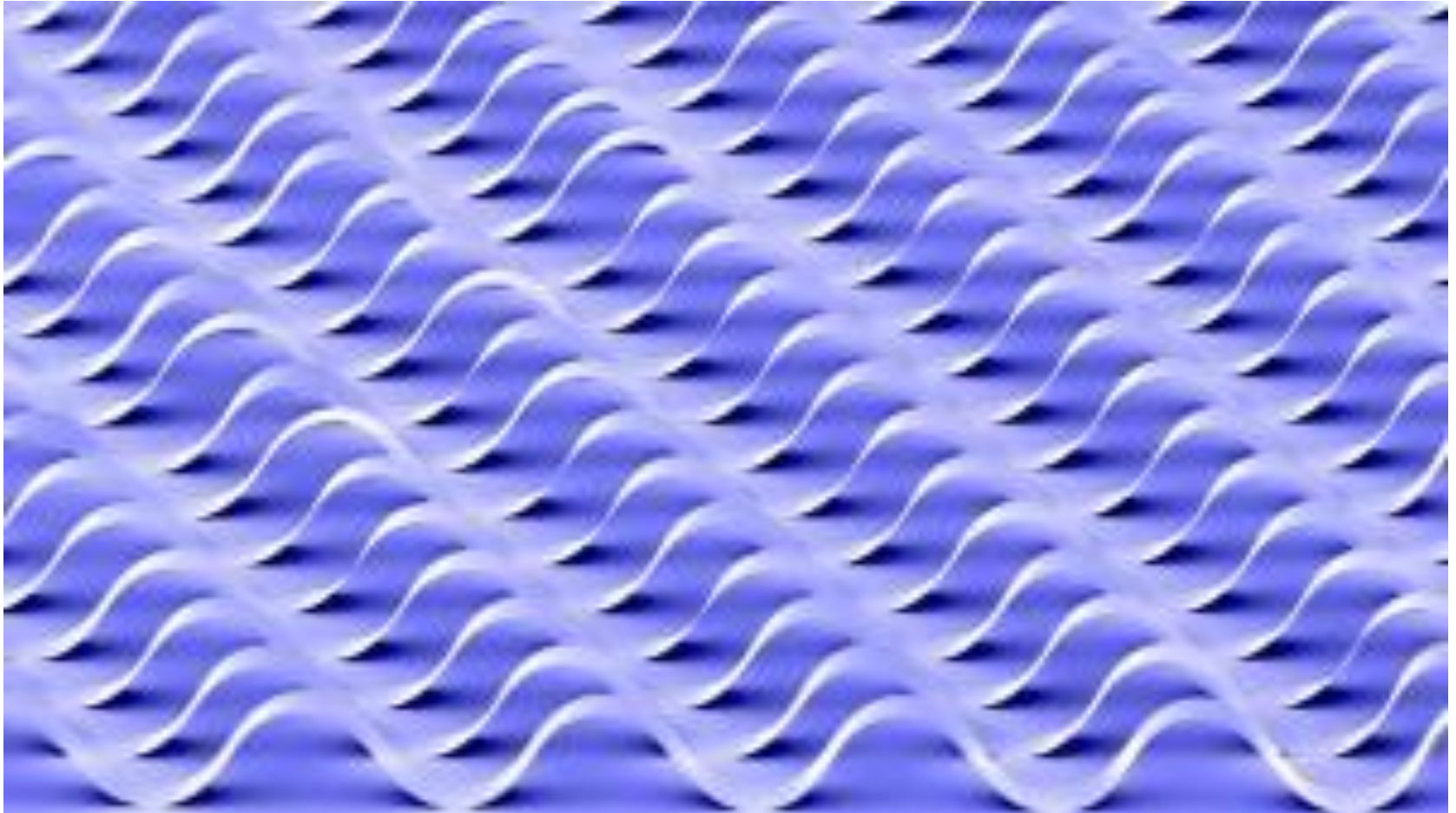
Antiferromagnetic Coupling



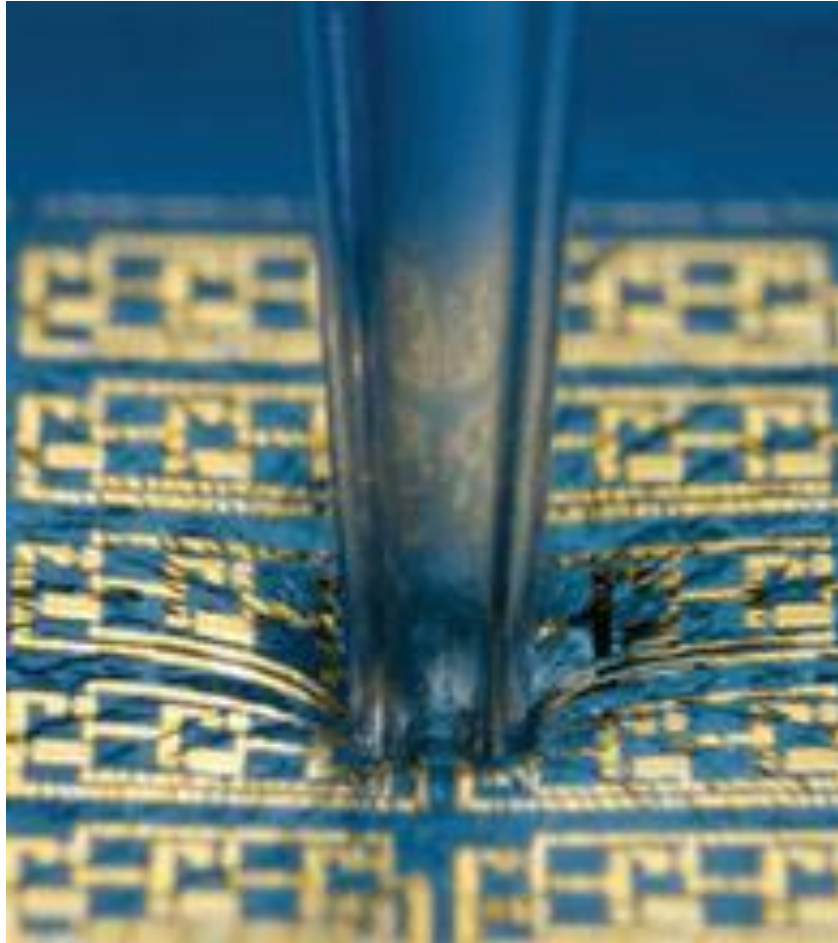
“Instant On” Computing!



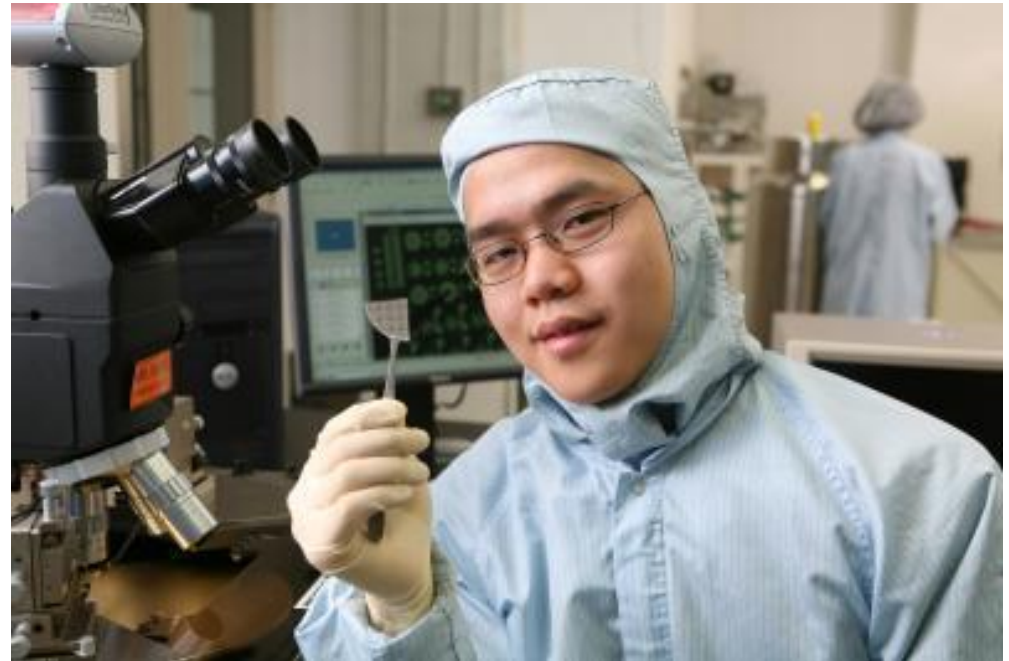
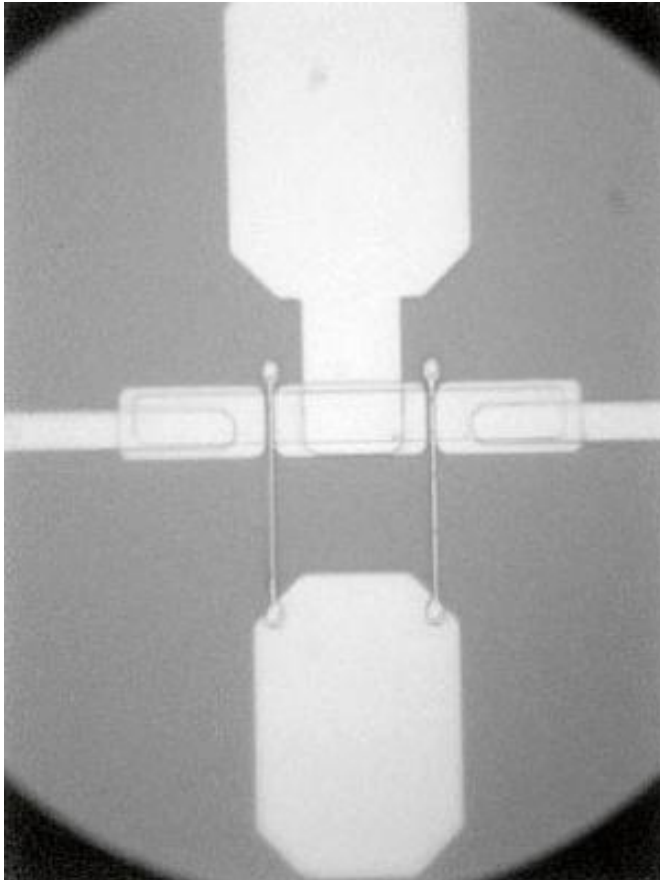
Stretchable and Foldable Silicon Integrated Circuits



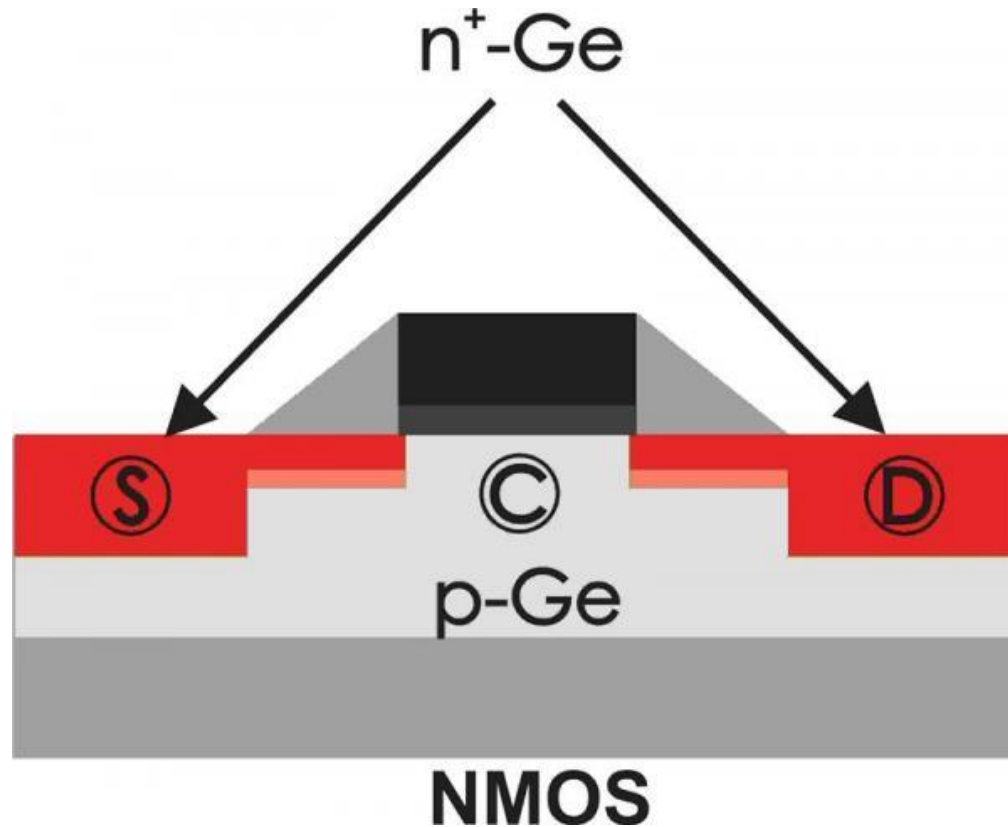
Stretchable and Foldable Silicon Integrated Circuits



Beyond Silicon!



Germanium Nanoelectronics

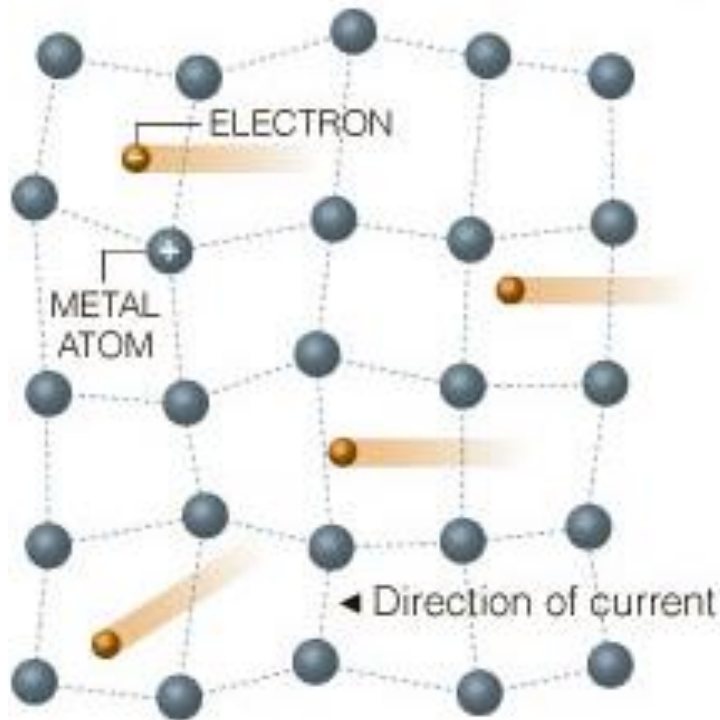


Will lead to even smaller, faster transistors!

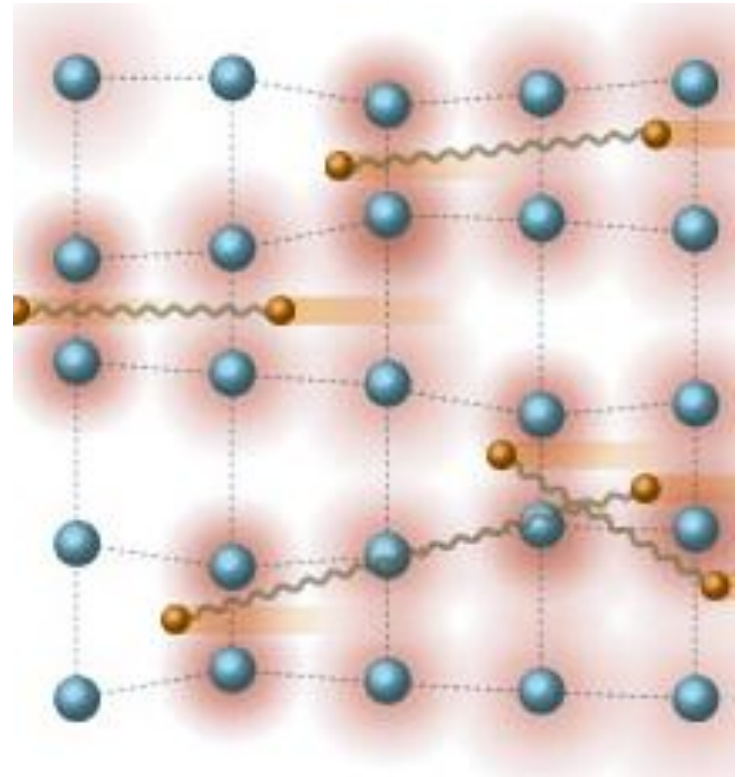
Superconductors



Superconductors



Normal State



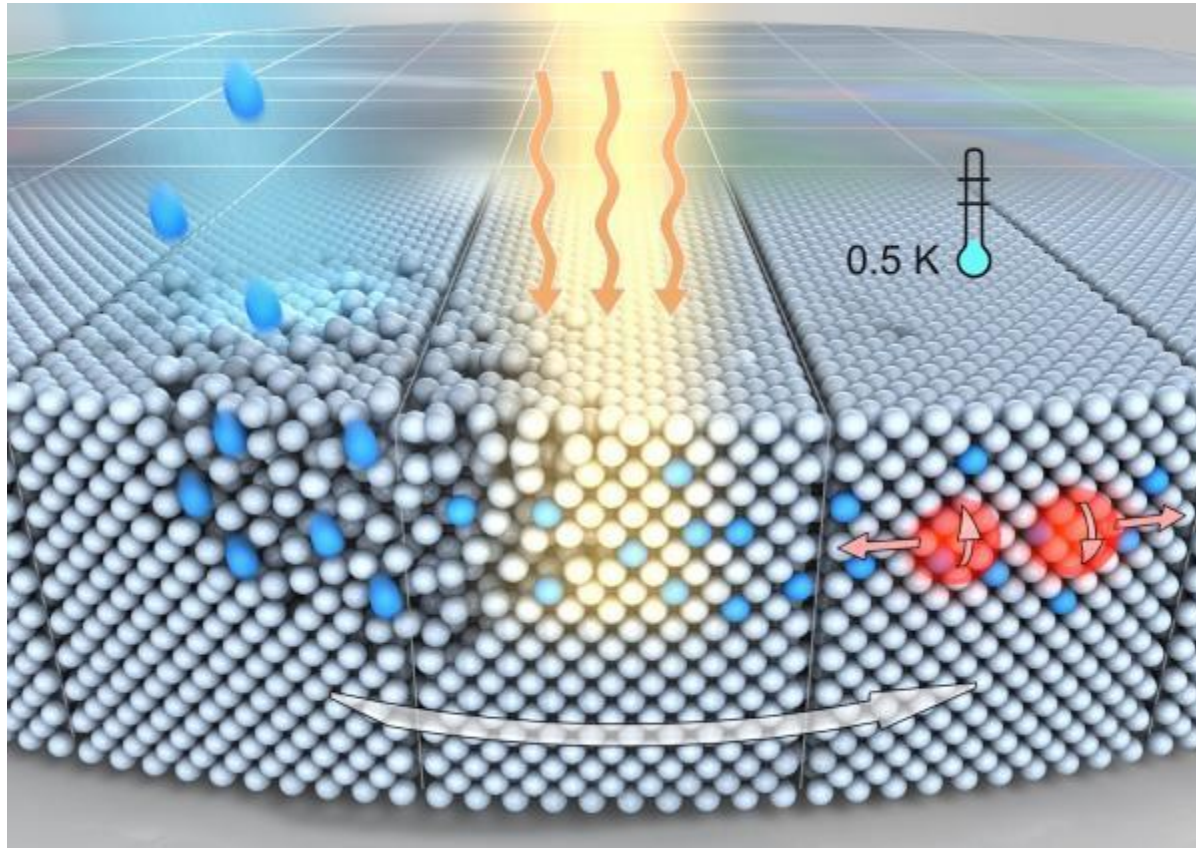
Superconductor

Superconducting Elements																					
1 H																	2 He				
3 Li	4 Be															5 B	6 C	7 N	8 O	9 F	10 Ne
11 Na	12 Mg															13 Al	14 Si	15 P	16 S	17 Cl	18 Ar
19 K	20 Ca	21 Sc	22 Ti	23 V	24 Cr	25 Mn	26 Fe	27 Co	28 Ni	29 Cu	30 Zn	31 Ga	32 Ge	33 As	34 Se	35 Br	36 Kr				
37 Rb	38 Sr	39 Y	40 Zr	41 Nb	42 Mo	43 Tc	44 Ru	45 Rh	46 Pd	47 Ag	48 Cd	49 In	50 Sn	51 Sb	52 Te	53 I	54 Xe				
55 Cs	56 Ba	57 La	72 Hf	73 Ta	74 W	75 Re	76 Os	77 Ir	78 Pt	79 Au	80 Hg	81 Tl	82 Pb	83 Bi	84 Po	85 At	86 Rn				
87 Fr	88 Ra	89 Ac	104 Rf	105 Ha	106 Sg	107 Bh	108 Hs	109 Mt	110 Ds	111 Rg	112 Uub										

In Bulk at Ambient Pressure
 At High Pressure
 In Modified Form

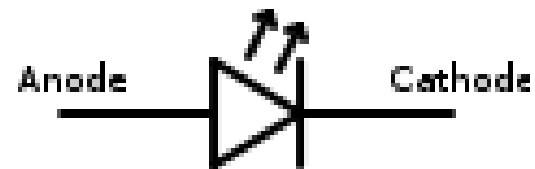
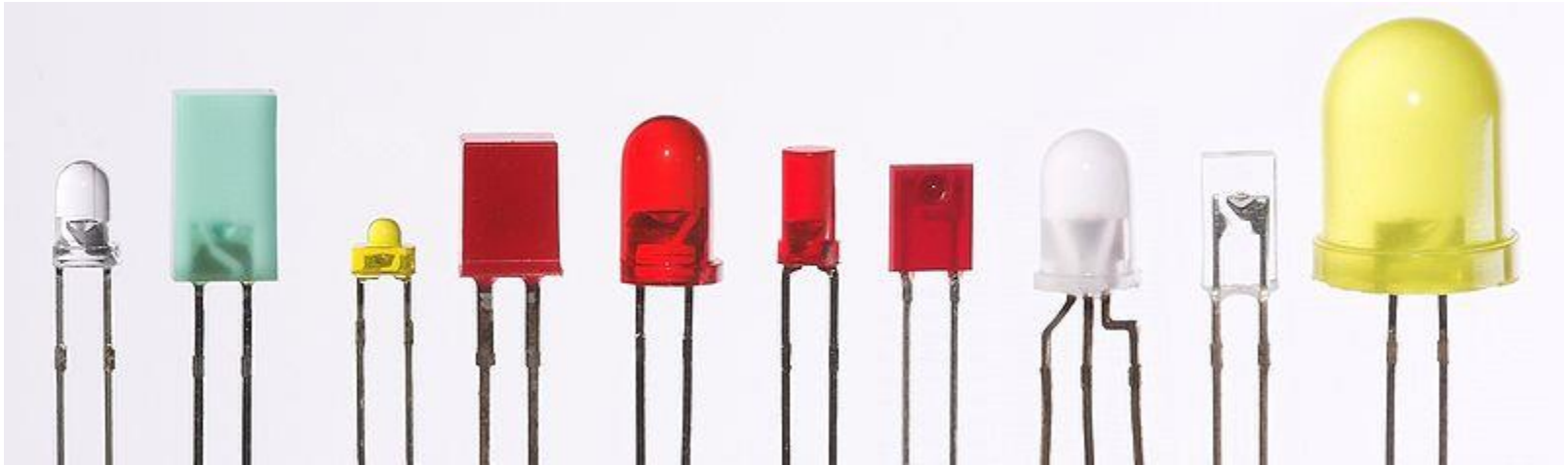
58 Ce	59 Pr	60 Nd	61 Pm	62 Sm	63 Eu	64 Gd	65 Tb	66 Dy	67 Ho	68 Er	69 Tm	70 Yb	71 Lu
90 Th	91 Pa	92 U	93 Np	94 Pu	95 Am	96 Cm	97 Bk	98 Cr	99 Es	100 Fm	101 Md	102 No	103 Lr

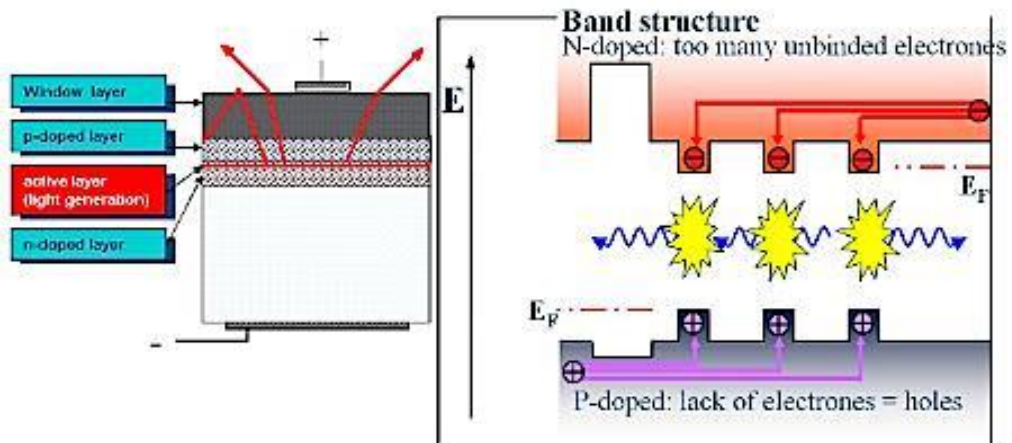
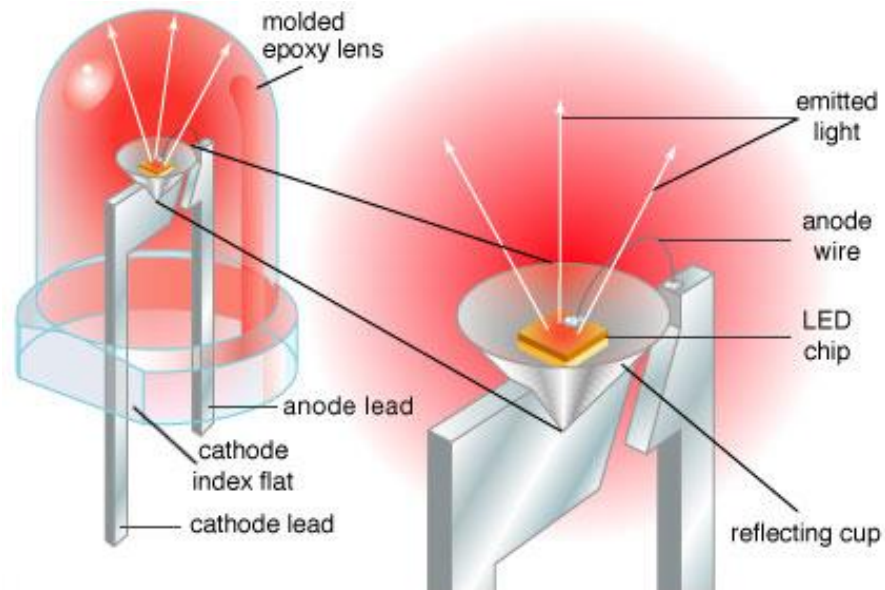
Semiconductor Superconductors



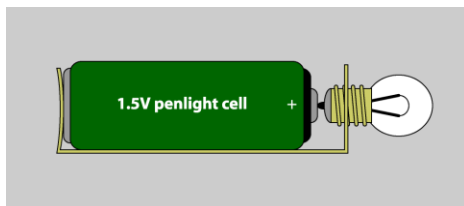
Doping germanium with charged gallium ions.

Light Emitting Diodes

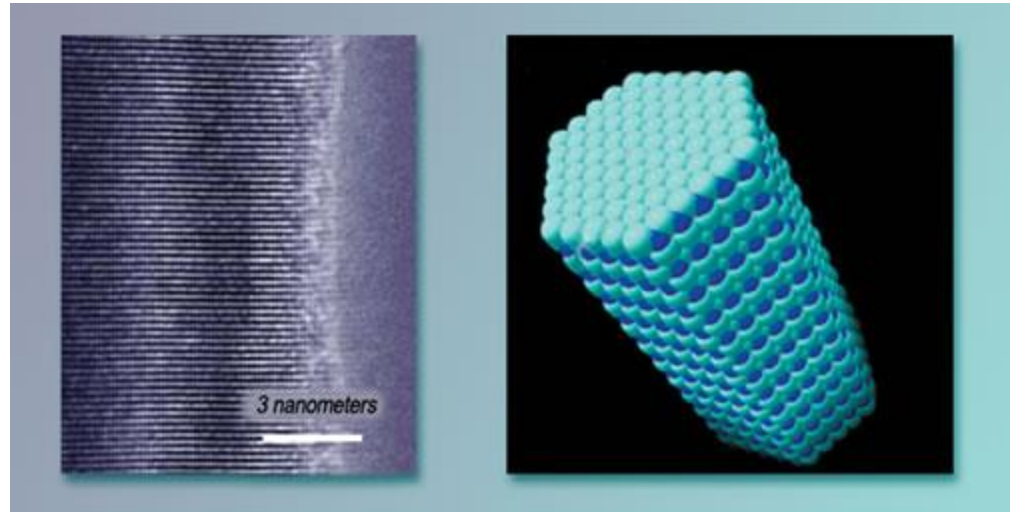
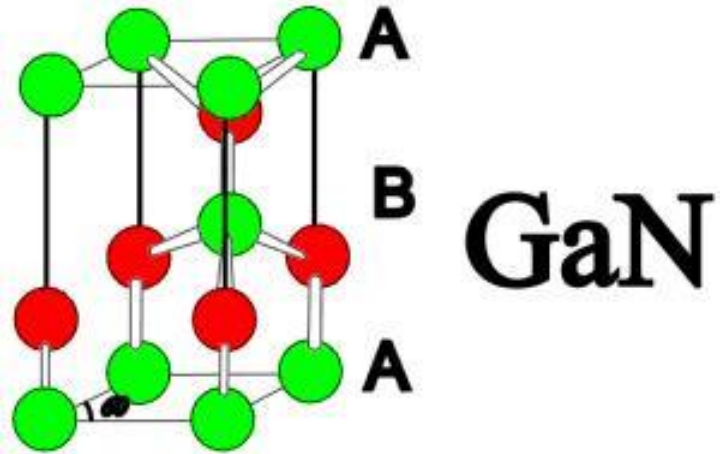




LED's Advantages



Gallium Nitride

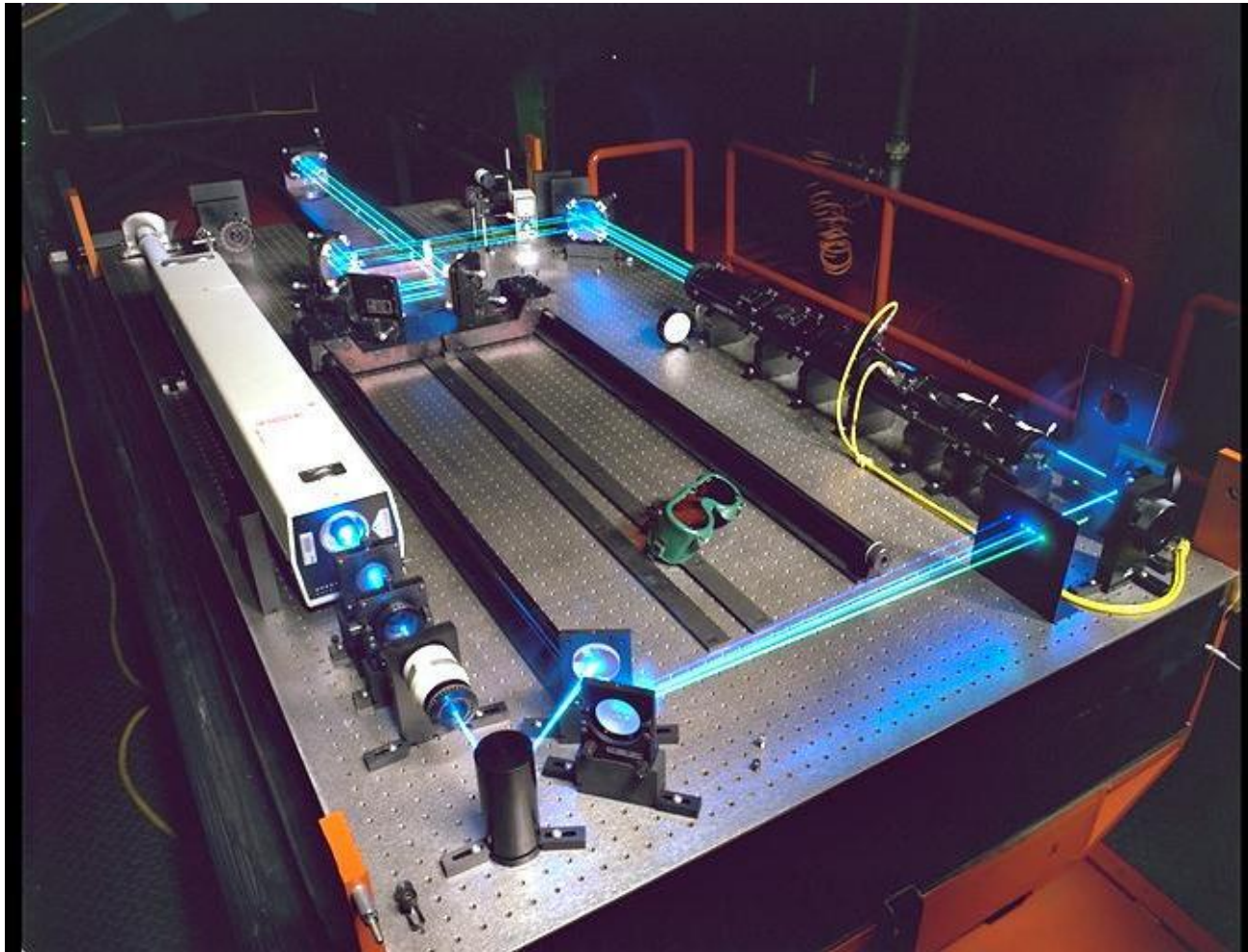




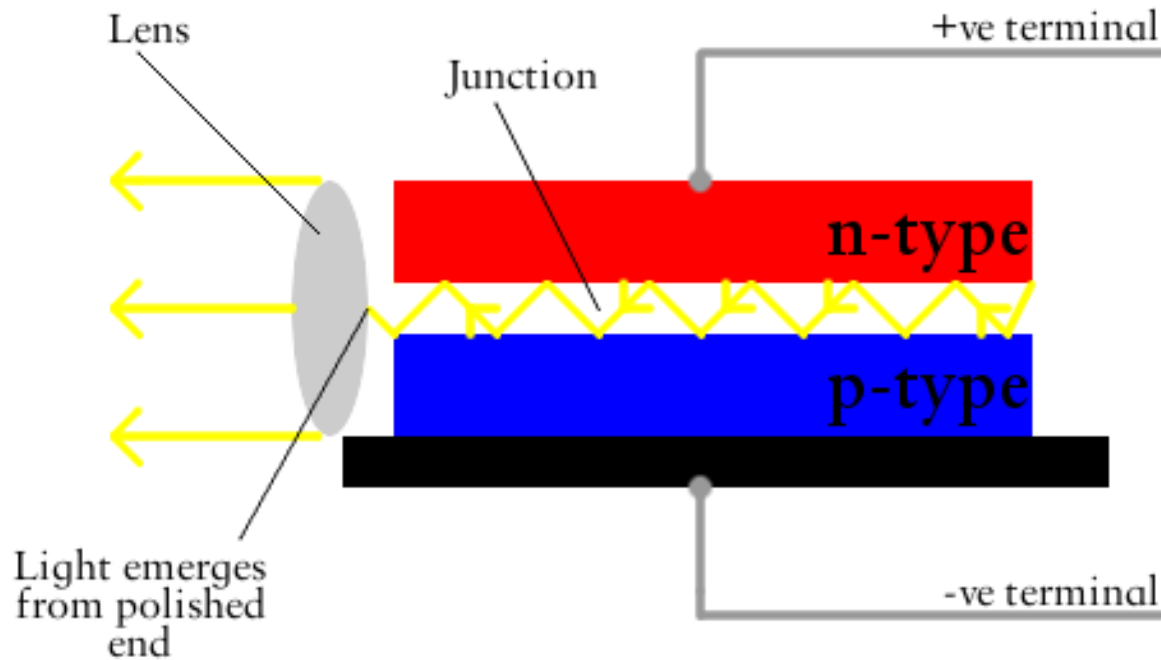
Polarized LED



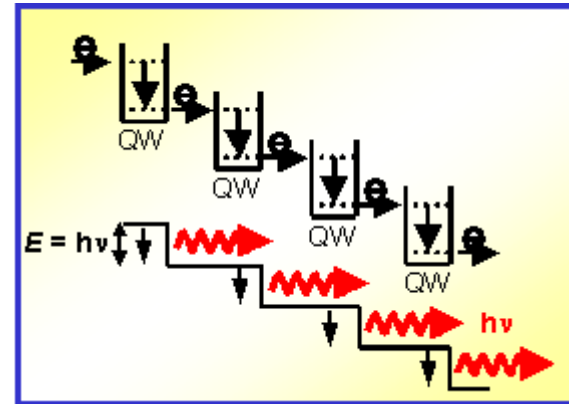
Semiconductor Lasers



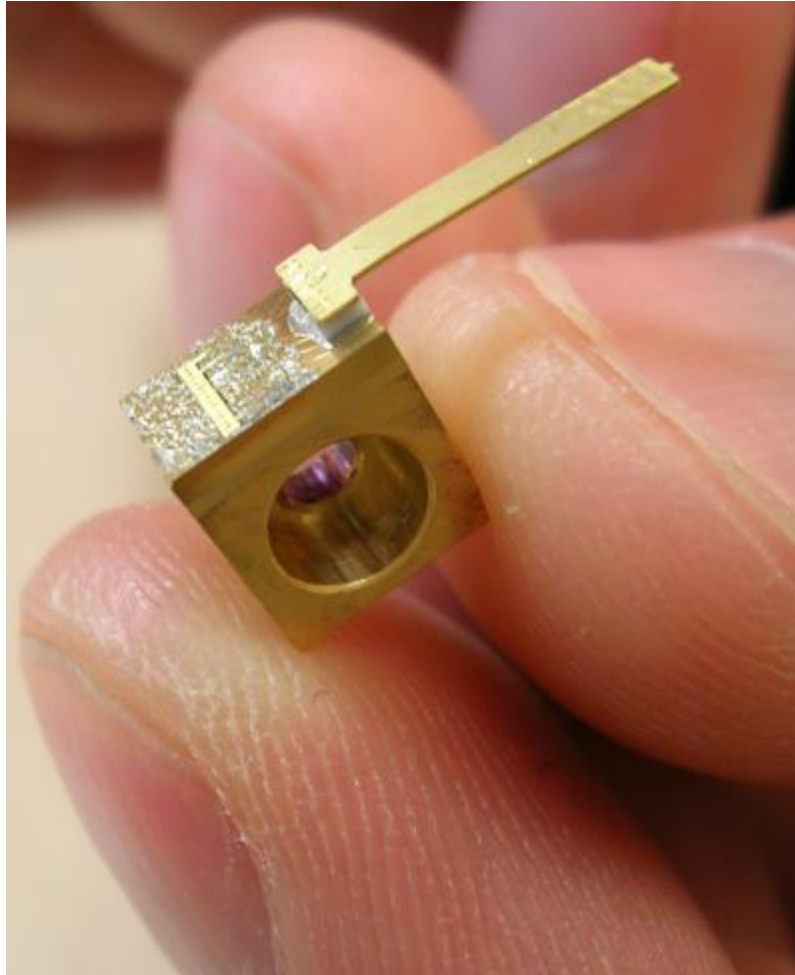
Semiconductor Lasers



Cascade Lasers

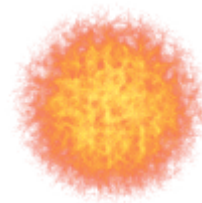
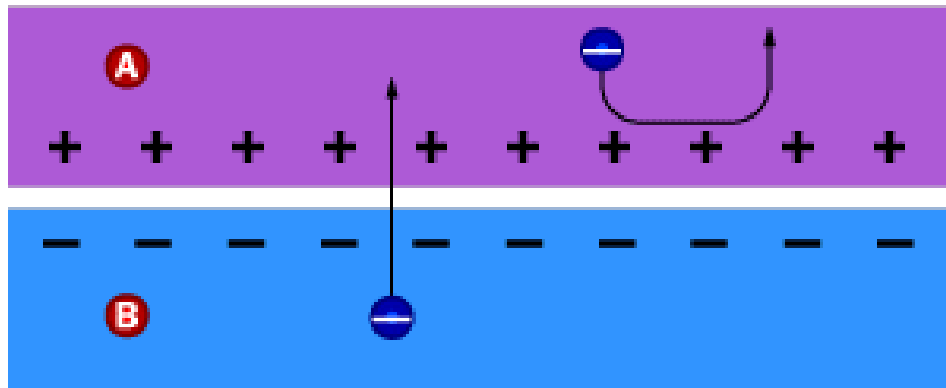


Quantum Cascade Laser



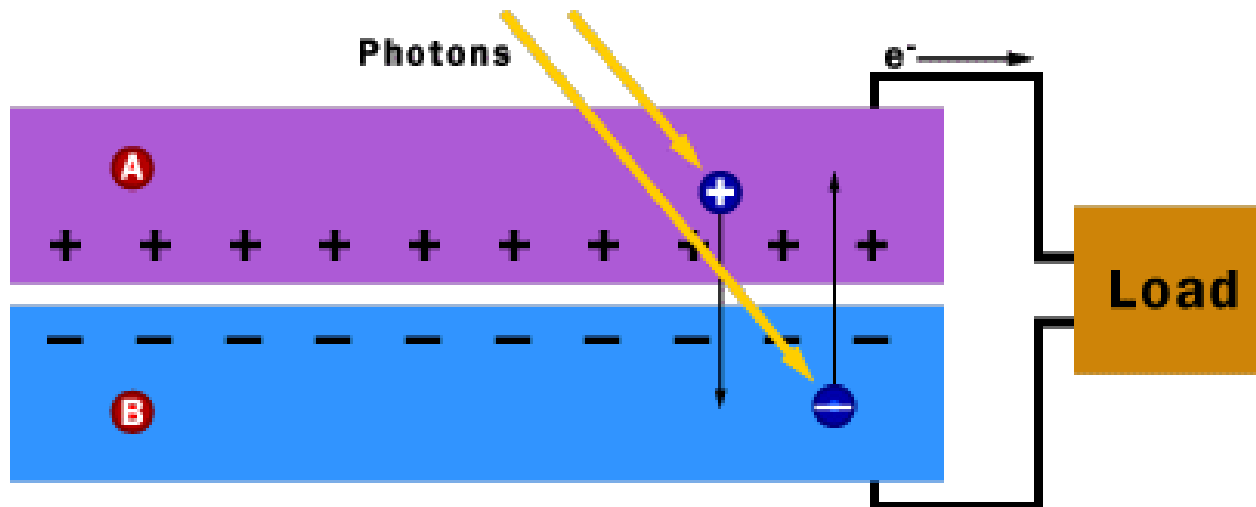
Solar Panels

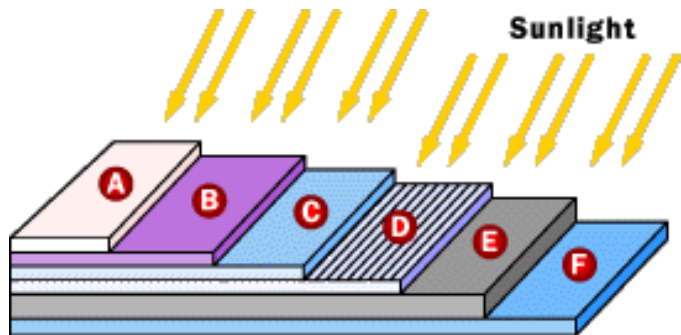




A n-type Silicon

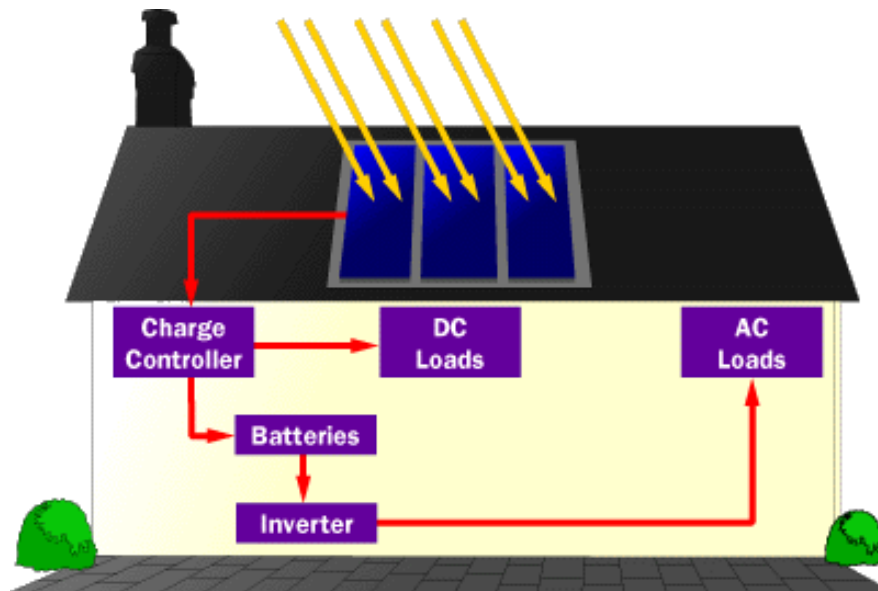
B p-type Silicon





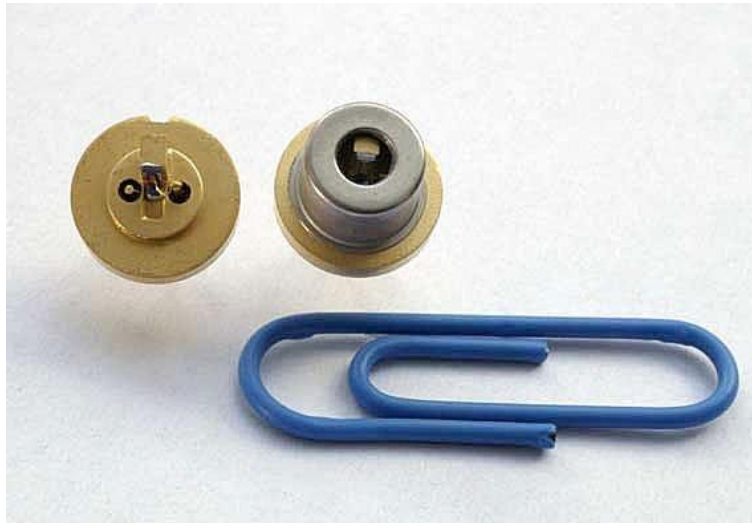
- A** Cover glass
- B** Antireflective coating
- C** Contact grid

- D** N-type Si
- E** P-type Si
- F** Back contact









$\text{Zn}_{1-x}\text{Mg}_x\text{O}$	$\sim 100 \text{ nm}$
ZnO	$\sim 1 \text{ mm}$
MgO	$\sim 10 \text{ nm}$
<i>c</i> -sapphire	

Silicon Wafer Production



**Polysilicon
Creation**



**Crystal
Pulling**



**Wafer
Slicing**

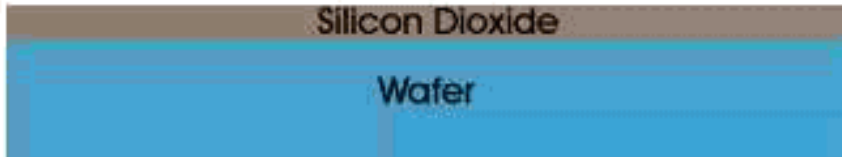


**Lapping &
Polishing**

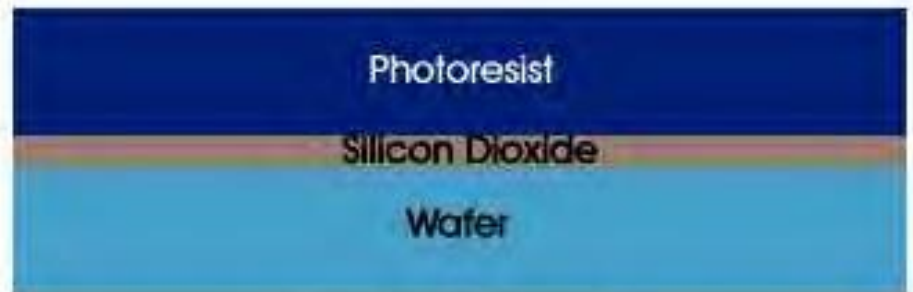


**Wafer
Epitaxial
Processing**

Semiconductor Manufacturing

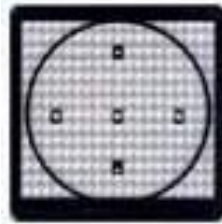


Oxidation Layering

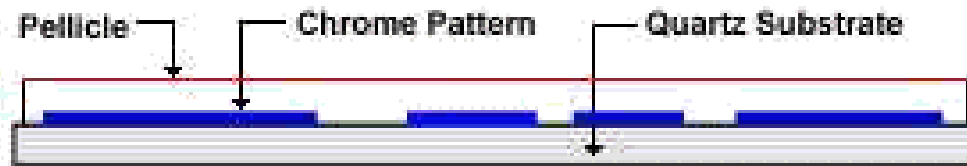


Photoresist Coating

Pattern Preparation



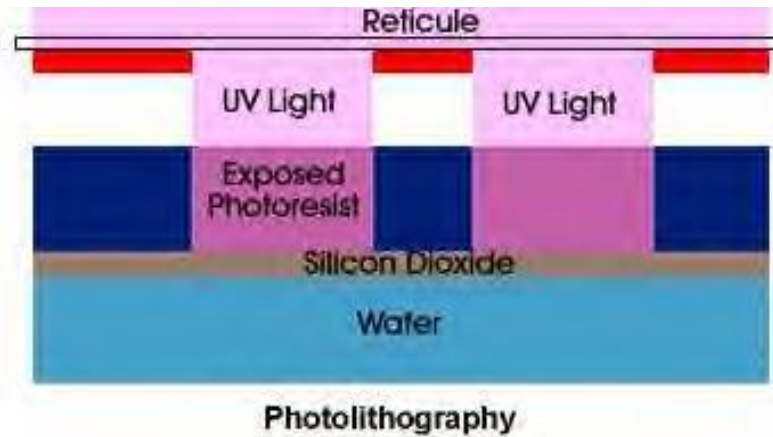
Pattern
Preparation



Reticle

Pattern Preparation

Photolithography



Photoresist Developing



Photoresist Developing

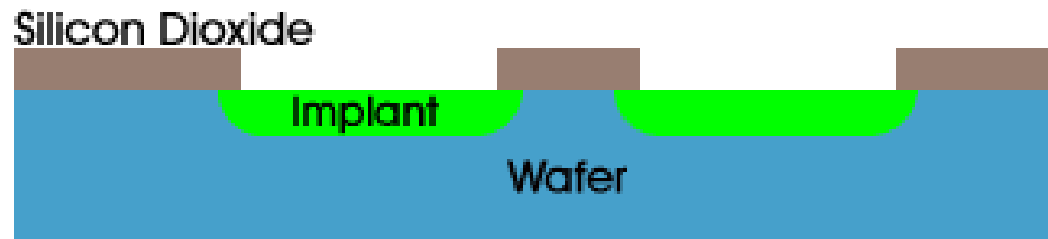
Dielectrics Etching



Photoresist Ashing

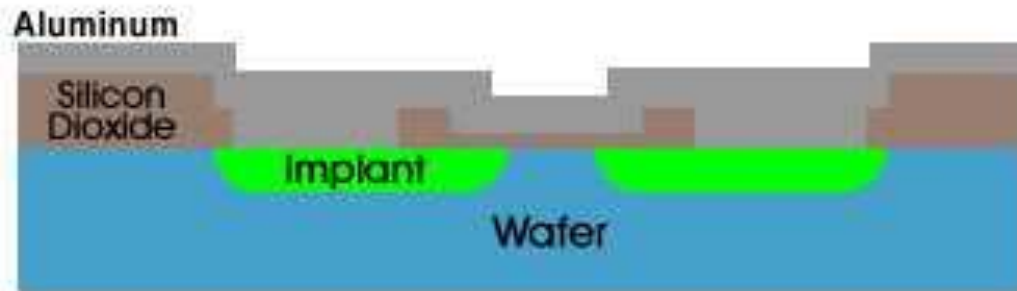


Ion Implant



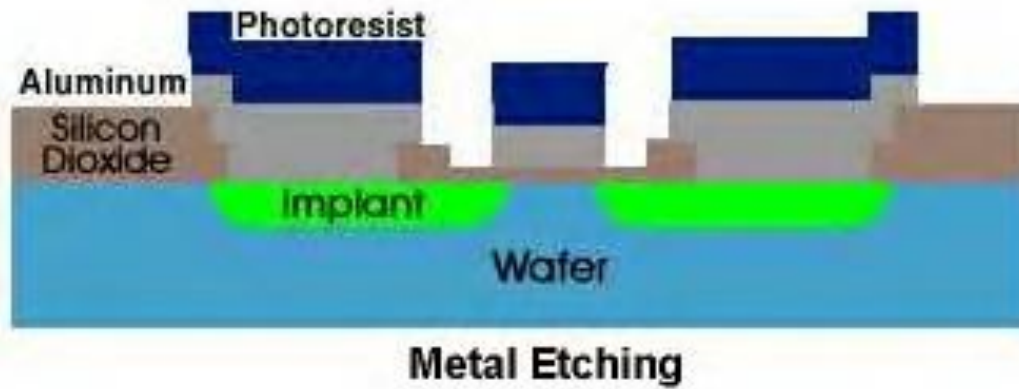
Ion Implant

Metal Deposition



Metal Deposition

Metal Etching



Dielectrics Layering



Dielectrics Layering